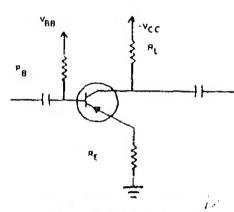
ADVANCED FIRST-TERM AVIONICS COURS

C-100-2010



FOR

CLASS AT

# UNIT

CNTT-M1704

PREPARED BY
NAVAL AIR TECHNICAL TRAINING CENTER
NAVAL AIR STATION MEMPHIS

MILLINGTON TENNESSEE

PREPARED FOR

CHIEF OF NAVAL TECHNICAL TRAINING

NOVEMBER 1984

#### FOREWORD

e of this Student's Guide is to assist you in comple istor Theory," Unit II, of the Advanced First-Term ourse. The proper use of this guide will increase y in the above mentioned areas, while building a basis future training will be built.

of contents lists the page numbers for safety notice sheets, information sheets, and references that wil hance your abilities and skills as an aviation elect

#### SAFETY NOTICE

safe and efficient maintenance on various types of elected equipment. Not only your life, but the lives of many of depend on your being safety conscious at all times. It responsibility of all Navy and Marine Corps personnel taccidents. This can be done if everyone develops conscibility and observes all precautions when performance of any type. Always remember:

As a Navy electronics technician, you will be required

SAFETY CANNOT BE OVERSTRESSED!!!!!

HOW TO USE THIS STUDENT'S GUIDE

s Guide" has been prepared for you to use while you the Advanced First-Term Avionics Course (Class A1). s been provided for taking notes on the required tion. Remember when you are in class, the informavided by your instructor is information you will need our Navy job.

sheets, containing lesson topic outlines,

ntains the following:

ons, and ample space for personal notetaking. n sheets to provide information pertinent to your

arn all you can!

The schedule is as follows: TOPIC NO. TYPE PERIOD TOPIC SECOND WEEK Fifth Day 67 Series Resonance 2.1 Class 78 79 Parallel Resonance 2.2 Class 80 THIRD WEEK First Day 2.2 Class 81 Parallel Resonance 2.3 Class 82 Physics Overview 83 84 2.4 Class 85 Semiconductor Physi 86 87 88 Second Day 2.4 Class Semiconductor Physi 89 2.5 PN Junctions (Labor Lab 90 91 2.6 Class 92 Junction Transistor 93 94 95 96

Class	100 101 103 104	Biasing Arrangements
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Class	113 114	Unit/Module Test: Criterion T Written Examination
C1 a.m.a	115	Decibels
Class	116 117	
Class	118 119 120	Féedback Amplifiers
Class	121 122	Feedback Ampilfiers
Class	123 124	Direct Coupled and Operational
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2.14	Class	130 131 132 133 134 135 136	Special Device
Third Da	ıy		
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2.15	Class	141 142	Vacuum-Tube Fu
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plete assigned homework may result in disciplinary

matical principles outlined in Mathematics, Vol. I, 10069 (series), Mathematics, Vol. III, NAVPERS 1007 Basic Electronics, Vol. I, NAVPERS 10087 (series), Electricity, NAVPERS 10086 (series). Performance w measured by a written multiple-choice examination. ANALYZE the internal structure and operation of sem 2.0 junctions by tracing majority and minority current a given semiconductor device, in accordance with qu mechanical principles outlined in Basic Electronics NAVPERS 10087 (series) and Aviation Electronics 3 & NAVEDTRA 10317 (series). Performance will be measu written multiple-choice examintion. 3.0 Mathematically ANALYZE the operation of given basic conductor circuits by solving problems in terms of current, reactance, and frequency. A formula sheet provided. Responses must be in accordance with Bas Electronics, Vol. I, NAVPERS 10087 (series), and pe will be measured by a written multiple-choice exami 4.0 ANALYZE the internal structure and operation of vac circuits by identifying elements and their function SOLVING problems in terms of voltage, current, resi biasing. Responses must be in accordance with info outlined in Basic Electronics, Vol. I, NAVPERS 1008 Performance will be measured by a written multiple examination. A formula sheet will be provided. ENABLING OBJECTIVES 1.1 SOLVE problems involving addition, subtraction, mul and division of radicals and exponents, using the 1 exponents. Response must be in accordance with Mat Vol. I, NAVPERS 10069 (series). Performance will b by a written multiple-choice examination.

> SOLVE problems involving the addition, subtraction, cation, division, evaluation, and simplification of expressions. Response must be in accordance with  $\underline{\mathtt{M}}$

VOL. I. NAUDEDS 10060 (----

1.2

mathematics, algebra, and trigonometry. A formula trigonometric tables, and a Universal Time Constant be provided. Performance must be in accordance wit Performance will be measured by a written multiple-cho: examination. A formula sheet and a Universal Time Cons Chart will be provided. SOLVE for unknown current, voltage, and resistance value electronic circuits containing source characteristics a voltage dividers. Response must be in accordance with Electricity, NAVPERS 10086 (series). Performance will neasured by a written multiple-choice examination. A sheet will be provided. SOLVE for unknown values of current, voltage, reactance power in series and parallel a-c circuits. Response mu in accordance with Basic Electricity, NAVPES 10086 (see Performance will be measured by a written multiple-cho. examination. A formula sheet and trigonometric tables provided. SOLVE for unknown values of current, voltage, reactance frequency, bandwidth, and circuit "Q", in series and page resonant circuits. Response will be in accordance with Electronics, Vol. I, NAVPERS 10087 (series). Performan be measured by a written multiple-choice examination. sheet and trigonometric tables will be provided. SELECT, from a given list, correct statements concernia structure of an atom, given an element from the Period: of Chemical Elements. Responses must be in accordance Basic Electronics, Vol. I, NAVPERS 10087 (series). Per will be measured by a written multiple-choice examinat SELECT, from given lists, correct statements related to properties of heat, sound, cryogenics, and the electron

SOLVE for total capacitance, RC time, curent, and voltable values of a simple RC switching circuit. Response must accordance with Basic Electricity, NAVPERS 10086 (series examination. A formula sheet and a Universal Time Cons

SOLVE for total inductance, L/R time, current, and volumes of a simple L/R switching circuit. Response must accordance with Basic Electricity, NAVPES 10086 (series

Chart will be provided.

ritten multiple-choice examination.

ETERMINE biasing arrangements of semiconductor circuits OLVING problems in terms of voltage, current, reactance requency. Responses must be in accordance with Basic lectronics, Vol. I, NAVPERS 10087 (series). Performance measured by a written multiple-choice examination. Pormula sheet will be provided.

ETERMINE capabilities, electrical characteristics, advant disadvantages of given semiconductor circuits by SOI roblems in terms of voltage, current, reactance, and for

y. Responses must be in accordance with Basic Electron ol. I. NAVPERS 10087 (series). A formula sheet will be

OMPUTE decimal gain and loss in terms of the voltage are for a given semiconductor amplifier circuit. Responses to accordance with Basic Electronics, Vol. I, NAVPERS 10 series). A formula sheet will be provided. Performance

e measured by a multiple-choice examination.

rovided.

ETERMINE normal biasing polarities of semiconductor jury ANALYZING majority and minority current through a give emiconductor circuit. Responses must be in accordance uantum principles outlined in Basic Electronics, Vol. 1 AVPERS 10087 (series). Performance will be measured by

UILD basic semiconductor amplifier circuits (under suporision). MEASURE values and RECORD measurements, calculand evaluations on a job sheet, given necessary test equal and RCA 6F16 transistor trainer. 'Accuracy will be mean accordance with information contained in Basic Electrol. I, NAVPERS 10087 (series).

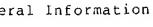
ELECT, from given lists, the names and functions of the

lements contained within a vacuum-tube. Responses must coordance with information outlined in Basic Electronic ol. I, NAVPERS 10087 (series). Performance will be meany a written multiple-choice examination.

OLVE problems in terms of voltage, current, resistance iasing, using vacuum-tube formulas and tube constants. esponses must be in accordance with information outliness.

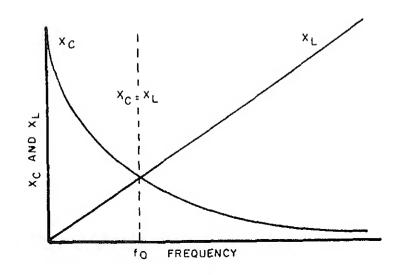
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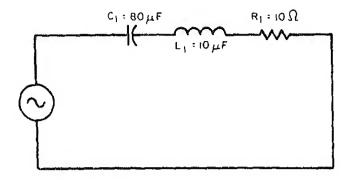


Figure 2. Series Resonant Circuit

### III. Resonant Series Circuit Analysis

### RLC Circuit Analysis

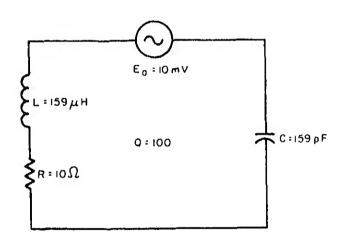
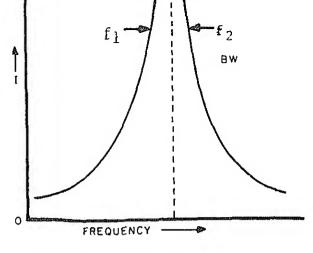


Figure 3. Series RLC circuit



(A) HIGH Q CURRENT CURVE

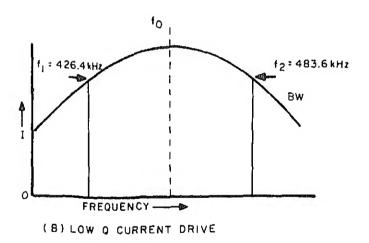


Figure 4. Bandwidth curves

. Shrader, Electronic Communication, Fourth Edition, ill, Inc., 1980, Chapter 8, pages 123-131.

ectronics, Vol. 1, NAVPERS 10087-C, Chapter 10,

3 to 209.

OUTLINE:

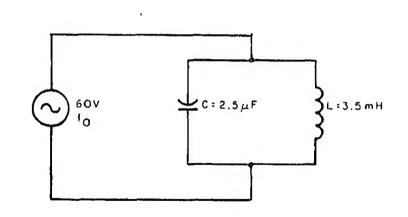


Figure 1. Parallel LC Circuit at Resonance

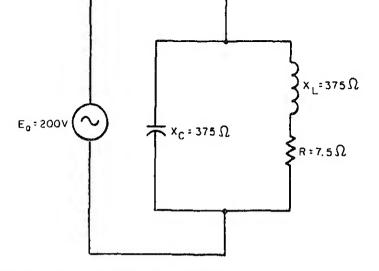
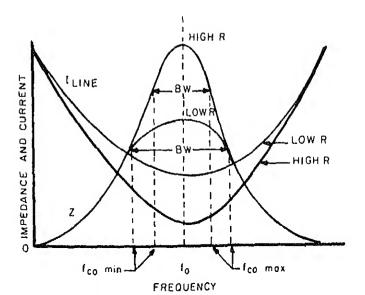


Figure 2. Parallel Resonant Circuit with Parallel Resistance.

## III. Bandwidth Considerations



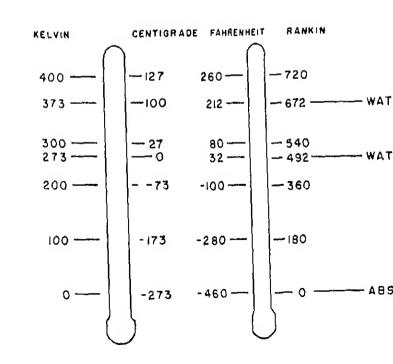
Metcalf, Trinklein, and Lefler. Modern Physics. Holt, Rinehart, and Winston, 1968. Chapters 1, 7, 27.

OUTLINE

tter

III. The Relationship Between Matter and Energy

IV. Cryogenics



## TEMPERATURE AT WHICH ELEMENT BECOMES SUPERCONDUCTIVE

iobium	8.0 K.
ead	7.2 K.
antalum	4.4 K.
ercury	4.2
horium	1.4
luminum	1.2
inc	0.91
itanium	0.4

Figure 2. Superconductivity Chart

nd

LEMENT

VELOCITY OF SOUND

MEDIUM

IN AIR AT 32° F

1,087 FT./SEC 4,794 FT./SEC

IN WATER IN STEEL 16,500 FT./SEC

Figure 3. Velocity of Sound in Various Medium

VI. Light

Units of heat measurement Methods of heat transference tanding of basic physical and chemical properties is to the study of electronics. Even the more complex c devices can be reduced to a study of electron behav or gases. To follow explanations for semiconductor for example, the technician must have a knowledge of d together to make a crystal. : Dull, Metcalf, and Williams. Modern Physics. New York, N.Y.: Holt, Rinehart, and Winston, Inc., 19 Chapter 6, pages 133-151. ON DUCTION TO THE PERIODIC CHART OF THE ATOMS any of the early scientists saw that the periodicity hythm to atomic behavior could be shown graphically. oday, the physical significance of such a rhythm is he "Periodic Chart of the Atoms" is the graphic port f this significance. As late as 1870, there were on lements known. At this time, some system of catalog he atoms was attempted. First, they cataloged by at eights. The weights of the elements were soon found ariable, depending on the number of isotopes. A lit ater, it was found that the atomic number (number of ons in the nucleus) was more stable. Even though th umber of elements known did not complete the chart, ave rise to speculation that the missing atomic numb ay be unknown elements. By 1900, the inert gases we iscovered and the chart began to fill out. In 1913, sotopes were discovered. They also fit into the rhy he chart. An isotope is a basic element with a diff tomic weight. It was simply a matter of listing all sotopes of an element under the same position on the eriodic Chart; they all have the same atomic number

sotopes of an element under the same position on the eriodic Chart; they all have the same atomic number ifferent atomic weights. Today, we have the Periodi hart in its entirety from Atomic Number 1 to Atomic 03. Refer to figure 1, Periodic Chart; there are no etween the known first and last elements, but this dot mean to say that there are no more beyond 103. E

is the number of shells. The Periodic System complete with all stable atoms discovered and a numbers and position. The outer planet system completed by the discovery of the six inert gas atmosphere, Group VIII atoms. Each row (or do ends with one of these inert atoms. II. PERIODIC CHART DATA A. Atomic symbol 1. All atoms have symbols. The "Periodic Char atomic symbols; examples are hydrogen, H; oxygen, O: and uranium, U. All elements exist in one of three physical 2. forms are solids, liquids, or gases. The each element's symbol by a color that repre form in which it is found to exist in natural not shown in figure 1). Black symbols represent solids. Some example 3. solids are carbon, silicon, iron, and gold Blue symbols represent liquids. There ae 4. known liquids; bromine, mercury, gallium, 5. Orange symbols represent gases. Some examp hydrogen, oxygen, argon, krypton, and zeno B. Atomic number The atomic number appears on the chart as black number. Refer to figure 1, "Periodi 2. The atomic number represents the number of the nucleus of the atom. Since atoms are neutral, they must contain equal numbers o electrons. Thus, the atomic number also e number of electrons in an atom. The atomithe "key" to the periodic chart. Refer to "Distribution of Electrons"; starting with which has one proton and one electron, each element increases by one proton and one el inguance by the total

or oncermose brances or

26Fe--Iron, Z = 26

54Xe--Xenon, Z = 54

a proton is added to the nucleus and an electron added to the shells, a new atom is formed. If a cron enters the nucleus a new atom is not formed. Though dead weight is added, such an atom behaves aically as before. These atoms with the same number protons but different numbers of neutrons ae called topes of the same element.

rogen (H). Shown in figure 2 are the three copes of hydrogen.

example of an element with three isotopes in

basic hydrogen atom, protium, has one proton and no crons.

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Figure 1

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alcium	2	8	8	2		62	Samarium	5	8	18	23	9	2
candium	2	8	9	2		63	Europium	5	8	18	24	9	2
itanium	2	8	10	2		64	Gadolinium	5	8	18	25	9	2
anadium	2	8	11	2		65	Terbium	5	8	18	26	9	2
nromium	5	8	12	2		66	Dysprosium	2	8	18	27	9	2
anganese	5	8	13	2		67	Holmium	2	8	18	28	9	2
ron	2	8	14	2		68	Erbium	2	8	18	29	9	2
pbalt	5	8	15	2		69	Thulium	2	8	18	30	9	2
lckel	5	8	16	2		70	Ytterbium	2	8	18	31	9	2
opper	2	8	18	1		71	Lutetium	5	8	18	32	9	2
inc	5	8	18	2		72	Hafnium	2	8	18	32	10	2
allium	2	8	18	3		73	Tantalum	5	8	18	32	11	5
ermanium	2	8	18	4		74	Tungsten	2	8	18	32	12	2
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elenium	2	8	18	6		76	OsiaLum	2	8	18	32	14	
romine	2	8	18	7		77	Iridium	5	8	18	32	15	2
rypton	2	8	18	8		78	Platinum	2	8	18	32	16	
ubidium	2	8	18	8	1	79	Gold	2	8	18	32		1
trontium	2	8	18	8	2	80	Mercury	2	8	18	32	18	
ttrium	2	8	18	9	2	81	Thallium	2	8	18	32	18	3
irconium	5	3	18	10	2	82	Lead	2	8	18	32	18	
iobium	2	8	18	11	2	83	Bismuth	2	8	18	32	18	5
olybdenum	2	8	18	12	2	84	Polonium	2	8	18	32	18	6

	85	Astatine	2	8	18	32	18	7	
	86	Radon	2	8	18_	32	18	8	
•	87	Francium	2	8	18	32	18	8	1
	88	Radium	2	8	18	32	18	8	2
	89	Actinium	2	8	18	32	18	9	2
	90	Thorium	2	8	18	32	19	9	2
	91	Protectinium	2	8	18	32	50	9	2
	92	Uranium	2	8	18	32	21	999999999	2
	93	Reptunium	2	8	18	32	55	9	2
	94	Plutoium	2	8	18	32	23	9	2
	95	Americium	5	8	18	32	24	9	2
	96	Curium	2	8	18	32	25	9	3 3 3 3
	97	Berkelium	2	8	18	32	26	9	2
	98	Californium	2	8	18	32	27	9	2
	99	Rinsteinium	2	8	18	32	28	9	5
	100	Fermium	5	8	18	35	59	9	5
	101	Mendelevium	2	8	18	32	30	9	5
	705	Nobelium	2	8	18	32	31	9	5
	103	Lawrencium	(U	nkn	own)				

second hydrogen atom, deuterium, has 1 proton and eutron. The third hydrogen atom, tritium, has 1 ton and 2 neutrons. The three hydrogen isotopes,  $^2_{1H}$ , and  $^3_{1H}$ ) given individual names to identify m. These names ae protium  $(^1_{1H})$ , deuterium  $(^2_{1H})$ , tritium  $(^3_{1H})$ . Almost all elements have more than

isotope.

Weight

atomic weight is the weighted average of the topes based on their relative abundance. The atomic ght is shown in figure 1, "Periodic Chart."

average weight of the three isotopes in hydrogen is

e average weight of the three isotopes in hydrogen in 0.797 AMU (Atomic Mass Units) (1 AMU =  $1.66 \times 10^{-24}$  kms). The figure for atomic weight is a relative liber and its only real importance is to the chemist. It atomic weight is not the same as the number of extens and neutrons in the nucleus. The mass number the number of protons and neutrons and is a whole liber.

on Shells

e orbits in which electrons must revolve about the cleus of an atom are called electron shells, or quanta

vels. The shells are labelled K, L, M, N, O, P, Q om the innermost (K) to the outermost (Q). Table I,

At this time we are not interested in the irregularities.

3. Study Table 1, "Distribution of Electrons" that none of the elements has more than two only one electron and it is in the "K" she other elements, only two electrons can eximal may occupy any given shell, use the equation first shell (K), the equation states:

shell fills first, then the "L" shell, and is not an absolute law; there are some ir

 $2(N^2)$   $2(1^2)$  2(1) = 2 electrons. The "K" shell in any element cannot contain two electrons. In the second shell (L), the

states: In the second shell (L),  $2(N^2)$   $2(2^2)$  2(4) = 8 electrons.

2(4) = 8 electrons.

The "L" shell in any element cannot contain electrons. All electrons do contain the may available to fill the shell (Z = 1 to Z = 9)

available to fill the shell (Z = 1 to Z = 9. electrons; "L" shell, 8 electrons; "M" shell "Distribution of Electrons" "M" hell

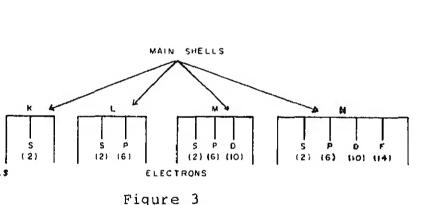
"Distribution of Electrons." The table show are distributed "K" = 2, "L" = 8, "M" = 18, trong and the last shell in germanium (N) only contain

ot take the one electron that went to the "N", we must delve deeper into the construction of the s.

L, M, N, O. P, Q shells are called the main se. Each main shell after the "K" shell is made subshells. The number of subshells (or suballs) that are present within a main shell is

in figure 3.

partially filled? An example of this is potassium, 19): notice the "K" shell = 2, "L" shell = 8, "M" = 8, "N" shell = 1. To explain why the "M" shell



in figure 3, each subshell that exists within a shell as a set number of electrons. Each one of S" subshells in any main shell contains two rons. Each succeeding subshell always has four rons more than its preceding subshell. Remember, s stated earlier that a main shell will fill, in

cases, before the next main shell begins. To be specific, a subshell will fill prior to the next ell out within a main shell. If a subshell in the hell cannot be filled, the electrons will move out e "S" subshell in the "N" main shell. An example is is again potassium (Z = 19). Refer to figure

### Figure 4

S S P S P D F

3. In the case of potassium, the "M" shell has shell full. The last electron would not ha the "D" subshell, so it was moved out to the In most cases, this will happen; this is not the law. A brief review of Table I, "Distressed Electrons", will show that a number of elem from the above. The majority do have some least through the "M" shell.

Each group or column on the "Periodic Chart contains atoms of similar behavior in verti ment, since the Roman numeral number is equ general, to the number of valence electrons

## G. Group (or column)

1.

- the properties of the atoms. The Roman num head of each column indicates the column number according to volume the grouping of the elements according to volume.
- electrons gives a ready reference to the electrons characteristics of the particular elements. elements all have a valence of one electron the "Periodic Chart", figure 1, that copper Group I; copper is a good conductor. On the end of the chart is Group VIII. Group VIII all the inert elements. Inert elements are elements whose outermost shell (or subshell shell) is full. These elements in Group VI readily combine chemically with other elements will not give up or take on electrons; thus
- 3. Groups I, II, and III are electrical conduct will readily give up an electron. These elgive up an electron in an attempt to gain a and become chemically stable.

stable or inert - good electrical insulator

shell within a shell). The breakdown of the elements can be seen by referring to Table 1. oution of Electrons." Note that the "inert" are underlined. I is the "semiconductor" group. These elements

ir electrons in their valence. They will either or give up electrons in an attempt to become lly stable. For this reason, Group IV elements ween conductors and insulators - semiconductor.

e last twenty years, literature on solid state researd. The information accumulated regarding the copper fier and germanium and silicon crystals led to the

fier and germanium and silicon crystals led to the of the transistor. A semiconductor, from which transade, is an electronic conductor with resistivity in

made, is an electronic conductor with resistivity in etween that of a conductor and an insulator. The phetransistor action is unexplainable by electron theory a new theory is used which is called hole flow. It is

transistor action is unexplainable by electron theory a new theory is used which is called hole flow. It is hat the technician have a basic understanding of solices in order to be able to understand the operation of

S. Kiver, Transistor and Integrated Electronics. New Y:: McGraw-Hill Book Company, 1972, Fourth Edition.

rg and Osterheld, Essentials of Radio--Electronics.

k, N.Y.: McGraw-Hill Book Company, 1961, Second

ction

story of the transistor is, in large measure, the story

matter and how the scientists at the Bell Telephone oratories have been able to make that matter amplify

ctric currents. If we consider the vacuum tube as mass significant advance into the field of communication the transistor must certainly be heralded as man's ond most important step.

first public announcement of the transistor was made a 1948. Thus, in terms of time, the transistor does

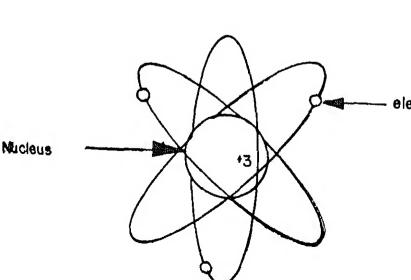
e 1948. Thus, in terms of time, the transistor does opare with vacuum tubes. In terms of application, hower, it must be classed with the vacuum tube. And while re is probably no prospect that it will completely re-

perform the same functions, but there are consi differences between the two. In order to appre differences, a study of atomic structure, intri materials, and electrical properties of semicon required. II. Review of atomic structure Any atom may be considered to be composed of a Α. located nucleus surrounded by electrons, which various orbits (see figure 1). The nucleus con neutrons, which have no electric charge, and pr are positively charged. Neutrons and protons h tially the same weight, and the combined weight neutrons and protons is referred to as the rela weight of the element. The number of protons w nucleus determines the atomic number of an elem net positive charge on the nucleus. If an atom usual atomic number, but a different atomic wei it contains an abnormal number of neutrons, it isotope.

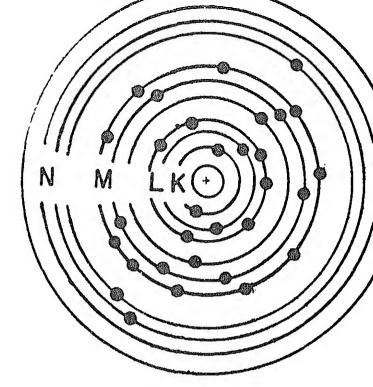
Operation of vacuum tubes depends upon the flow

trons from cathode to plate and the control of intermediate grids. Operation of the transisto dent upon electron and hole flow. These two de

Ο.



. Conv r orbit e elect etc.) t ectron	versel t will tric f the to will	ly, an elect absorb ending the description of the d	ctron ex nergy. gh tempe y of an com the	cited f If by s ratures electro parent	rom an ome median is i atom.	inner ans ation, ncrease Under	to
		n found to 2 and the					
in She	11			Sub S	<u>hell</u>		
К	2	electrons		2	elec	trons	
L	8	electrons		s 2	р 6 el	ectrons	3
M	1.9	electrons		s 2	p d 6 10	electi	rone
N		electrons		s 2	p d 6 10	£	. 0111
N	32	elections		2		trons	



A two dimensional representation of the mann which electrons are distributed about the nu of a germanium atom.

Electrical and chemical activity of a materia

in the excitation level because of thermal agwe shall see later, this is one of the most s

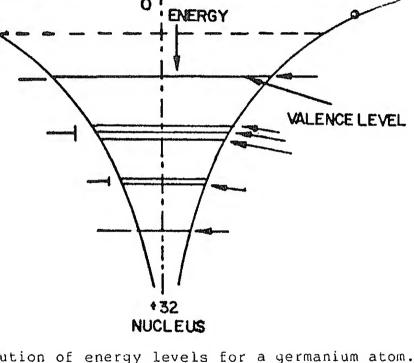
# Figure 2.

stricted to the electrons in the outer shell. shell of an atom is called the valence shell occupying orbits in these shells are called velectrons. Unfilled orbits lying above the vare called excitation levels. Imparting suffice an electron may cause it to jump into an elevel. The applied electric field may cause by a displacement process toward the region of tive potential. Actually, at temperature above, there will be some probability of findi

Ŀ.

electrons. Silicon has an atomic number of 14, eans there are 2 electrons in the K shell, 8 in the A in the M shell; therefore, silicon has 4 valence as. A plot of the total energy of an electron as tance from the germanium nucleus increases, is shown se 3.

DISTANCE -

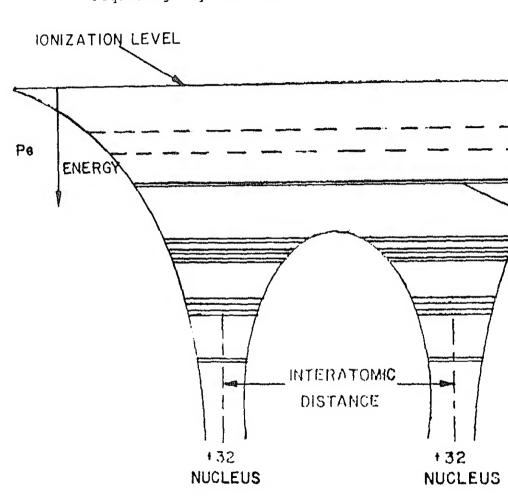


ENERGY LEVEL

ucton of energy levers for a germanium acom.

Figure 3.

counterpart in the other atom has a slightly of energy level, and they can switch levels continuous in figure 4 that the valence and excitate common to both atoms. This means a valence e atom could travel to another and vice versa w requiring any external energy.



when two similar atoms are brought together, a action occurs which permits additional levels.

Figure 4.

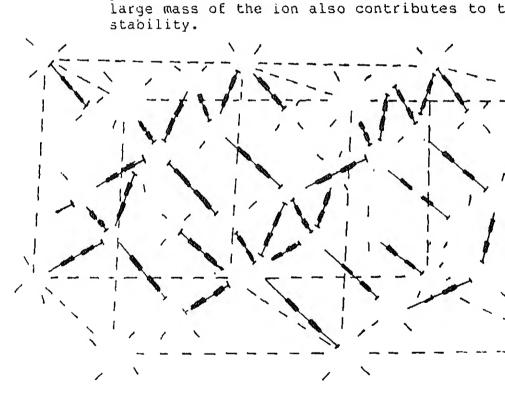
applied to the crystal of figure 5, electrons must be accelerated in order to change their total energy. В because of their discrete behavior their total energy increase only if they can be excited into a new level in a crystal, the valence band is completely filled, duction can occur only when sufficient stimuli is imp to raise some electrons from the valence band to the duction band. Here there are many levels through whi electron may be accelerated. Note that accelerating electron from the valence band into the conduction ba leaves a vacant level in the valence band. This mean electrons can now accelerate in the valence band. Th vacant level left in the valence band is a hole. N LEVEL CONDUCTION BAND ENERGY GAP VALENCE BAND/

The various valence levels form the valence band. The first excitation levels are lumped into the conduction band. For conduction to occur when an electric field

covalent bonds bind the germanium atoms intorderly, geometric pattern within the cryst

2. Figure 6 is a simplified illustration of the arrangement of a crystal structure. The in of each atom has an overall positive charge locked into the structure in an orderly man ion is repelled by the similarly charged su ion from various directions, thereby stabil positive of the ion in the structure. The

electron sharing is called covalent bonding



Pure germanium crystal, lattice structure.

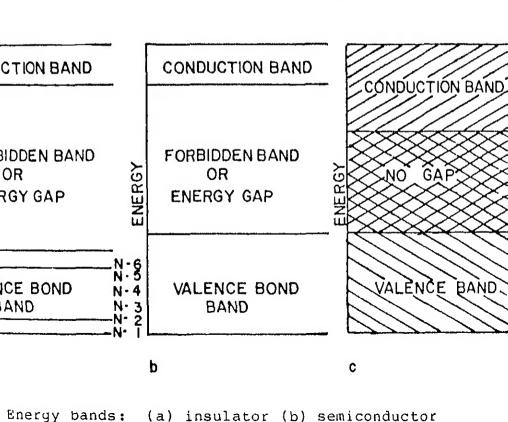
Figure 6.

Materials may be broadly classified as insusemiconductor, or conductors according to the second conductors.

# Insulators

a. An insulator may be defined as a material which offers high resistance to the flow of electrons. The basic reason for offering such a high opposition to the flow of electrons is that free electrons are relatively scarce in such materials. referring to figure 7(a), which illustrates the energy diagram of an insulator's valence and conduction band, it can be seen that the energy gag wider than that of the semiconductor and conduct The energy levels within the insulator's valence band are filled, and the energy levels in the conduction band are empty. This means the valence electrons have very little opportunity to understand the electrons have very little opportunity t

changes from one valence energy to another.



5. Semiconductors--Figure 7(b) is the energy semiconductor. The energy levels within band are filled, as in the case of insulvalence electrons have very little opposed

motions, and virtually no mobile eleavailable for participation in the o

valence electrons have very little oppositions of the valence band, since vacant levels. The forbidden gap between and conduction band is not as great as insulator. The probability of valence acquiring the necessary increment of the better, since smaller packages of thermal

process.

- insulator. The probability of valence of acquiring the necessary increment of the better, since smaller packages of thermal required. This energy gap, at room tempabout 0.7 eV for germanium and 1.2 eV for Because of the lower height of the forbigap, semiconductors have resistivity lowers, but considerably higher than condi
  - difference.
    6. Conductors The energy diagram of a continuous figure 7(c). Notice the overlap between the conduction levels and lower conduction levels.

electron volt (eV) is the Kinetic energy electron when accelerated through a one-

valence levels and lower conduction lever electrons, in such a material, require increments of thermal energy to be excisonduction level. The probability of the occurring at room temperature is very homaterial displays low resistance (high Such is the condition which exists in metal displays low resistance)

\*Conductivity is the reciprocal of resistivity; or,

conductors.

e impurity content would have to be less than 1 part i mewhat larger impurity concentrations than these is st metimes referred to as intrinsic. temperatures of absolute zero, intrinsic germanium or licon can be shown as it is in figure 6. All of the lence electrons are tightly held by the parent atoms a so, through the covalent bonds by other atoms. The ectrons are not free to move through the crystal struc

astically alter their electrical properties. For this ason, a semiconductor would not be called truly intrin less the impurity level is very small--for germanium 1 an 1 part impurity in 108 parts of germanium; for sili

re and, thus cannot conduct electricity. For this ason, an intrinsic semiconductor at absolute zero beha ke an insulator. It is a very poor conductor of ectricity. nsider what happens as the temperature is increased. crease in temperature means an increase in the heat er

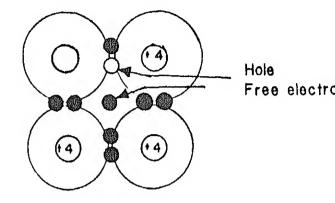
each atom. This increase in energy may be given to o the atom's valence electrons. By this process, a val ectron may acquire sufficient energy to break away fro s parent atom and, in so doing, break one of the coval nds. This electron is now free to wander through the ystal structure and is not bound to any particular ato

is called a free electron and can now act as a currer rrier if a voltage is applied to the material. A curi rrier is simply any charged particle (such as an elect ich is free to move as part of an electric current if urce of voltage is applied.

t what happened back at the place where the electron ! s parent atom? It left behind a vacancy or an incompl gure 8 shows the crystal structure with one free elect

valent bond, which is usually referred to as a hole. d one hole brought about by the electron breaking away om the parent atom. This process of the formation of

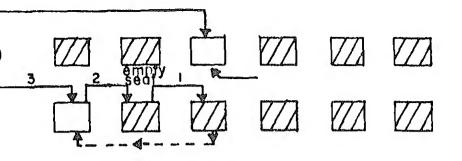
ectrons and holes is called thermal generation.



Creation of a free electron and a hole caus by an increase in crystal temperature.

Figure 8.

E. The interesting thing about a hole is that it current carrier. If a hole is created by an expreaking away in one atom, an electron from a atom can easily fill the hole by breaking its bond and jumping over to the first atom. When it appears that the hole has moved. If you had an electron at B, when the electron fills it leaves a hole at B. Thus, in effect, the from point A to point B. This can be illustrated sidering the situation when you arrive late as and find the only vacant seat is in the center (see figure 9).

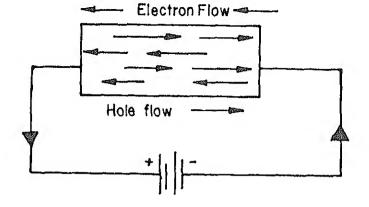


Hole movement.

Figure 9.

you can become a "free electron" and go along the row ou get to the "hole" or the people in the first two an move in sequence one seat to the right and make the move to you at the end of the row.

a hole exists there is a net positive charge the +4 charge of the parent atom (nucleus and innerlectrons) is greater than the -3 charge of the three ng electrons. Thus, we consider the hole as having, ct, a positive charge. When the hole moves, there is of positive charge. A voltage is applied to a semior containing free electrons and holes, the free ns will move from negative to positive, and the holes ve from positive to negative. Remembering the disof hole movement, you can see that a hole moving to ht is really an electron moving to the left. Thus, w of holes from positive to negative is really the the flow of negative charges (electrons) from e to positive. You can think of current in a semior as consisting of two parts; free electrons moving opposite direction. To get the total current, you d the two parts. Figure 10 is a representation of w of charges in a semiconductor.



The flow of charges in a semiconductor due to an applied voltage.

# Figure 10.

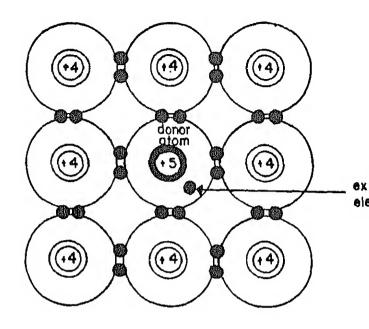
The flow of charges in a semiconductor due to an a voltage. NOTE: There is no hole flow external to conductor. Current flow in a conductor is by the of free electrons.

You may be wondering what happens to the holes whe

reach the edge of the piece of semiconductor mater B in figure 10). The answer is that some of the coming from the negative battery terminal combine fill the holes so that both the holes and the fill electrons disappear as charges. This process is combination. The rest of the electrons travel the semiconductor as free electrons. The electrons lead of the two categories: those who at B and traveled through the crystal or those who freed within the crystal when the holes were formed.

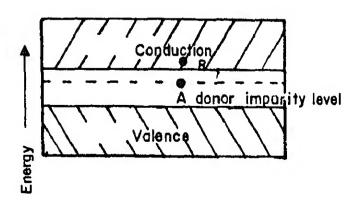
ons have enough energy to move freely through the cry thout being tied down to any atom. u can see from this that the free electrons are able we faster through the crystal than the holes, which h move in a succession of jumps. We say that the free ectrons have a higher mobility than the holes. ordinary room temperature (approximately 25°C), the ermal energy is sufficient for a large number of free ectrons and holes to exist in an intrinsic semiconduc room temperature intrinsic semiconductors such as ge nium and silicon are fair electric conductors, being orer conductors than a metal such as copper, but much tter conductors than an insulator such as rubber. An portant characteristic of an intrinsic semiconductor at is possesses a negative temperature coefficient (r stance decreases with a rise in temperature); therefo onductivity increases with an increase in temperature. is is true because of the increased thermal agitation gher temperatures; therefore, there are more free ele ons and more holes created. In an intrinsic semicond th no applied voltage, the total number of free elect quals the total number of holes. (extrinsic) semiconductors actical semiconductors contain traces of impurities eliberately added to the material after the natural spurity level has been reduced to a negligible degree. ne types of added impurities fall under two categories . Elements containing five valence electrons (Pentava Elements containing three valence electrons (Trival ne effects of each type upon the energy and electrical naracteristics of germanium will be examined. ne donor or N-type crystal . There are a number of elements possessing five elec in their outermost shells which are chemically comp

become really free. On the other hand, the free elec-



The addition of an N-type impurity ato produces one free electron.

Figure 11.



Energy distribution in donor-type german

temperature is approximately 0.026 eV.

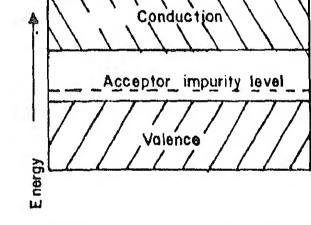
A crystal containing an impurity whose atoms posse five valence electrons is called a donor crystal, it readily donates electrons to the conduction pro-The conduction which occurs because of these mobilelectrons, when an external electric field is appl

is called extrinsic conduction, as opposed to intr conduction which is due to electrons that are elevto the conduction region from the valence energy Because of the great difference in energy requirement between the two types of conduction, extrinsic contion occurs at a much lower temperature than intri conduction (where the increment of energy must be least as high as the forbidden energy gap). At a temperature the conductivity of the donor crystal higher than that of a pure crystal to an extent de mined by the number of impurity atoms added. The carriers of charge in this type of material are ne tive, hence the term N-type crystal. acceptor or P-type crystal hole

> captured electron

more electron than it should normally have negative ion. This extra electron must be distance form the gallium nucleus than the valence electrons and is therefore closer band in terms of energy. The energy level electron is immediately above the valence in figure 14.

arrangement, and any such three-valence el "acceptor" atoms. When the gallium atom r



Energy distribution in acceptor type ge

Figure 14.

B. Notice that only a small increment of ene (0.01 eV) to excite a valence electron in impurity energy, since this level is closband than the conduction region. This ac

even at low temperatures, where relativel electrons are thermally excited across the energy gap. Each valence electron excite impurity level leaves a vacancy (hole) in

pand, so it is possible for valence elect covalent band and move to another with th

semiconductor. Actually, the major cariers of charge s material are positive, hence the term P-type nductor. rical properties of semiconductor materials ivity e electric resistance of a piece of material depends its atomic structure; on the material length; and on s cross-sectional area. Resistance can be expressed

Treind courre our negaciae ecrutivat or one evectivat ial. Within the extrinsic range of temperatures, at intrinsic conduction is negligible, the significant n of conduction occurs by this hole current in the

 $R = \frac{PL}{\Delta}$ 

thematically as:

ere R, L, and A are resistance, length, and cross-

ctional area, respectively, and P is the resistivity pecific resistance) of the material. The reciprocal resistivity is conductivity. Resistivity is a asure of the degree that a material opposes the flow

electric current, and conductivity is the degree that material allows current to flow. A material which

hibits a high opposition to current flow is said to ve a high resistivity. The same material could also said to have a low conductivity. e manner in which a semiconductor device behaves in ar

ectronic circuit depends greatly on its resistivity, ich can be controlled over a wide range. The value of sistivity (or conductivity) of a semiconductor depends : the charge on each carrier; the concentration of rrent carriers (holes and electrons); and the carrier bility (ease with which carriers may be moved).

e charge on a hole is always +1 and the charge on a ee electron is -1. These values cannot be changed. us, carrier concentration and carrier mobility are the operties that may be changed to alter resistivity.

neral, it is desirable to make carrier mobility as gh as possible. This leaves carrier concentration as When a semiconductor is exposed to a tem absolute zero, some of the heat energy a material may be acquired by an electron, the conduction band and leaving behind a produces two charge carriers: one hole electron. They are said to have been the generated. As long as the material is e temperature, the free electrons and hole continuous random motion even though the current flow.
 This may be likened to a swarm of bees a Each bee moves rapidly from place to pla but if no new bees are arriving and none the net flow of bees is zero, although t continuous motion.

Thermal generation and recombination

В.

3.

free electrons is equal to the number of value of the free-electron concentration concentration) in an intrinsic semiconducthe intrinsic carrier concentration. The creases exponentially with an increase in

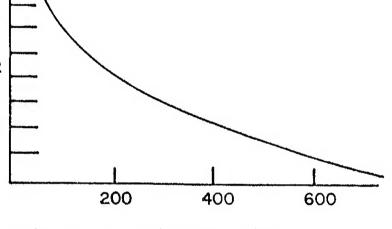
the forbidden energy gap in the crystal. recall that germanium has a smaller ener silicon. Consequently, at a given tempe thermal generation rate will be higher i in silicon, because it takes less energy electron from germanium's valence band the band.

The rate at which hole-electron pairs ar erated depends on the temperature and on

- 4. As a free electron moves randomly throug structure, it may encounter a hole and by valence electron. When the electron combole, the hole no longer exists and the
- longer free; hence, two carriers cease to process is called recombination.

  5. The rate at which recombination takes pl
- the number of holes and free electrons i

vity will decrease (conductivity will increase) re carriers are present to conduct current. ntrinsic carrier concentation increases with ture, resistivity decreases, and conductivity es. A typical plot of intrinsic resistivity temperature is shown in figure 15.



Variation of resistivity with empeature for intrinsic silicon.

Figure 15.

rs.

cinsic semiconductors, the number of free election not equal to the number of holes. In N-type als, each donor atom contributes a free electron contributing a hole. The only holes present are produced by thermal generation. The thermally ted holes are called minority carriers. Siminin P-type materials, the only free electrons are those thermally generated, and the number of present is equal to the number created by the or impurity plus the number generated. The ally generated electrons are called minority

increased, the concentration of thermal carriers may become comparable with the impurity-produced carriers, and the respectome temperature-dependent. If the semiconductor is increased to such an exthermally generated carriers greatly of impurity-produced carriers, properties will be mainly dependent on the internation generated carriers, and the material with intrinsic.

10. Resistivity of extrinsic germanium or a temperature is determined almost complete.

amount of impurity present in the mater limits, any desired value of resistivity

by adding the correct amount of impurit formation of the crystal.

C. Mobility

- 1. It hs been stated that mobility is a me with which the carriers can be made to material. It is measured as the rate carrier (in centimetes per second) per field (1 volt per centimeter). Thus, references
  - dimensions centimeters per second dividentimeter, or cm<sup>2</sup>/volt-sec.

    2. Although mobility does not appear to be
  - from resistivity considerations, it plaimportant role in the behavior of semi-In semiconductors, the mobility of the greater than the mobility of the holes
  - it is easier to move a free electron i band than it is to move a bound electron the valence band. (Keep in mind that electrons in the valence band from holbrings about the movement of holes.)
    - brings about the movement of holes.) can be made to move by the application idea of "hole mobility" is not unreaso

c Resistivity	65	200,000	ohm-cm
ap	0.7	1.1	eV
rinsic propertie Silicon at room			
TABLE	1.		
several factors re of the crysta move has the pre imperfections in arrier motion. all atoms are i oms are present. the structure and tions exist in a is retarded and	l strucedominathe crif the ntheir The cd mobil	ture through the effect. Are ystal lattice structure is proper place sarriers can all ity is high.	which the my impuri- e tend to perfectly es and no move easily However, if ent of
is retarded and			i. The types

ility 1,900 500 cm<sup>2</sup>/volt-sec

fections that can exist in a crystal structure too numerous to delve into at this time. it to say that one of the most important steps anufacture of semiconductor devices is the of crystals with as nearly perfect lattice e as possible. ure is another factor that affects mobility. At eratures, atoms in the crystal structure tend to their regular places. As temperature is d, energy is added to the crystal. Some of this s used to excite the electrons to the conduction t some of it is also given to the atomic cores, them to move very slightly. Although the cores ove away from their positions, they do vibrate ut of position much as a violin string vibrates leaving the violin. This vibration has the f impeding carrier motion.

## D. Diffusion currents

3.

- It has been determined that if a voltage
  - piece of semiconductor material, the hole negative terminal and the electrons to the terminal. The combined effect of this mand electrons constitutes a current.
  - 2. It is possible for a current to flow in a even in the absence of an applied voltge tration gradient exists in the material. tration gradient occurs when the concent type of carrier is greater in one part of ductor than it is in some other part.

When a concentration gradient of carriers or free electrons) exists in a material,

Consider a small bar of P-type semiconduction

tron gradient exists. The excess electr

- tend to move from the region of higher contraction. The said to diffuse from the region of high and the current produced by this movemen diffusion current.
- which the charges are evenly distributed length of the bar. The concentration of electrons are in equilibrium and no grad Suppose that a large number of electrons carriers) is injected at one end of the is accompolished will be discussed in PN theory.) These added minority carriers concentration of electrons at the end wh injected than in the rest of the bar. H
- toward the other end of the bar, attempt uniform distribution throughout the bar. results in a diffusion current. The rat electrons diffuse, and hence, the diffus depends on the value of the gradient and of the electrons.

combination is called the <u>Lifetime</u> of the excess riers.

have seen that two distinct things occur when excess crity carriers are injected into a material. The riers diffuse and they recombine with the opposite-exarriers. Consider these two occurrences simultated by Imagine, again a high concentration of free extrons injected at one end of a P-type semiconductor. The electrons diffuse toward the other end of the and, at the same time, recombine with holes. As any move along the length of the bar, more and more of the disapper by recombination. Eventually, all of the

ess carriers disappear by recombination. The length time required for the excess carriers to disappear by

and, at the same time, recombine with holes. As y move along the length of the bar, more and more of m disapper by recombination. Eventually, all of the less electrons will disappear, but in the meantime by have moved along the bar; the distance the ectrons move before they disappear is called the fusion length of minority carriers. If excess holes injected into an N-type material, the holes will lergo the same sort of process as free electrons.

I can see that the diffusion length of minority riers in a material depends on how fast the carriers and on how long they move before disappearing; that diffusion length depends on mobility and lifetime.

been brought out in the information sheet, "Introto Semiconductors," that when a voltage is applied miconductor, current flow is brought about as a of holes moving toward the negative terminal and ons moving toward the positive terminal (see figure Hole flow

+ | | - |

The flow of charges in a semiconduction

due to an applied voltage.

Figure 16.

The total current is the sum of the currence flow and the electron flow. It is current. A second current may exist in This current, called diffusion current, result of a gradient of a carrier concendiffusion current may also be due to bot flow. The hole and electron flow is in

and the total diffusion current is the s

A material which contains an equal numbe

negative charges is said to be electrica Objects which are electrically neutral delectric charges. An ordinary atom is esince it has as many negative charges (epositive charges (protons). When an atom it is left with a net positive charge and tive ion. When an atom gains an extra enet negative charge and is called a negative charge and is called a negative.

В.

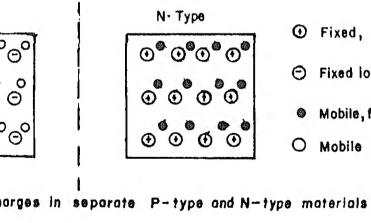
C. A sample of semiconductor material is no neutral since it is made up of atoms whi electrically neutral. Although a free e away from the atom (leaving a positive i inside the semiconductor material, the s electrically neutral. If a current flow due to an applied voltage, electrons are the material at the positive terminal an electrons are entering (at the same rate terminal. The semiconductor remains eleduring conduction when considered as a

ever, if for some reason, a semiconducto

l difference (or voltage) will exist between them. an N-type semiconductor such as silicon. Each atom consists of a core with a net charge of +4 and ence electrons, each with a charge of -1. Thus, the atom is electrically neutral. Each donor atom has a h a net charge of +5 and five valence electrons each egative electrons. In a similar way, P-type silicon

and another object becomes negatively charged, a

harge of -1. Only four of these valence electrons in bonding with the silicon atoms. The fifth is free to wander around. As it moves away from r atom, it leaves behind a positive ion with a net f +1. The positive ion is not free to move, as it in the crystal structure. Thus, an N-type semir is studded with immobile positive donor ions and egarded as a neutral material studded with immobile acceptor ions and mobile positive holes. Figure 17 tes the charge distribution in separate P-type and amples. N. Type • Fixed, ionized donor atom.



Fixed ionized acceptor atom

O Mobile hole.

Mobile, free electron.

s in separate P-type and N-type materials.

Figure 17.

con atoms are not shown and should be imagined as a us crystal structure over the whole background. The it will allow current to flow through i direction.

Ε.

assuming that we can merely push the tw form the junction.) A completely diffe ditions will now exist. In the P regio concentration of holes. Since the hole P side is so much greater than that on will diffuse into the N region. The di similar to the uniform distribution of glass of water after an ink drop has be ink molecules try to distribute themsel technical parlance, we say that a hole gradient exists from the P to N region. electron concentration gradient exists region and results in electrons diffusi tion. See figure 18. 4 | I | P- Type

> SPACE Charge

we now turn to the condition of the mat

the junction is formed. (We shall take

niently represented by a battery placed across the nction as shown by the dashed lines in figure 18. e holes that cross from the P to the N region recombin th electrons on the N side. Simarly, electrons from t region recombine with holes on the P side. This flow oles from the P to N side and electrons from the N to t side constitutes a recombination current across the nction. This recombination current does not, however, ersist at some constant value. Instead it falls to some ery low value vicinity of the junction. The uncovered egative ions on the P side start repelling the electron om the N side while the wall of uncovered positive ion the N side repels the holes from the P side. The bat figure 18, therefore, represents the barrier potentia et up by the uncovered charges, which inhibits the reombination currents. Thus, it seems that a condition quilibrium is established between the diffusive potenti the concentration gradient, the barrier potential of oncentration gradient and the barrier potential of the covered charges. thermal agitation caused all the mobile carriers to ? eactly the same kinetic energy, this simple explanation

unneutralized positive ion. These unneutralized, imm le ions on each side of the junction are called uncove larges, and the electric field between them can be con-

quilibrium conditions at the barrier would suffice. Ho ver, the thermal energy impaired to the mobile charge arriers is randomly distributed. Statistically speaking ome holes and electrons have only a small amount of kin nergy whereas others have a very large amount. Some of igh energy carriers will, from time to time, be capable

vercoming the barrier potential. If this were the only

ction, it would seem that the barrier height would keep ocreasing in an effort to compensate for those high-energy arriers that manage to hurdle it. Ultimately, we might spect the last of the mobile charges to cross the barr eaving some large barrier potential.

which, in turn, is determined by the number of atoms introduced into the lattice.

J. If this electron in the P region survives long drift into the vicinity of the junction, it wil the influence of the electric field existing the direction of the field is such that the electron

carrier, and it will have some average time of lifetime) before it combines with one of the nu available. The lifetime of a minority carrier depends upon the number of surrounding majority

swept across the depletion region (region conta uncovered charges) since it is attracted by the positive ions on the N side. Another way of vi this is to imagine the barrier battery in figur

applied, the actual equilibrium conditions are There will be a net recombination current acrostion which consists of holes climbing the barri

K. By similar reasoning, we see that a thermally g in the N material constitutes a minority carrie be swept across the depletion region from the N side. The flow of thermally generated minority across the junction is aided by the potential b
L. We now have a complete picture. With no extern

electrons from the P to the N side.

- P to the N side and electrons which climb the bethe opposite direction.

  M. At the same time, the breaking of covalent bond a net thermally generated current because the m
- a net thermally generated current because the macarriers are swept across the barrier. The the erated current (minority) depends solely upon the macarrier of the second solely upon the second second solely upon the second seco
- erated current (minority) depends solely upon the net result is that the total junction current which it must be, since shorting a PN junction of wire does not result in a gurrent flow throw

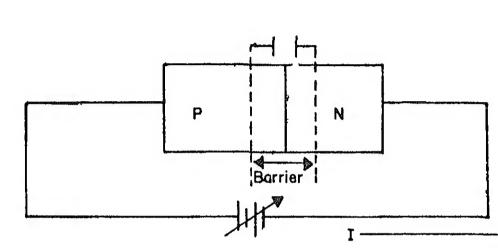
of wire does not result in a current flow through the barrier height will assume a potential of sthat it permits the recombination current to just thermally generated current.

narrower.

ward bias

Consider that an external source of potential is conr
to the PN junction, as illustrated in figure 19.

and acceptor atoms. Overall, the barrier will become



The PN junction with forward bias permits

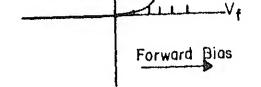
large amounts of current to flow.

Figure 19.

Placing the voltage source across the diode causes as electrical field which opposes the barrier potential

(positive to P-type and negative to N-type material) established through the semiconductor. This is known forward bias. The net effect is that the height of barrier is reduced. For convenience, we might think external source as trying to push holes from the P tergion and electrons from the N to the P region. The mechanism involved is, however, not one of pushing by

merchanism involved is, nowever, not one of pushing of merely controlling the net barrier potential. If we the source from one potential to a higher potential, shall find that the current increases quite rapidly some exponential curve. (Refer to figure 20.)



Forward bias characteristics.

Figure 20.

What is happening is that, in reducing the barried the recombination current greatly increases because holes from the P region and electrons from the N cross the junction and recombine. The thermally current does not significantly change, for it is determined by the temperature and not the voltage in the forward bias case, recombination current if greater than thermally generated (minority) current.

- B. We might be tempted to think that putting a volt across the junction would annihilate the barrier an enormous current flow. This does not occur be the current increases, more and more of the applicis used up as a voltage drop across the bulk of tregions. The barrier can be reduced but not destruction of the semiconductor materials due to dissipated in it.
- C. Once the internal barrier potential is greatly rethe applied forward bias voltage, the current bed limited, only by the source resistance of the appsource, the junction lead resistance, and the bulk tance, and the bulk resistance of the semiconduct materials. The semiconductor material resistance amount of doping, cross-sectional area and length bulk resistance (about 1 to 200 ohms) can cause ecurrent flow; therefore, a current limiting resistance placed in series with the semiconductor under bias conditions.

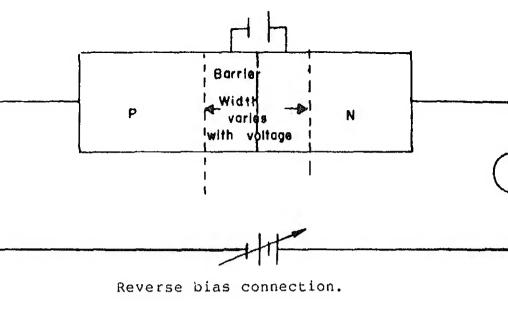


Figure 21.

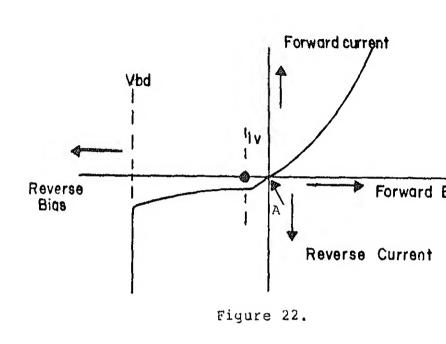
d the internal potential barrier in keeping carriers cossing to the junction. Mobile holes in the P region away from the junction toward the negative batter; arminal. Mobile electrons in the N region are also draway from the junction toward the positive battery term he more reverse bias that is applied, the wider the detection region grows. If, as is usually the case, the sides are unequally doped, the depletion region will end further into the region of higher resistivity (matches the least doping). This is easy to understand if we isualize the P and N regions are two resistors in series larger percentage of the applied voltage will appear cross the larger resistor. This effect is important in

ransistors, for it results in a condition known as pun-

arough.

n this case, we see that the field established through emiconductor by the external battery is such at it ten

of reverse bias, the recombination curruent is and current essentially equals the thermally currents (minority).



C. As the reverse voltage is increased, it seems reverse current remains constant since it is a ture and not voltage dependent. However, the that between -.1 volt and Vbd (voltage breakde reverse current actually increases with revers Such a characteristic should be expected if the leakage resistance in shunt with the junction resistance is due to dirt or other impurities junction and little understood surface effects.

tribute to leakage resistance.

ery 6°C rise. Even though this is a a more rapid inease than for germanium, the initial value is so low t licon is generally preferred for high temperature work 100 C. e breakdown the reverse voltage across the junction is gradually creased, a point is reached where the reverse current arts to increase rapidly. This incease may be exceedi rupt in silicon junctions. The breakdown characterist indicated at Vbd (voltage breakdown) in figure 22. tice that Vbd stays essentially constant for large var ion in current. This is characteristic of a constant ltage source and is the basic principle on which the oltage-regulating" or zener diodes operate. e sudden increase in current may be the result of eith two mechanisms. First, if reverse bias is sufficient creased, it is possible for the electrical field in th cinity of the junction to b ecome quite strong - so rong, in fact, that electrons are suddenly pulled out valent bonds when Vbd is reached. This phenomenon is own as zener breakdown. e second and more common type of breakdown, called alanche breakdown, is due to a secondary emission effe nority carriers produced by covalent bond breakup, are celerated across the junction by the reverse bias. Wh verse bias approaches a critical value, the minority rriers have sufficient velocity to knock apart covaler nds of atoms they collide with, and these in turn brea her bonds, and so forth. The consequence is that a emendous increase in the number of current carriers sults which make the semiconductor material and juncti pear to have a low resistance. ode reverse current in the breakdown region should be mited by an external resistance if reverse bias is to ual Vbd. The diode will not be barmed if the current

e energy gap in silicon is higher than in germanium an erefore, at a given temperature, fewer electrons are cited out of covalent bonds into the conduction band. lue of minority current in silicon roughly doubles for

- likened to the dielectric of a capacitor. bordering the depletion region have good because of the presence of charge carrie be compared to the plates of a capacitor of the depletion region is controlled by
  - tne reverse voltage, here is a capacitor depends upon the junction voltage. The varies with the method of fabrication of typical values range from 3 to 100 pF. In the recent years some manufacturers o. devices have made voltage-sensitive capacities
- available. They have found extensive app electronic equipment, particularly in the cations, as oscillator frequency control

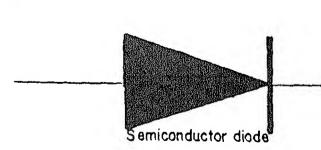
## XII. Diode symbols

В.

these are stated here. (Refer to figure Figure 23 shows schematic representation в. dioge. The arrowhead of the drawing wil

Some facts hold true of all semiconducto

- anode. The anode will always be the P-t cathode will always be the N-type materi
- C. In order to forward bias the diode, the positive with respect to the cathode. T diode, the anode must be negative with r cathode.



Semiconductor diode.

Figure 23.

Kiver. Transistor and Integrated Electronics.
NY.: McGraw-Hill Book Company. 1972, Fourth Edition. and Osterheld. Essentials of Radio-Electronics.

NY .: McGraw-Hill Book Company, Inc., 1961, Second

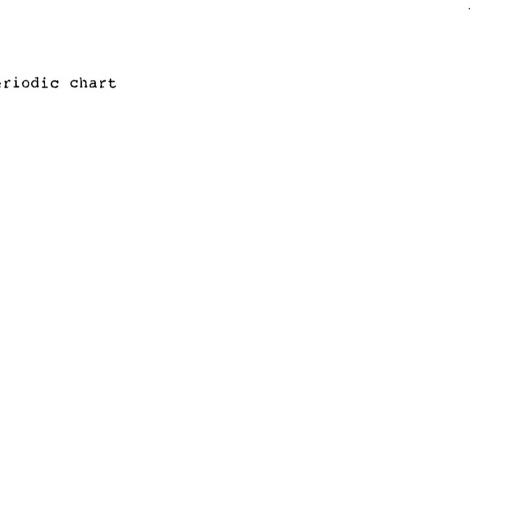
Metcalf, Lefler, and Williams. Modern Physics. NY.: Holt, Rinehart, and Winston, Inc., 1968.

LINE:

structure

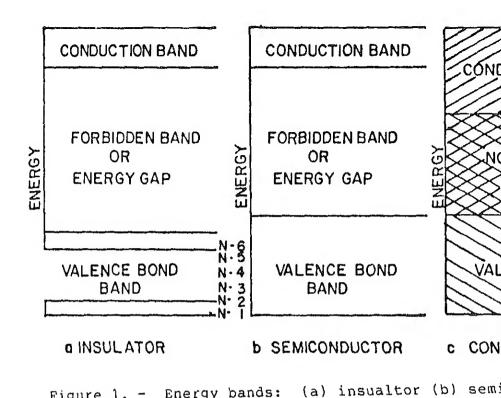
neral information

e atom



F. Energy levels of isolated atoms

bands



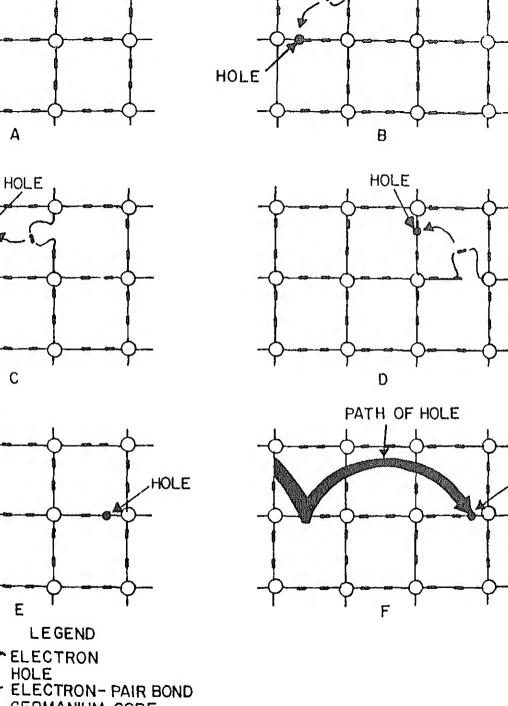
Energy bands:

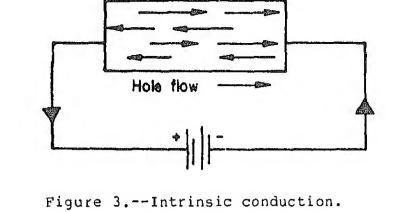
conductor

(c)

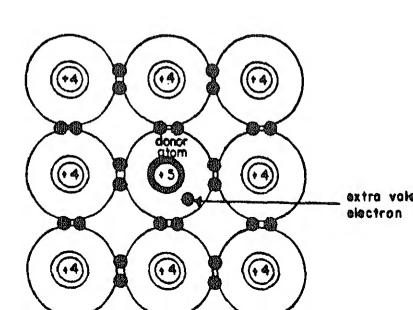
Intrinsic materials II.

Figure 1.





III. Extrinsic materials



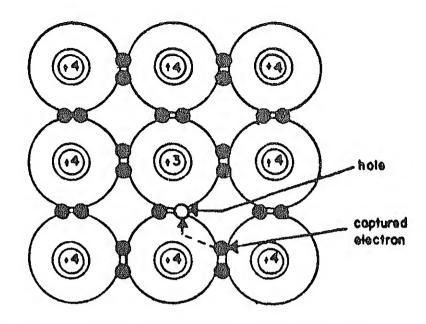
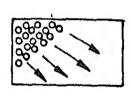


Figure 5.--P-type semiconductor material.

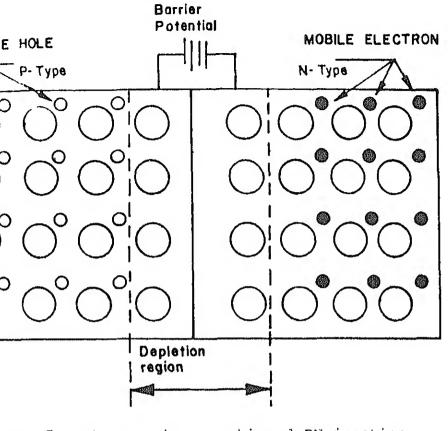
rical properties of semiconductors



Concentration Gradient



Figure 6.--Diffusion.



gure 7.--Charges in an unbiased PN junction.

rse biased PN junctions

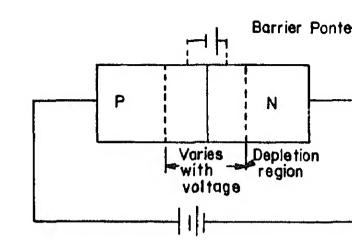


Figure 8.--Forward biased PN junction

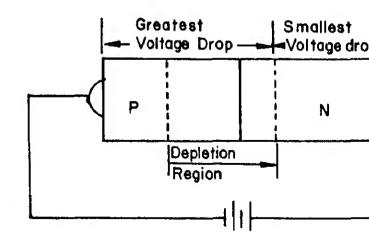
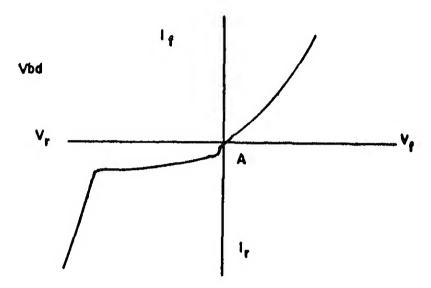


Figure 9. -- Reversed bias PN juncti



re 10.--Reverse bias versus reverse current.

e Symbology and use

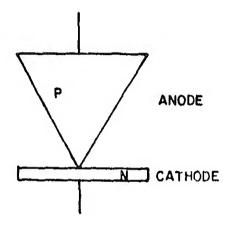


Figure 11. Diode symbology

d reverse-biased PN	junction:
e table 1, entering d.	d-c measurements in spaces
ORWARD BIAS	REVERSE BIAS
IB	+V <sub>BE</sub> I <sub>B</sub>
ν	+0.1 V
v	+0.5 V
v	+2.0 V
TABLE 1	
e the following graph ble 1.	oh, using the information obta

the data sheet is for you to record the effects of erse bias on a PN junction and the effects of

nges on current flow through the junction.

	(b) State the effect of removing heat	
	tion with respect to minority curr	
đ.	3	
	(1) Forward-bias resistance at -0.2 V	
	(2) Reverse-bias resistance at +2.0 V	
е.	Questions (Fill in the blanks.)	
	(1) The major characteristic of a PN junct	
	biased is low/high resistance	
	(2) When reversed-biased, the PN junction	
	very low/high	
	(3) When temperature increases, the amount	
	increases/decreases	
	(4) If not controlled, what effect will a	
	in temperature have on the PN junction	

respect to minority current carrier

at you as technicians acquire an understanding of
The main purpose of this information sheet is to gi
the fundamental principles of transister action.

dic-Circuits, NAVSHIPS 0967-00-0120, pp. 5-10 to 5-20.

ls of Radio-Electronics, Slurzberg & Osterheld, McGra

or and Integrated Electronics, Kiver, McGraw-Hill Co.

, 1961 2nd Editioin.

leased artitization of fransistors, it has become

TION

The advantages of using transistors are well known as

The advantages of using transistors are well known an need only cursory mention. Chief among the advantage are the small physical size and the extreme ruggednes the transistor. Although designed to perform many of functions of the vacuum tube, this device requires no filament power and operates with very low bias voltage. Although the disadvantages of the transistor are steadeing diminished, present limitations to its use exist There is still a basic limitation on the power handli ability, and the temperature dependence of its charactistics are often a challenge. The low resistance of

Although the disadvantages of the transistor are steadeing diminished, present limitations to its use exist There is still a basic limitation on the power handli ability, and the temperature dependence of its characteristics are often a challenge. The low resistance of transistors to radiation fields is another disadvanta With the increased utilization of transistors, it has become essential that technicians acquire an understanding of transistors. The main purpose of this information sheet is to draw forth the fundamental principles of transistor action.

external load where useful work could be perfigure I could be considered an active circuits ability to amplify power. The transfer across two resistance ratios gives rise to transistor, and is the basic analogy of transistor.

 $E_o = 10V \frac{1}{T} P_I = 12R_I$ = 1 X10 = 10 WATTS

RI = 10 1

P2 - I2 R2

= 12 X 1000 = 1000 W

POWER GAIN = P2

- 2. It is suggested that the reader review figure operation before continuing, and keep in mitthe analysis of transistor action that in form transistor action consists of:
- a. Transferring approximately the same cur unequal resistances.
  - b. Utilizing the power developed across the resistance to perform some useful work.

C. Transistor analysisl. In your previous lesson on junction diodes,

action.

REVERSE BIAS FORWARD BIAS MINORITY CARRIERS Conditions existing at a forward and reverse-biased PN junction. Further observation of figure 2 reveals that the PN junction biased in the reverse direction is equivaler a high resistance element (low current for a given voltage). Notice also that as the reverse bias voltage increases, the minority current remains relatively co tant until avalanche is reached. Thus, it can be see in figure 2 that: The amount of current flow through a forward-bias a. junction is primarily voltage dependent. The amount of current flow through a reverse-bias ъ. junction is not voltage dependent, but primarily dependent upon the number of minority carriers is

CURRE

JUNCTION

MAJORITY CARRIERS

UFAFK2F DIVZER

JUNCTION

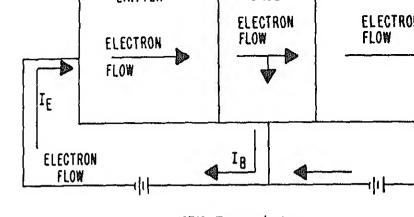
dependent upon the number of minority carriers i P-and N-type materials.

Applied logic at this time will reveal the transistor

Applied logic at this time will reveal the transistor action idea.

If a crystal containing two PN junctions were prepare signal could be introduced into one PN junction biase the forward direction (low resistance) and extracted the other PN junction biased in the reverse direction

the other PN junction biased in the reverse direction (high resistance). Such a device would transfer the signal current from a low resistance to a high resistance it.



## NPN Transistor

## Figure 3

emitter-base junction and collector-base

3. Figure 3 depicts the basic model of trans
Notice that the N-type material labeled en
biased with respect to the P-type base, a
collector is reverse biased with respect
base. Resistors R<sub>1</sub> and R<sub>2</sub> represent the

respectively.

4. A basic analysis is as follows: with the junction forward biased a current will fluguration. Some of this current will cont P-type base, and some will exit the P-type forward-biased battery. In figure 2, it that current flow across a PN junction unbiased conditions is due to minority carrended, the electrons in the P-type base we carriers. It was also stated that the current states and stated that the current states are stated that the current states are stated to the states of the states are stated to the states of the states of the states are stated to the states of the states o

reverse-biased junction was dependent upo minority carriers and not the bias voltag some percentage of the original carriers crossed the base-emitter junction could c collector-base junction. Because the col junction is reverse biased, it offers a h

the electrons which cross the junction (rresistor R2). Thus, we have transferred low resistance to a high resistance.

ause most of the current that crosses the emitter-base unction to cross the collector-base junction as well. N N EMITTER BASE COLLECTOR o Mobile Free Hole zed Donor Atom zed Acceptor Atom · Mobile Free Electronc hanges in the Emitter, Base, and Collector Region

urrent flow out of the base lead in figure 3, and to

Figure 4

igure 4 shows a schematic illustration of the charge

istribution in the emitter, base, and collector region transistor. The valence 4 atoms; i.e., silicon or ermanium, are not shown and should be imagined as a ontinuous crystal structure over the whole background

otice that there are more carriers in the N-type emitted han in the P-type base, and that there are more carriers the base than in the N-type collector (as a result of

9. Re-examination of figure 4 will show that which enter the P-type base region must tr into the region itself in order to recombine The electrons in the base region are in ef

recombine in the N-type region.

concentration of electrons and so will ver

- spread themselves out in order to recombin was defined in your lesson on PN junctions

  10. Each time an electron does recombine with
- P-type base region, the region is no longe neutral, but takes on a negative charge (ratom that takes on an excess electron is denegative ion).

  11. In order to regain its electrical balance, give up an electron to the external circuities to a current called IR (base current)
  - 12. Again recall that our goal is to get as multiple of our emitter current ( $I_E$ ) to flow through region and become collector current ( $I_C$ ). figure 1.) Figure 3 reveals that collector is simply the emitter current ( $I_E$ ) minus at ( $I_B$ ).

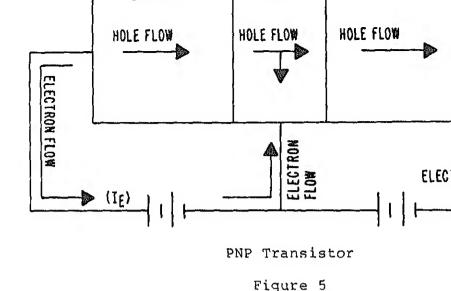
## $I_C = I_E - I_B$

Therefore, minimizing  $I_{B}$  will cause  $I_{C}$  to 13. The action taken to minimize  $I_{R}$  should be

- understood at this time. As stated earlied electrons must travel by diffusion through region. The distance they travel through (base) region before they recombine with a
- (base) region before they recombine with a their diffusion length. Now, let us introjunction by arranging a second N-type mate to the right of the base and, at the same base itself very thin. As the electrons of

the center P-type (base) region, some of the process. However, if the width of the very small as compared to the diffusion legislations only a few recombinations will be

tor proof landeron are erecerone the cite i cable base al (minority carriers). Therefore, the collectorunction will appear as a forward bias, and the ons will be swept across the junction. These excess ons in the N-type collector will give it an excess ve charge which it can easily give up to the al battery terminal in the form of Ic. Recall also : is not the reverse bias voltage that is conng the amount of electrons, but the forward biased -base junction which controlled the electrons into the base. ocess of causing majority carriers to cross over a ction and flow as minority carriers on the other s called injection. This process describes precisely ion that takes place at the emitter-base junction. ture on transistor action is now complete, and can ribed as three basic mechanisms: jection - The process (under forwrd bias conditions) ere majority carriers from the emitter are made to oss the emitter-base junction and flow as minority riers in the base region. fusion - The process by which the minority carriers lectrons) in the P-type base region travel (from an ea of high carrier concentration to an area of low rier concentration). lection - The process of causing minority carriers lectrons in a P-type material) to become majority riers (electrons in an N-type material) and giving em up to the external circuit. transistor model, external current was supported by cy carriers (electrons) in the transistor itself. ectrons are majority carriers in both the emitter llector, both of which are N-type carriers. The aree mechanisms of transistor action can be achieved NP transistor. 5 depicts the basic model of a that in this configuratio or are both P-type materi



19.

dre

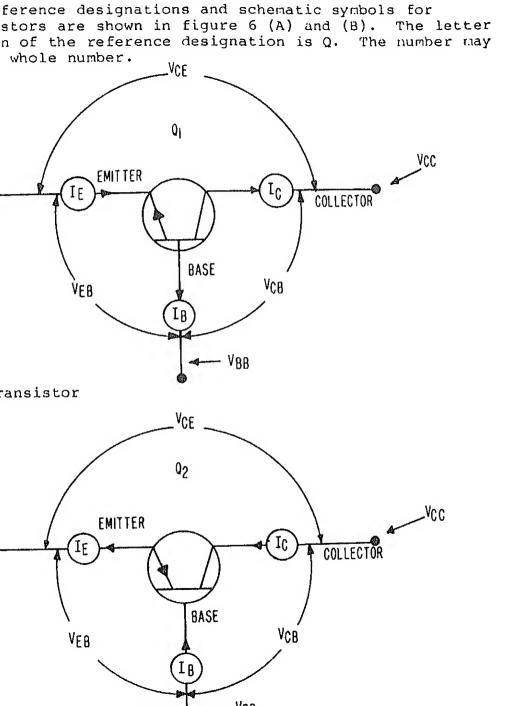
As forward bias is applied to the emitte

holes are accelerated across the emitter Once the holes enter the base region, th carriers (holes in an N-type material). recombine with some of the excess electrobase, creating positive ions. In order

- electrical balance, the base will readily electron from the external circuit for exwhich is created by an electron-hole recommendate, in order to reduce the number of in the base, the base is made very thin more heavily doped just as in the case of transistor (figure 4). The holes that do the base region continue to travel by the process; i.e., from an area of high carresto an area of lower carrier concentration which diffuse near the reverse-biased conjunction are swept across the junction be electric field. Once these holes enter collector region, the collector must acc
- 20. Thus, the external circuit current (elec supported by internal majority current c

balance.

the external circuit in order to achieve



3. The following generalizations are helpful behavior of transistor circuitry. These apply to a transistor that is operated as amplifier. The first letter of the type of trans the polarity of the emitter voltage w the base. A PNP transistor has posit applied to the emitter (+VEE). A NPN negative voltage applied to the emitt

emitter arrow.

b.

In the PNP transistor (B, figure 6), the to-collector current carrier in the devic For holes to flow internally from emitter the collector must be negative with respe emitter. In the external circuit, electr collector to emitter opposite to the dire

The second letter of the type of tran

electrons flow out of or into the col

2.

- the polarity of the collector with re base. A PNP transistor has negative applied to the collector (-V<sub>CC</sub>). An has positive d-c voltage applied to t (+Vcc). The first and second letter of the ty indicate the relative polarities betw and the collector respectively. In a
  - the emitter is positive with respect the collector is negative with respec (-VCE). In an NPN transistor, the em with respect to the collector; the co positive with respect to the emitter
- The d-c electron current direction is d. the direction of the arrow on the emi
- If the electrons flow into or out of e.
- respectively (Ic). The base current is always equal to t current minus the collector current /

ransistor, the collector is positive with respect to the base (+V<sub>CB</sub>).

In input voltage that aids (increases) the forward ias increases the emitter and collector currents.

In input voltage that opposes (decreases) the forward ias decreases the emitter and collector currents.

The reverse bias voltage (V<sub>CB</sub>) is normally much reater than the forward bias voltage (V<sub>BE</sub>) in a ransistor. Typical values of V<sub>CB</sub> range from 3 to 8 olts d-c. Typical values of V<sub>BE</sub> are .2 volts d-c for ermanium and .6 volts d-c for silicon crystals.

educate when reobeer to the page / ACH). In the Man

transistor is a three-element, three lead device, sible to use it in any of three different, useful tions. The identification of each of these circuits is derived from the element "common" to t and output. The three possible connections are: se, common-emitter, and common-collector. An often ation is "grounded' emitter, "grounded" base, etc., common element is usually returned to the signal int in a circuit.

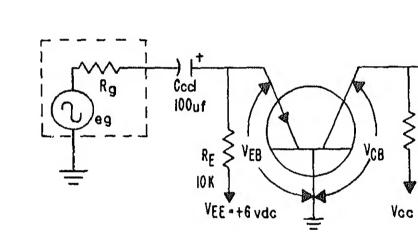
convenient to start a detailed examination with the n-base amplifier, which is normally considered to be reference amplifier" for any comparisons of the three fier configurations.

e 7 is a schematic drawing of a common-base amplifier e PNP type. Notice that the input is supplied en the emitter and base. Thus, the base is common to the input and output. In "transistor symbology" you given some general rules to follow when analyzing istor circuits. Following these rules, roper operation that V<sub>FF</sub> must be a posi

cc a negative voltage for proper bias po

source, and  $R_C$  is chosen to provide the digain. The reverse-bias voltage ( $V_{CB}$ ) is  $I_{CRC}$ . The reverse bias voltage will normal (3 to 6 volts) as comapred to the forward

4. Let us analyze the amplifier under dynamiconditions.



. (( -- ---

Figure 7

Common-Base Amplifier

ent in the device (IE). of the change in the output current (Ic) to the the input current (I\_E), or  $\frac{\text{IC}}{\text{I}_E}$ , is referred to pha" (0) of the transistor. Thus, the current is amplifier arrangement is less than 1, and is not true; a large voltage gain may be ecause the output load resistance is much an the input resistance. Thus, if we assume an stance of 50 ohms (the forward biased emitterin (input to output) is:  $in = \frac{\Delta E_{\text{out}}}{\Delta E_{\text{in}}} = \frac{\Delta I_{\text{CRC}}}{\Delta^{\text{I}} E^{\text{Rin}}}$ 0.98 for a typical value

 $in = \frac{\Delta E_{\text{out}}}{\Delta E_{\text{in}}} = 0.98 \times \frac{1000}{50}$ 

the polarity of the output signal.

carrenes. The accreasing corrector carrell Mil voltage drop across RC, making the collector more negative.  $(V_{CB} = V_{CC} - I_{CR_C})$ . Thus, a oing input signal produces a negative-going nal. During the positive half-cycle of the al, the emitter will be driven more positive s under static (no signal) conditions. This ase the current in the emitter and collector cause the voltage drop across Rc to increase. see that the polarity of the input signal

tput, a load resistor (RC of 1000 ohms) is used. the current is concerned, there is less at the e., collector) than at the emitter.  $I_C = I_F$ 

ifference (IR) is normally 1 or 2 percent of the lead one to believe that the circuit has little ion) and utilize a 1000 ohm load resistance, the

$$= \frac{\Delta_{I_C}^2 R_C}{\Delta_{I_e}^2 R_i}$$

 $= .98^2 \times 20$ 

 $= .96 \times 20$ 

Power gain = 19.2

8. In the input impedance of a transistor in the configuration is very low because of the formemitter-base junction. The output impedance the load resistor and look into the collector high, on the order of 1 to 2 megohms. However connect a load resistor of 1000 ohms, then the value of the output impedance since it completed to 2 megohms with which it is basically it is well for the reader to keep this disti

essentially determine the output impedance.

9. In summary, the characteristics of the commo

amplifier configuration are:

a. No phase inversion between input and out

because reference is often made in literatur output impedance of the common-base arrangem means without the load resistor. Once a muc resistance is connected to the collector, it

- b. Low input resistance because of forward (VEB) typical values 50-100 ohms.
- c. The output signal sees a reverse biased
  - (1) Typical values 1-2 megohms.
  - (2) In a practical circuit,  $R_C$  shunts th resistance of the transistor.
- d. The output to input resistance ratio is leads to a very high voltage gain.

e input signal is applied between the emitter and the se.

soutput signal is taken between the collector and

e base.

base is "common" to both the input and the output.

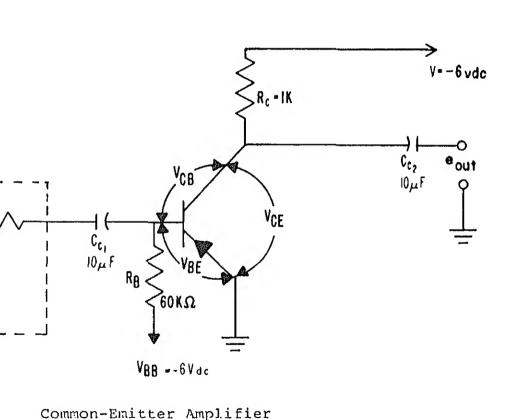


Figure 8

forward bias voltage across the base emitted (VRE). As is normally the case, this forward bias 2. very small. VCC is the collector supply so chosen to provide the desired voltage gain bias voltage (VCB) is equal to VCC -ICRC -3. Again, let us analyze the amplifier under ditions. As the incoming signal goes negaaid (increase) the normal negative bias be emitter (VRE). An input voltage that aids will increase the emitter and collector cu increasing collector current will increase across Rc. making the collector potential positive  $(V_C = V_{CC} - I_C R_C)$ . Thus, a negative signal produces a positive-going output si

the base resistor  $R_B$ , a 60 k-ohm resistor.  $I_B$  (approximately equal to  $V_{BB}$ ) will develop

- positive half-cycle of the input signal, to driven more positive than it was under stated conditions. This will decrease the current emitter and collector leads causing the vortex to decrease. This decreased voltage dreated become more negative. Thus, in the company of the co
- to become more negative. Thus, in the comamplifier polarity inversion between input

  4. For the output, a load resistor of 1000 onutilized to compare the characteristics of those of the common-base amplifier.
- 5. Since the input signal is applied to the b common-emitter amplifier, it is the variat signals on the base which control the coll
- signals on the base which control the coll As stated previously,  $I_C = I_E I_B$ . It was the difference in  $I_E$  and  $I_C$  is  $I_B$ , which i percent of the total current ( $I_E$ ). In fact

was intentionally designed to minimize IB; region, heavily doped emitter. Thus, it f minute variations of base current produce variations in collector current. If we as

current gain in the common-emitter amplifier is  $t \text{ gain } = \frac{\Delta I_C}{\Delta I_R}$ 

f  $\Delta I_C$  is called Beta ( $\beta$ ). In our amplifier the  $\Delta I_B$  twould be .1 mA, while the collector received

t would be .1 mA, while the collector received ostituting these values, we obtain

sizeable current gain is obtained, in contrast loss incurred in the common-base amplifier. esistance of the common-emitter amplifier is higher than the input resistance of the amplifier. As was the case with the amplifier, the input is applied across a sed junction ( $V_{\rm EE}$ ); however, the current flow junction ( $I_{\rm B}$ ) is quite small as compared to the w through the common-base forward-biased

values =  $\frac{.2 \text{ volts}}{.1 \text{ mA}}$  = 2 k-ohms

impedance, looking into the collector, before connected, is about 500,000 ohms. This is so than the value presented by the common-base

$$\Delta I_{\rm B} = R_{\rm in}$$

$$= 49 \times \frac{1000}{2000}$$

= 24.5

8. This is somewhat larger than the voltage gain the common-base amplifier. The difference is much; however, power gain is considerably bett

Power gain = 
$$\frac{\Delta_{Ic}^2RL}{\Delta I_B^2R_{in}}$$
$$= 49^2 \times .5$$
$$= 1200.5$$

- 9. In summary, the characteristics of the common-amplifier are:a. There is a polarity inversion between the
  - output.

    b. Higher input resistance than the CB amplif
  - value 2 k-ohms.

    c. The output resistance of the common-emitte less than that of the common-base amplifie
    - amplifier.d. The output to input resistance ratio is moleads to a good voltage gain.

Rc will shunt the output just as it did th

 There is a good current gain in the common configuration.

(c) 
$$\beta = \frac{I_C}{I_E - I_C}$$
(2) Dividing denominator and numerator by  $I_E$ 

$$\frac{\frac{1C}{I_E}}{\frac{I_E}{I_E}} - \frac{I_C}{I_E}$$

(3) However,  $\frac{\Delta I_C}{\Delta I_F} = \alpha$ 

By substitution; 
$$\beta = \frac{\alpha}{1 - \alpha}$$

(1) It can be seen that by keeping the recombination

amplifier.

Collector Amplifier

cuits.

approaches unity.

currents in the base circuit very low, alpha (2) As  $\alpha$  approaches unity,  $\beta$  will approach infinity. There is a very high power gain in the common-emitter is because of its higher current gains, power gains, a

relatively close input-to-output impedance ratio (1 t

our example), that the common-emitter amplifier conration is the most popular configuration in transisto final transistor amplifier circuit arrangement is the mon-collector. This is shown schematically in figure that the collector of the transistor is not at d-c and since the collector still requires a - ${
m v}_{
m CC}.$  Note al bias polarities. They are the same polarities as wer lired for the common-emitter amplifier in figure 8.

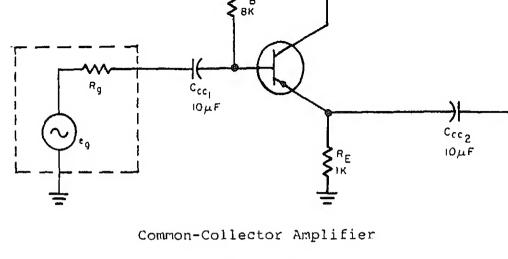


Figure 9

- ne input signal will be
- The input signal will be developed across the base collector junction (the collector is the common el
  - and the output signal will be developed across the resistor R<sub>E</sub>. Thus, in the common-collector amplifi input is applied to the base and the output is tak
  - input is applied to the base and the output is tak the emitter with the collector the common element.
- 3. Analyzing the amplifier under dynamic conditions, incoming signal goes negative, it will aid the nor negative bias between base and emitter (VBE). An i aids forward bias will increase the emitter and convergents
- alds forward bias will increase the emitter and cocurrents.
  4. The increasing emitter current will increase the various across the emitter resistor R<sub>E</sub> (negative to present with the compact of the
  - from the top of  $R_E$ ). Therefore, a negative-going is signal will develop a negative-going output signal the positive half-cycle of the input signal, the he driven more positive than it was with no signal
- This will decrease forward bias, and will lend to decreasing current in the collector and emitter led decreased emitter current will decrease the voltage across the emitter resistor, causing the output sigo in the positive direction, Thus, in the common-

configuration, there is no polarity inversion betwand output. The current gain of a common-collector

$$= \frac{I_C}{I_B} + \frac{I_B}{I_B}$$

 $= \beta + 1$ 

of the change in output current,  $I_{\rm E}$ , to the

rent,  $I_B$ , or  $\frac{\Delta I_F}{\Delta I_B}$  is referred to as "gamma",  $\gamma$ .

ge gain of the amplifier is always less than l, generally it is not much less than l. The emitter develops the output signal which will be in the rity as the input.

seen in figure 10, as the input signal goes (which would increase forward bias), the output also goes negative, which tries to reduce the ias. The actual difference between the input and t would be the voltage dropped across the forward tion RRE.

s resistance is very low, the output voltage will ual the input voltage. In short, what we have is ble degeneration.

RE Peour

RE Peour

Input Resistance of the Common-Collector Amplifie

Figure 10

- 8. Power gain is achieved in the stage because of current gain, but the gain is less than it is i common-base or common-emitter characteristics.
- 9. In summary, the characteristics of the common-c amplifier are:a. There is no polarity inversion between the the output. For this reason the common-col
- amplifier is frequently referred to as an emitter-follower.b. Highest input resistance of the three possi configurations. The input is applied between
- configurations. The input is applied betwee collector-base junction which is reverse bi
- collector configuration, the emitter resist primarily the load.

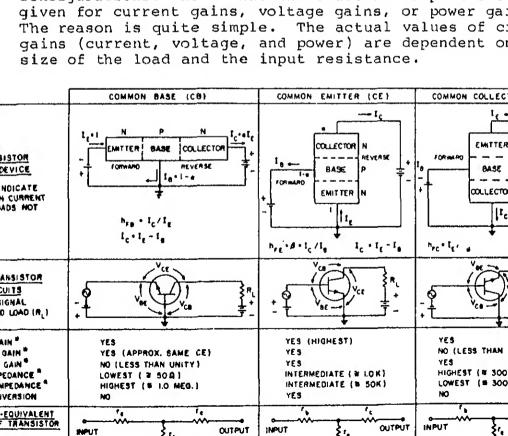
  d. The voltage gain is less than 1. You may be why use a common-collector stage if the vol less than unity? Because the input resistatingh (approximately 100 k-ohms) and the out

tance quite low (approximately the size of use the common-collector similar to a transthat it can be used to transform (step down

 $\frac{\Delta I_E}{\Delta I_B}$  = Gamma =  $\gamma$  = ( $\beta$  +1)

configuration

TO a ...... carrone dark fit che common-coffe



transistor manual. Here, we find the mechanical a electrical specifications for each type of transis similar fashion, equivalent data is published by t manufacturers for each of their products. Transis manufacturers' sheets contain the specifications o particular transistor, including maximum ratings, characteristic curves, and physical outline. 1. A typical specification sheet is shown in figu The various sections of the specification numbered 1 to 3, and the appropriate explanati will be discussed. 2. We will not cover each specification at this t the degree of knowledge on transistors require in later lessons, as your knowledge of transis increases, you will be able to interpret all o given by the manufacturer in his specification The lead paragraph is a general description a. device and usually contains three specific information: in this instance, an alloy-j germanium PNP transistor, a few major appl computers and switching applications, and features such as standard size and type pa The absolute maximum ratings which must no b. To exceed them may cause device exceeded. The dissipation of a transistor is general by the junction temperature (Ti). Therefo

operation, or service of electronic equipment is t

The dissipation of a transistor is general by the junction temperature (Tj). Therefo higher the temperature of the air surround transistor (TA = ambient temperature), the the device dissipates. A factor which ind much the transistor must be derated for ea increase in ambient temperature is usually Note that the 2N404 (given on the specific sheet) can dissipate 150 mW at a TA of 25° applying the given derating factor of 2.5 degree increase in ambient temperature, we the power dissipation will drop to zero mW This, then, is the maximum operating tempe the transistor.

 $\frac{\Delta I_C}{\Delta I_B} = 135.$ 

ensure device reliability and stable characteristics

iental tests

These units meet JEDEC TO-5 registration.

S. S. S. DIA

LINE IN THIS

nical data

To ensure maximum reliability, stability, and long life, all units are aged at 100°C for 100 hours mi

humidity cycling, shock and vacuum leak testing under rigid in-process control procedures,

All leads insulated from the case.

Close parameter control and the JEDEC TO-5 welded package

3 COLLECTOR

prior to electrical characterization. All transistors are thoroughly tested for complete adherence to s design characteristics. In addition, continuous qualification tests are made comprising temper

Metal case with glass-to-metal hermetic seal between case and leads. Unit weight is approximately

2N40 40 v

35v

25 v

150 m

+100

moximum s	ratings at	25° C	free-air	temperature	(unless	otherwise noted)	

te maximum ratings at 25° C free-air temperature	(unless otherwise noted)
	2N404
Collector-Base Voltage	25 v

ALL DIMENSIONS IN INCHES

SEATING

PLANE

Collector-Emitter Voltage (see note I) 24 v

0.200

**RADN 0.0007** 

Emilter-Bose Voltage 12 v

0m 001

Collector Current

Emitter Current 100 ma

150 m Total Device Dissipation (see note 2) 150 mw 150 m

Operating Collector Junction Temperature 85°C 1000 -65°C

Storage Temperature Range -65°C to + 100°C

NOTES: I Punch through voilage

2. For 2N404 decate linearly to 85°C free-air temperature of the rate of 2.5 mm/°C For 2N4O4A decale linearily to 100°C free-air temperature at the rate of 2.0 mw/°C

\* Indicales JEDEC registered data. The maximum power dissipation at 25°C case temperature is 300 mw.

CURRENT	Tg = 80°C	-	-+0	- 804	-	-40	- 10	μα
EBO EMTTER CUTOFF CURRENT	Yeş:-16V,1;:0	-	-1	-1 1		-1	- 0 5 <sup>6</sup>	
VERS COLLECTOR - BASE	1c - 10 HQ , 1e - 0	-154	-	_	-4B*	-	-	٧
VERG EMITTER - BASE BREAKTOWN VOLTARE	rg = -sojrG,rg = o	-14*	-	-	-134	-		٧
FE DC FORWARD CURRENT	YCE = -0 (8V , IG+12m4	10	100	_	10	100	-	-
TRANSFER RATIO	Ycq 80V , 1c - 84me	14	110		84	110 .	-	
DE DARE-ENITTER	1g+-04me,Ic+-Ifme	-	-0 45	-0 18	-	-0 86	-0 35	٧
VOLTAGE	Ig = -inc ; Ic = - 24me	-	-0 30	-0 40		-030	-0 40	٧
CE(mt) COLLECTOR	1g0.4me, 1c18me	_	-0 D6	-015	_	-0 04	~018 <sup>4</sup>	٧
-EMITTER SATURATION YOUTABE	Inime, Icline	-	-0 00	-0 10	-	-0.04	-0.18	٧
PT PUNCH - THROUGH VOLTAGE !	AEB 10 s = 1A	-14.	_	_				٧
EBIL EMITTER - BATE PLOATING POTENTIAL	V <sub>CB</sub> v = 16 V	_	=			-01	-1	٧
FE AC COMMON — EMITTER FORWARD CURRENT TRANSFER RATIO	V <sub>CE</sub> + -8V , 2 c = -(ma		135	-	-	138	-	-
EMITTER INPUT	V <sub>CE</sub> + + + + − 1	_			_	•	_	lwa
AC COMMON - EMITTER OUTPUT ADMITTANCE	Y <sub>CE</sub> + -4Y, E <sub>C</sub> +1m0 f + 1KC	-	10	-	_~	10	-	ji na
TO BE COMMON - EMITTER REVERSE VOLTAGE TRANSFER RATIO	V <sub>C</sub> g + −6V , T <sub>C</sub> + (ms	_	1110-4			7110 <sup>4</sup>	_	_
PASE - NOIMEDS de- TUT FUT SDRATIDADE	V <sub>CB</sub> + - 6 V , I g + O f + 1MC		,	10,	-	_	-	,,
	Yes 67, 12-1m2	<u>-</u>		-		,	104	91
NIS COMMON - BASE ALPHA CUTOFF FREQUENCY	Your way, ferins	,•	"	-	,	18		ne.
P, IS DETERMINED BY MIABURING THE EMITTER-BASE FLDAFING POTENTIAL V <sub>EQU</sub> I ING A VOLTMETER WITH II MESONMS MIMMUM IMPUT IMPEDENCE THE COLLECTOR-BASE DLTASE, V <sub>CS</sub> IS INCREASED UNTIL V <sub>ERTI</sub> I VOLT; THIS VALUE OF V <sub>CR</sub> +(V <sub>SI</sub> ++) CARE MUST TAKEN HOT TO EXCEED MAXIMUM COLLECTOR-BASE VOLTASE SPECIFIED UNDER MARIMUM ATINSS.								
BASE-EMITTER V VS COLLECTOR CU	OLTAGE Breny					EMITTE - AIR	V 5	
		1	0 7	,				
TA = 26 ° G	╼┼╌╂╌╂╂╂┥	ا ن	0 6				-	_ _
┝╌╏╼╏╼╌┼┼┼┼╢╏╃╼──╏		2						
	11111	5			, a			
			0 4	-	'a .' 'a . 'o	0 70		
1810 4me		- 5047102 - 80471020	0 3		ا ''	me -	k 113	
				•		-		_

increase in current flow between the colle base. This point is known as the avalanch breakdown, in which minority electrons, pa PN junction, gain sufficient energy to kno valence electrons bound to the crystal lat raise them to the conduction band. BVCRO usually specified at some value of reverse current. The 2N404 will avalanche between collector and base at approximately 25 vol 20 pamps of leakage current. (4) Emitter breakdown voltage BVEBO is the max voltage which can be safely applied betwee and base when these elements are reverse b with the collector open. This value is gi specification sheets in order to indicate a reverse bias voltage may be applied to t of a common-emitter amplifier before the i circuit will break down. (5) Many manufacturers will list a collector s voltage VCE(sat). This voltage is essenti minimum voltage necessary, at a particular collector current, to sustain normal trans action, and it occurs when the emitter-bas equals the emitter-collector voltage. At collector voltages, the base-collector jun becomes forward biased and the current-vol relationship changes abruptly. The curren increase at a rapid rate limited only by a external resistance in the collector circu (6) The collector cutoff current is the curren collector to base when no emitter current This is ICBO. It varies with te changes and must be taken into account whe semiconductor is designed into equipment w used over a wide range of ambient temperat (7) Base to emitter voltage  $V_{
m BE}$  is the voltage recommended by the manufacturer for normal transistor action. Notice for the 2N404 V

listed for typical and maximum conditions.

with the emitter open at which there is a

to us by the manufacturer. We have discussed only a characteristics but, as stated earlier, in future ou will become familiar with several more important characteristics.

Oly the two most important characteristics we have seed were the maximum reverse bias between collector ase (BVCBO), and the power dissipation rating.

, there are many characteristics of a transistor made

ly another way of expressing the safe amount of heat the collector-base junction can withstand.

Let words, the transistor must dissipate power in the of heat across the junction. If the power is too there will be more than 85°C of heat generated at anction, which would destroy the device. It was found we must derate (reduce the output power) the stor for each degree of increase in ambient rature as the collector-base junction must dissipate eat it receives to the ambient air.

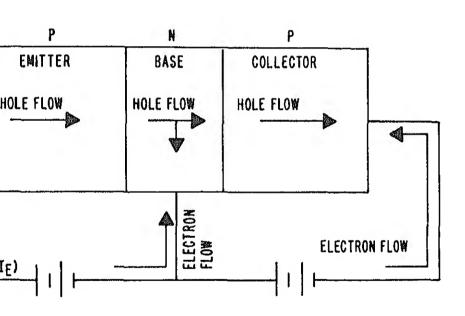
eat it receives to the ambient air.

sist transistors in achieving higher collectorcation ratings, heat sinks, in which the transistors
cunted, have been developed. These heat sinks, or
dissipaters, help conduct heat away from the
con, thus lowering the junction temperature (Tj).

ic Circuits, NAVSHIPS 0967-00-0120, pp. 5-10 to 5-20. ls of Radio-Electronics, Slurzburg and Osterheld, ill Co. or and Integrated Electronics, Kiver, McGraw-Hill Co., urth Edition. UTLINE: sistor action R1 - 10 1 R2-100Ω N EMITTER BASE COLLECTOR **ELECTRON ELECTRON** FLOW FLO# **ELECTRON** FLOW CTRON Ic Ĭρ

A. Analysis of the NPN Transistor

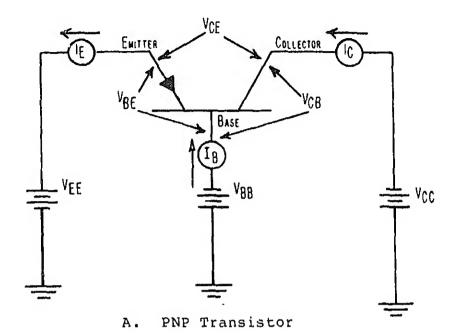
lysis of the PNP Transistor

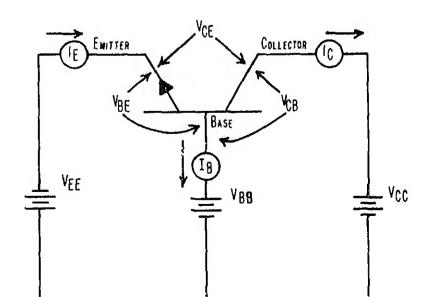


2.6 Figure 2 - PNP Transistor

C. Mechanisms of transistor action

- II. Transistor symbology and notations
  - A. Schematic symbols





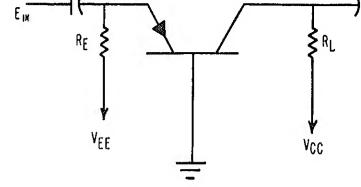
2. PNP type

3. Supply voltages

4. Terminal voltages

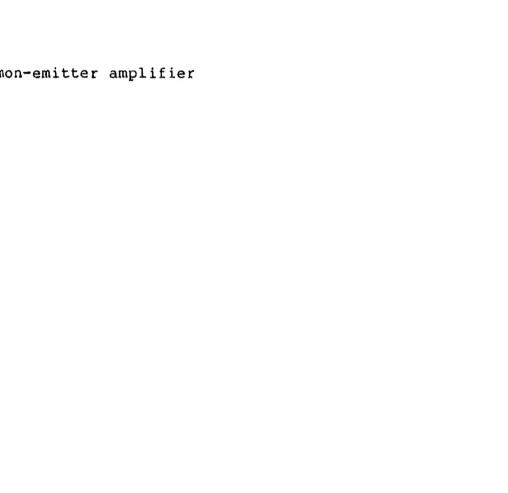
it configurations and operation

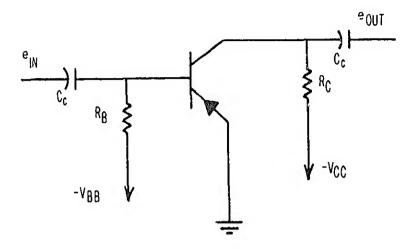
hree basic configurations



2.7 Figure 4 - Common-Base Amplifier (PNP)



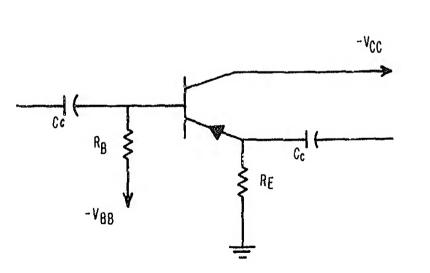




2.6 Figure 5 - Common-Emitter Amplifier (PNP)

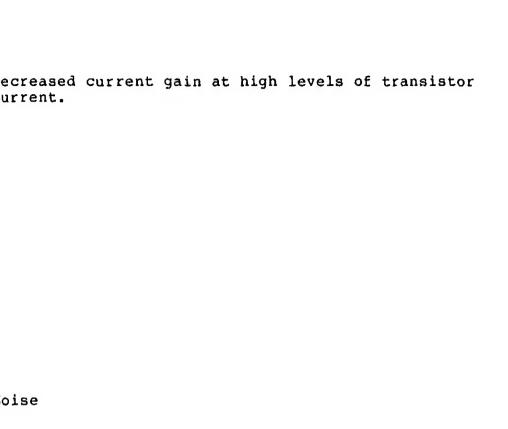
.

## Collector amplifier

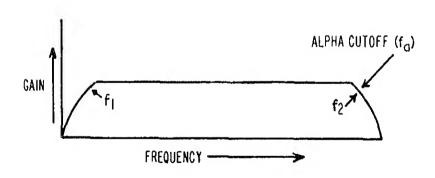


e 6 - Common-Collector Amplifier (PNP)

B. Junction temperature



## E. Frequency response



2.6 Figure 7 - Transistor Frequency Response Curve

this data sheet is for you gains and resistances o	ou to measure, record, and f the three basic transistor
e amplifier	
te the following schematind label components; i.e.	c of the common-base ampli-, $V_{CC}$ , $V_{EE}$ , $R_{E}$ , $R_{L}$ , etc.
measurements and calcula	tions:
	(5) $I_C = $
B =	(6) $R_I = $
3	(7) $A_{I}(\alpha) = $
CB =	
ic measurements	
out =	
in =	
v =	

ions:

rite the formula for  ${
m V_{EB}}$  for the above schematic.

Con	mmon-collector amplifier				
a.	Complete the following schematic amplifier and label components.	of	the	common-c	3(
ъ.	Static measurements and calculat	.ion	s <b>:</b>		
	(1) $V_B = $ (	6)	V <sub>BE</sub> :	3	
		7)	I <sub>E</sub> =		
	(3) $V_{\rm E} = $ (	8)	R <sub>I</sub> =		_
	$(4) I_B = $ (	9)	Α <sub>Ι</sub> (γ	) =	
	$(5) V_{BC} = \underline{\hspace{1cm}}$				
•	Dunamic measurements:				
	=				
	_				

eration?
at is the voltage gain characteristic of the common- llector amplifier?
Instructor's initials
tter amplifier
te the following schematic of the common-emitter ier and label components.

	(5) $V_{BE} =$
c.	Dynamic measurements:
	(1) e <sub>out</sub> =
	(2) e <sub>in</sub> =
	$(3) \Lambda_{\mathbf{V}} = \underline{\hspace{1cm}}$
d.	Questions
	(1) What would happen to forward bias i
	parameters and the community of the comm
	(2) Are the bias voltages correct for no operation?
	Instructor's

(4) I<sub>B</sub> = \_\_\_\_\_

(9) A

sistor means setting the d-c voltages and currents of to certain chosen values to establish an operating a-c signal. A bias circuit employs resistors and d-c to set the various voltages and currents at the preues. These d-c voltages and currents must be such ne transistor's ratings are exceeded; that is, they the permissible operating point region.

N. Y., McGraw-Hill Book Company, 1972, Fourth

he a-c signal is applied to the transistor, the

Circuit Analysis, NAVAIR 00-80-T-79, Chapter 8.

Kiver, Transistor and Integrated Electronics.

stor's voltages and currents vary about the operating Only a portion of the permissible operating point is such that the amplification is linear; this nof the permissible operating point region is called near operating region. The entire signal swing must nin the linear operating region for the input to be ied without appreciable distortion.

are two major reasons for the difficulty in sustaindesired operating point. First, as was noted in
fluction to Semiconductors," the characteristics of
nductor materials are temperature dependent. Second,
aracteristics of different transistors of the same
ill vary from unit to unit. Consequently, when
s transistors are placed in the same circuit, the
ion will vary somewhat unless stabilizing measures
cen.

Changes in temperature affect three transistor quant \*I<sub>CBO</sub>, β, and V<sub>EB</sub>. β and I<sub>CBO</sub> will rise as the tempincreases. The V<sub>EB</sub> which is necessary to produce a emitter current decreases as the temperature increase these, the most serious variation is experienced by

1. Reverse-Bias Collector Current (I<sub>CBO</sub>). I<sub>CBO</sub> (so referred to as I<sub>CO</sub>) is normally measured at a T<sub>i</sub> temperature) of 25°C (see figure 1). Note that

minority current, and flows in the same directic collector current if the transistor was properly This current  $I_{\rm CBO}/I_{\rm CO}$  is the same type current that flows in any PN junction under a reversed 1

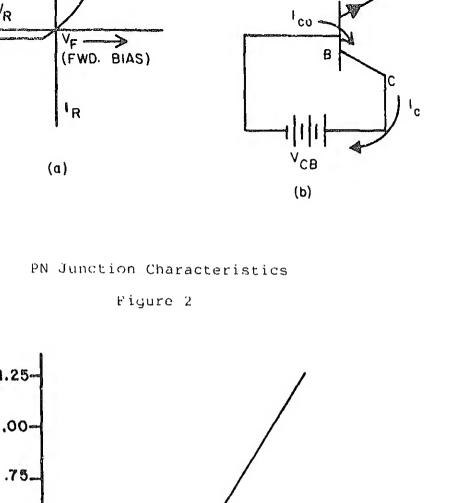
transistor and the means for removing heat from the

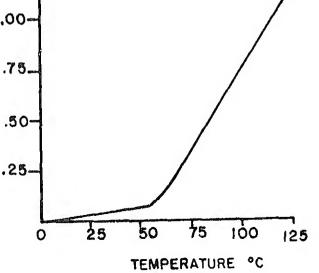
condition (see figure 2). The current flow in biased condition is almost constant and independ voltage prior to the breakdown point.

Figure 1

a. Variations of  $I_{CBO}/I_{CO}$  with temperature of collector-base junction is shown in figure current value varies from almost zero at 10  $^{\circ}$ 

well over 1 milliampere at 125°C. Note that temperatures below 10°C, I<sub>CBO</sub> causes no prol I<sub>CO</sub> doubles for every 10°C rise in germanium every 6°C rise in silicon.





Beta -  $\beta$  is the current gain of the common-emitter trasistor configuration. It is the ratio of a change in collector current ( $\Delta I_{C}$ ) caused by a change in base cur ( $\Delta I_{B}$ ).  $I_{CBO}$  flows through the base lead in opposite direction to  $I_{B}$  (figure 4), increases  $I_{CBO}$ , causes  $I_{C}$  tincrease, and  $I_{B}$  to decrease. Therefore, for a set valof  $I_{B}$   $\beta$  would increase and shift the operating point.

N

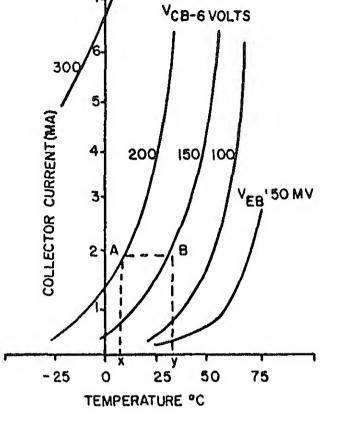
I co (ELECTRON)

SISTORS IN THE BASE LEAD.

base are high in value, electrons from the collect can accumulate in the base region. Such an accumulation of electrons will cause an increase of emithole into the base, increasing collector current. Increased collector current would raise the temper of the collector-base junction, and cause an incre in  $I_{CO}$  (figure 3). The cycle would continue until severe distortion occurs, the transistor becomes in operative, or it destroys itself. THIS CONDITION BE MINIMIZED BY AVOIDING THE USE OF MIGH-VALUED RE

Figure 4

VEB - Figure 5 indicates the variation of collector cu with temperature. Each curve is plotted with a fixed collector-base voltage (Van) and a fixed emitter-base



ariation of Collector Current with Transistor Temperature

Figure 5

ethod of reducing the effect of the NEGATIVE RATURE COEFFICIENT of resistance is to place a value resistor in the emitter lead. Essentially, causes the variation of emitter-base junction tance to be a small percentage of the total rence in the emitter circuit. The external resistors (overcomes) the junction resistance; the rer is referred to as a swamping resistor.

ond method of reducing the effect of the rature coefficient of resistance is to er-base forward bias as the temperatur

# temperature, or increased 2.5 mV/°C for decre temperature. Common-Emitter Amplifier

1. The common-emitter amplifier is the most commonly amplifier because it has the following character:

Difference in forward bias =  $\frac{50 \text{ mV}}{20^{\circ}\text{C}} = 2.5$ 

This calculation indicates that collector cur not vary with emitter-base junction resistance forward bias is reduced 2.5 mV/°C for increas

a. Current gain; 
$$\beta = \frac{\alpha}{1-\alpha}$$
  
b. Voltage gain  $\equiv \beta \equiv \frac{R_O}{R_i}$ 

c. Highest power gain

d. Easier to cascade because 
$$\frac{R_0}{R_1}$$
 is more closely

common-emitter amplifier to compensate for i stability. Constant base current biasing is figure 6 and will be used to analyze basic b

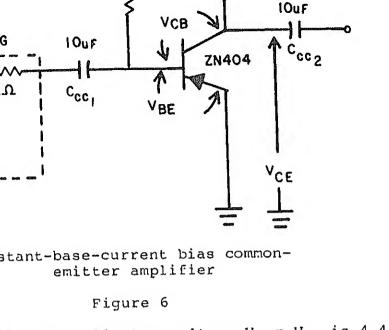
$$I_{B} = \frac{V_{CC} - V_{BE}}{RB} = \frac{5.8V}{1M} = 5.8 \ \mu A$$

variations, and temperature instability.

However, it must be stabilized because of unit to

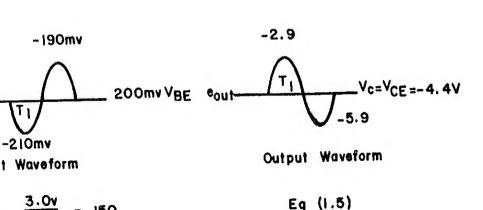
(1) There are several biasing arrangements used

VRR \* .2V for germanium; since RB >> the d resistance, IB will be limited primarily by  $I_C = \beta I_B = 100 \times 5.8 \mu A$ 



G

re, the collector voltage  $V_C = V_{CE}$  is 4.4 volts. put waveform will vary around this point (4.4 as shown in figure 7.



out waveform versus input waveform

parameter  $I_{CBO}$  was not included.  $I_{CBO}$  current that flows collector to base wi emitter open. However, transistor action occur with the emitter open. If, on the  $I_{CBO}$  flowed only in the collector-base would cause no serious problem. But, it is constructed that has a high resistant base lead, it will appear open to this current. This will cause a current to  $I_{CEO}^*$  (figure 8). These minority carri

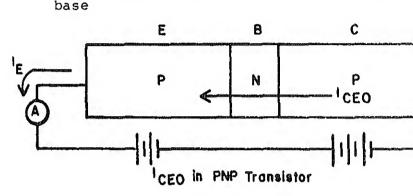


Figure 8

circuit and become majority carriers. emitter, this is the same as an increas bias current. The emitter injects  $\beta$  + the base to offset the negative charge  $\beta$  holes will diffuse through the base amount that will recombine with  $I_{CO}$ .

Mathematically:

$$I_{CEO} = I_{CBO} (B+1) = I_{CO}(B+1)$$

The collector current (Ic) is:

$$I_C = \beta I_B$$
 (Eq 1.2) +  $I_{CEO}$   
=  $\beta I_B + I_{CEO}$ 

$$= \beta I_B + I_{CO}(B+1)$$

 $(100)(5.8 \mu A) + 5 \mu A (101)$ 

(1.085 mA)

 $V_{\rm CC} - I_{\rm C}R_{\rm L} = 6 - (1.085 \text{ mA})(2.76 \text{ kg})$  (Eq 1.8)

6 - 2.99 ≈ 3 volts

ual operating point would be  $V_{
m CE}$ =3 volts and he output signal would be symmetrical if the emained 20 mV p-p and  $A_{
m V}$  150. However, if the ture increases and cause  $I_{ extsf{CO}}$  to increase,  $I_{ extsf{C}}$  will e. This would create more heat and more Ico. ocess is called thermal runaway and could damage asistor if  $R_{
m L}$  is very small. In our example, if perature increased and caused I<sub>CO</sub> to increase to a small current compared to Ic, the new operating

$$V_{CC} - I_{C}R_{L} \qquad (Eq 1.9)$$

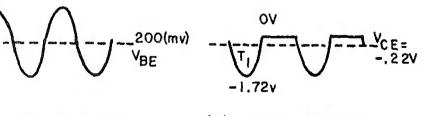
 $V_{CC} - \{100 \times 5.8 \mu A + (15 \mu A)(101)\}(2.76 k\Omega)$ 

6 - 5.78

ill be:

-.22V (saturation)

nput signal and  $A_{
m v}$  remained the same, then:



input Waveform

(b) Output Waveform

It indicates the change in collector curr

change in ICBO. The optimium value of S equals 1, then I<sub>C</sub> will change only by the ICRO. This is an idealized objective and realizable with ordinary measures. The v is always greater than 1 for the common-e

fier. However, it should be remembered t the value of S is to 1, the better. Apply equation 1.10 to figure 6.

 $S = \frac{\Delta I_C}{\Delta I_{CRO}} = \frac{\Delta^I_{CEO}}{\Delta I_{CO}} = \frac{1.010 \,\mu\text{A}}{10 \,\mu\text{A}} = 101$ The stability factor of the unstabilized

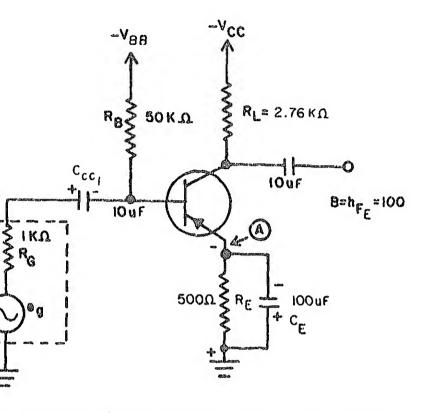
amplifier (figure 6) approximately equals current gain. We will see in the followi how this value is improved by various sta achemes.

- Figure 10 is a bias scheme used to improv of the circuit. The addition of an emitt (swamping resistor) increases the stabili circuits by:
  - (1) Compensating for the negative coeffic tance of the emitter base junction.
    - (2) Unit to unit variations, since this v same as temperature variations.
  - (3) Providing a constant current source.

The resistor R<sub>E</sub> adds the disadvantage of since it develops a voltage that is degen input signal. If greater gain is require passed with a capacitor. RR is reduced t

bias scheme is called constant emitter cu since it attempts to maintain IE constant in In would cause a more negative voltage oped at point (A) in figure 10, which wou

> forward bias and reduce transistor curren and the second of the contract of the second of the second



r Current Biased Common Emitter Amplifier

#### Figure 10

C100 C ... 103

the circuit. Under dynamic conditions, the s at a-c ground due to the bypassing action of hould be remembered that bias stability deals conditions and  $C_{\rm E}$  simply keeps the emitter at d. Through the use of calculus it can be at the stability factor for the circuit in is

$$\frac{\Delta_{IC}}{I_{CBO}} = \frac{(R_{B} + R_{E})(\beta + 1)}{R_{B} + (1 + \beta)R_{E}}$$

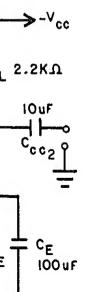
$$= \frac{(50 \times 10^{3} + .5 \times 10^{3})(101)}{50 \times 10^{3} + (.5 \times 10^{3})(101)}$$
(Eq 1.11)

ever, even though RE can be a-c bypassed by a car the power supply voltage must be made larger as I increased. For  $R_{\rm B}$ , a lower limit set by the shur effect on the a-c signal if the stage is capaciti direct coupled; if it is transformer coupled, the limit on R<sub>R</sub> is set only by the magnitude of the h voltage. d. The stability, it is noted, is affected by  $R_{\rm E}$ ,  $R_{\rm I}$ Beta of the transistor. Note also, that the state does not depend on  $R_{\mathrm{L}}$ . The stability factor used circuit will depend on whether the Ic variation missible, in terms of signal swing, permissible p dissipation, or the conditions for thermal runawa not, then R<sub>E</sub> must be raised or R<sub>B</sub> lowered until suitable condition is found. The most frequently used biasing circuit is shown e. figure 11 where an additional resistor is added : base circuit.

zero, the stability factor approaches ideal. Full if  $R_{
m F}$  approaches zero the stability factor approa

small as possible and  $R_{\rm E}$  as large as possible. Cannot make  $R_{\rm E}$  larger and  $R_{\rm R}$  smaller indefinitely

Therefore, for good stability RB should be



Beta

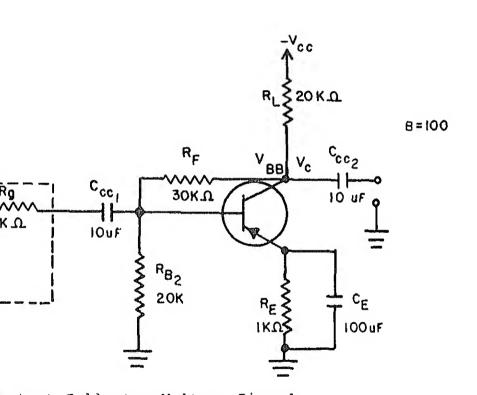
uld decrease the stability of the circuit.

res 10 and 11, the swamping resistor develops ative d-c current feedback. If a-c stability is sired, the removal of the emitter bypass capaci-

-- 30 to escapitan the proper forward blas.

general method for stabilizing the operating onsists of using direct voltage feedback with current feedback (figure 12).

) will provide a-c current feedback.

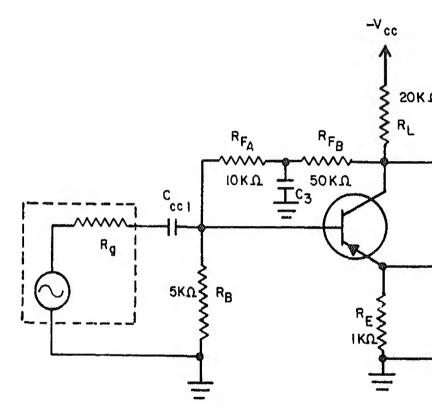


nstant-Collector-Voltage Biased Common-Emitter Amplifier

Figure 12

feedback is defined as that situation when the of signal fed back to the input (from the output) upon a voltage in the output circuit.

If greater gain is required, the circuit as in figure 13. The capacitor  $C_3$  bypasse generation without altering the d-c circuit because  $R_{FB} \mid \mid R_L$  and reduces the a-c load



Constant-Collector-Biased Common-Emitter Amp

## Figure 13

i. These, are the stabilizing schemes and eq on the common emitter. The choice betwee current-feedback is largely determined by the d-c load resistance. If the d-c R<sub>L</sub>, i usually the case for RC-coupled amplifier feedback (emitter at a-c and d-c ground)

as the current type. For transformer couthe d-c  $R_L$  is low, current feedback is mu

(2) Decide upon the component values by the usual considerations and then check the resulting S.

values which will give the S.

are compensated.

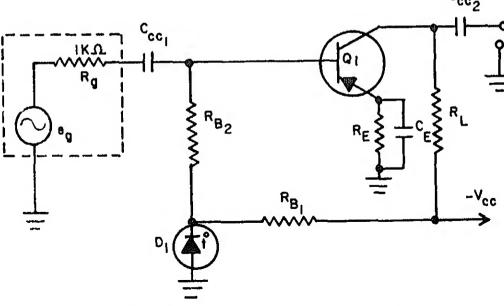
(1) Determine the appropriate S value and then use various d-c equations to fix the circuit compo

tional Stabilizing Techniques

When using temperature-sensitive elements for stabilit
idea is to cause the circuit conditions to change with

temperature so that the changes effected by the transi

Figure 14 is an example using a diode ( $D_1$ ) that has signared characteristics as the emitter-base junction of  $Q_1$  (not temperature coefficient). Any temperature variation waffect the base voltage and correct  $I_B$  to compensate in change. Note also that current feedback is still used  $C_{CC_2}$ 



Temperature-Compensated Common-Emitter Amplifier

Very low input resistance; high output resista C. d. Used mainly where the matching of a low to a h resistance is required. Ideal stability factor in the basic circuit e. configuration. 2. Figure 15 will be used to illustrate the common-ba

 $A_V \approx \alpha \left(\frac{R_0}{R_1}\right)$ 

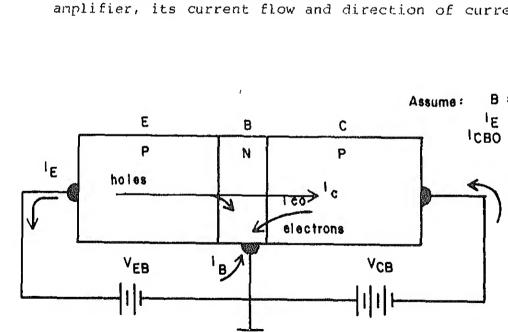
A current gain called Alpha =  $\frac{\Delta I_C}{\Delta I_E}$ 

configurations;

always less than one.

b.

Capable of the highest voltage gain of the thi



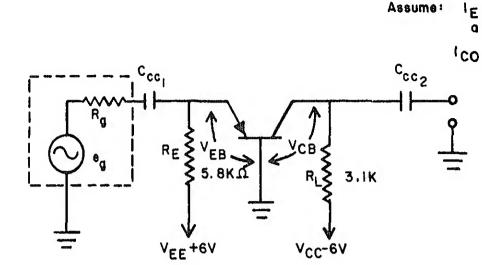
Current Flow in a PNP Transistor

Figure 15

```
- 4.95mA
llector current did not include the effect of
\alpha I_E + I_{CO}
(.99)(5,000 \mu A) + 25 \mu A = 4,975 \mu A
-\alpha) - Ico
\mu A (1 - .99) - 25 \mu A
- 25 µA
lear that if I_{CO} decreases I_{B} by its increase;
constant and Ic will change only by Ico.
an ideal stbility factor.
or using constant emitter current biasing is
igure 16.
-I_E R_E = 6 - \{1mA \times 5.8k\} = + .2V (Eq 1.13)
I_{CR_{I}} = V_{CC} - (\alpha I_{E} + I_{CO})(R_{I})
                                             (Eq 1.14)
\{(.99)(1000 \mu A) + 5 \mu A\}\{3.1k\}
lts
v_{B}
                                             (Eq 1.15)
-(0)
```

 $^{I}C$ 

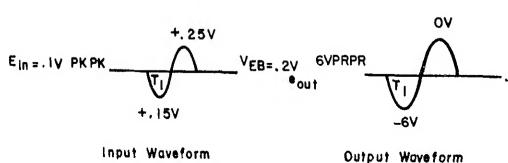
olts



Constant Emitter Current Biased Common Base Amplifier

### Figure 16

With the bias voltages computed, the amplifier is problemed. Assuming a voltage gain of 60 and input signly volts p-p, the output signal is given in figure 1 operating point is 3 volts ( $V_{\rm CB}$ ) and the maximum out without distortion is used.



```
change in I_{CO} will change I_{C} by the same amount. current that becomes I_{CEO} simply aids the circuit in stability. A disadvantage of this circuit is that requires two power supplies. One power supply could used with a voltage divider network; however, one t remember any resistance added in the base increases stability factor. ector Amplifier
```

h input resistance; low output resistance.

d mostly for impedance matching.

d a-c and d-c stability due to its degenerative

a (4201)/07-10-6\(\)

dback.

highest current gain;  $\gamma = \beta + 1$ 

tage gain less than one;  $A_V = \gamma \left(\frac{R_O}{R_i}\right)$ 

 $\Delta L_{CRO}$   $R_R + (\beta+1)R_R$ 

 $S = \frac{R_E(\beta+1)}{R_E(\beta+1)} = 1; \text{ ideal stability}$ 

common-collector amplifier is shown in figure 18. s voltages are as follows:

s voltages are as follows:  $I_{BB} - I_{B}R_{B} - I_{E}R_{E}$  (Eq 1.16)  $4 - \left\{ (27x10^{-6})(30x10^{3}) \right\} - \left\{ (101)(27x10^{-6})(1.1x10^{3}) \right\}$ 

 $4 - \{(27x10^{-6})(30x10^{3})\} - \{(101)(27x10^{-6})(1.1x10^{3})\}$ .19 volt  $= V_{CC} - I_{E}R_{E}$ (Eq 1.17)

$$= -6 - (-3.2)$$

$$= -2.8 \text{ volts}$$

$$-4V_{BB} - 6V_{CC}$$

$$R_{B} \longrightarrow V_{BC}$$

$$V_{EC} C_{CC_{2}}$$

$$R_{Q}$$

$$R_{Q}$$

$$R_{Q}$$

$$R_{Q}$$

 $= -6 - \{4 - (-.8)\}$ 

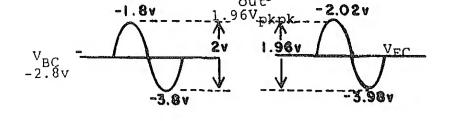
Basic Common-Collector Amplifier

1.1KΩ.≥RL

# Figure 18

If a 2V  $p_{-p}$  signal was applied to the amplifi would be as shown in figure 19.

2. The S of this circuit is approximtely equal t  $R_{\rm B}$  to  $R_{\rm L}$ . Equation 1.9 could be used to anal circuit also. The common collector amplifier



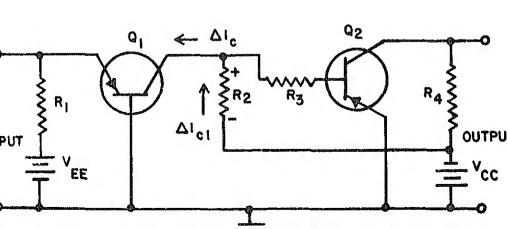
(a) INPUT WAVE FORM (b) OUTPUT WAVEFORM

Output Waveform Versus Input Waveform Common-Collector Amplifier

Figure 19

amplifier - Sometimes direct-coupled amplifiers are us silize I<sub>C</sub> variations. An example is given in figure 20 amplifier amplifies d-c voltage and very low frequency talk. This circuit is arranged so that an increase in

This circuit is arranged so that an increase in ector current caused by a temperature rise in transist reduce the forward bias in transistor Q2. The voltage across resistor  $R_2$  opposes the forward bias on  $Q_2$ . Exting the values of resistors  $R_2$  and  $R_3$  so that the voltage across  $R_2$  is the larger, the change in  $I_C$  of  $Q_1$  will tendency of transistor  $Q_2$  collector current to increase perature.



- 2. Items that should be remembered concerning bias ments are:
  - a. Reverse-bias collector current I<sub>CBO</sub>, also concreases rapidly at high temperatures and increased collector current.
     b. Emitter-base junction resistance decreases creasing temperature and causes increased
  - current. c. The stability factor (S) is defined as the change in collector current ( $\Delta_{\rm IC}$ ) to a charminority current ( $\Delta_{\rm ICBO}$ ) and is expressed a

$$S = \frac{\Delta_{IC}}{\Delta_{ICBO}}$$

- d. An emitter swamping resistor minimizes varient caused by variations in emitter current caused by variations in
- junction resistance.

  e. Zero base resistance limits the accumulator carriers (I<sub>CO</sub>) in the base region and there the increase in emitter current due to this
- f. The basic common-base amplifier (figure 16) best temperature stability because it uses swamping resistor and zero base resistance.
  - g. The basic common-emitter amplifier (figure poor temperature stability because it uses resistor and zero emitter resistance.
- h. The temperature stability of the basic commamplifier (figure 18) depends upon the rational resistance to emitter resistance.

Circuit Analysis, Vol. I, NAVAIR 00-80-T-79,

Kiver, Transistor and Integrated Electronics. New, McGraw-Hill Book Company, 1972, Fourth Edition.

LINE:

l Information - Biasing

ional Analysis of the Common-Emitter Amplifier asing

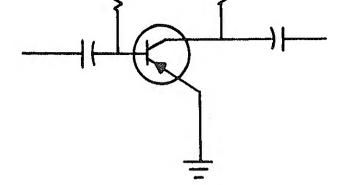


Figure 1

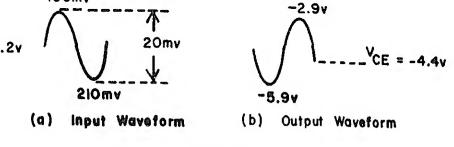
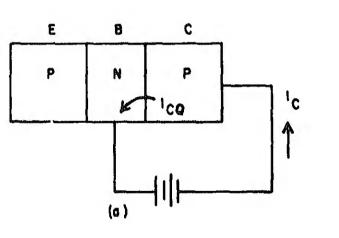


Figure 2

Temperature variations



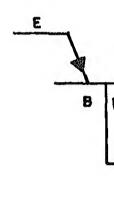


Figure 3

D, Beta

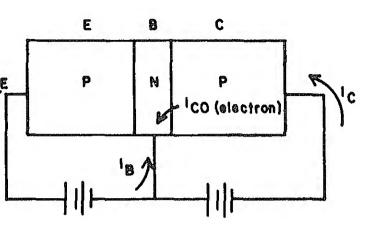
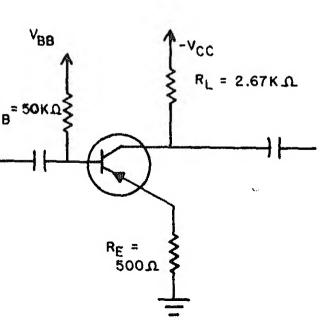
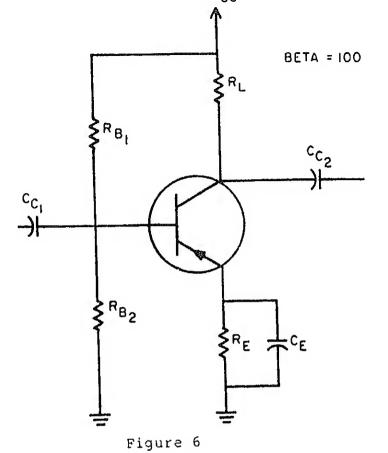


Figure 4

ant-emitter-current biased common-emitter amplifier





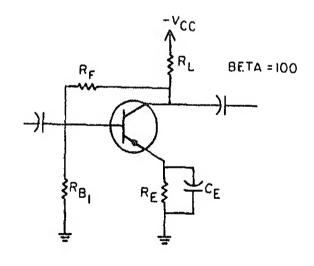
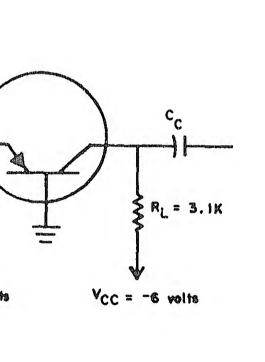
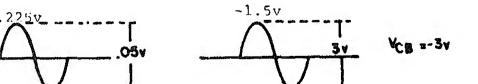


Figure 7



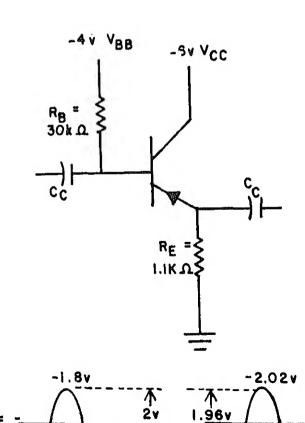
ASSUME: IE = 1 mA ALPHA = .99 ICO = 5 uA



V. Operational Analysis of the Common-Collector

Biasing Α.

> V<sub>CB</sub>= - 2,8 v



1.<u>96v</u>

the data sheet is for you to record the effects of a transistor's operating point. You will apply heat r, and you will measure and record the resulting rent with and without compensating circuit components.
e effects
ishing operating conditions:
E =
E =
tput wveform
E ==
s of increased temperature:
BE =
V <sub>BE</sub> =
C =
I <sub>C</sub> =
tput waveform
المنا
· □ ≖

		(2) now is VBE affected by temperature changes?
		(3) Does temperature affect fidelity? Explain.
		(4) What would be the result of a transistor's to extreme heat for a prolonged period of t
		Instructor's initials
2.	ucing temperature instability with the addition istor.	
	a.	$R_7$ equals 10 $k\Omega$
		$(1) I_{C} = \underline{\hspace{1cm}}$
		(2) I <sub>C</sub> after heating =
		(3) $\Delta I_C = $
	b.	R <sub>7</sub> equals 100 kΩ
		$(1) I_{C} = \underline{\hspace{1cm}}$
		(2) I <sub>C</sub> after heating =
		(3) $\Delta I_C = \underline{\hspace{1cm}}$
	c.	E <sub>out</sub> =
		Ein =
		$A_V = $
		<del></del>

ons
es the introduction of an emitter resistor improve cansistor temperature stability? Why?
pes the size of the emitter resistor affect transistor emperature stability? Explain.
nat is a disadvantage of using an emitter resistor?
ow can the above disadvantage be compensated for?
pes the emitter bypass capacitor stabilize I <sub>CO</sub> ? Why?
Instructor's initials
E $R_{ m B}$ and $R_{ m E}$ on temperature stability and $A_{ m V}$ .
ter heat =
<b>=</b>

	j.	E <sub>out</sub> =
	k.	Ein =
	1.	$A_V =$
	m.	Questions
		(1) In terms of stability, what conclusion regratio of $R_{\rm B}$ to $R_{\rm E}$ can be drawn from this perperiment? Explain?
		(2) Why is it desirable to have I <sub>CO</sub> flow throu collector-base junction rather than both the base and the emitter-base junction: Explain
		Instructor's initia
1.	Con	stant collector-voltage feedback to improve sta
	a.	Operation at ambient temperature:
		(1) I <sub>C</sub> =
		(2) E <sub>out</sub> =
		(3) $E_{in} =$
		$(4) A_{V} =$
		(5) I <sub>C</sub> with heat applied =

constant-bas as, explain tability.	e voltage bias any difference	to const in their	ant-collecto effects on	r
	Instructo	or's init	ials	

h heat applied = \_\_\_\_

Adams, Basic Mathematics for Electronics. New York: Book Company, Ind., Third Edition, Chapters 34 and

tronics, Volume 1. NAVPERS 10087-C. Washington, ted States Government Printing Office, 1979, pages 221-231.

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of Logarithms.



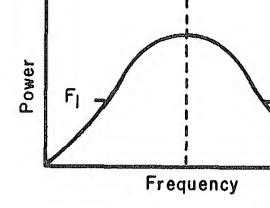


Figure 1 Bandwidth Cur

•	17	771	4914	5051	5185	5315	5441	5563	5682	5798	5911
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ų, E		990	7076	7160	7243	7324	7404	7 u 8 2	7559	7634	7709
5		782	7853	7924	7993	8062	8129	8 195	8261	. 8325	8388
		151	9513	8573	8633	8692	8751	8008	8865	8921	8976
7 9		331	9085	9138	9191	9243	9294	9345	9395	9445	9494
,		542	9550	9638	2685	4731	9177	9823	2868	9912	9956
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13	- 1	:35	:173	1206	1239	1271	1303	1335	1367	1399	1430
14	3		1-12	1523	1553	1584	1614	1644	1673	1703	1732
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18		738 188	2810	2833	2856	2878	2900	29 23	2945	2967	2989
20		010	3032	3054	3075	3096	3118	3139	3160	3181	3201
		222	3243	3243	3284	3304	3324	3345	3365	3385	3404
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27		1314	4330	4346	4362	4379	4393	11109	1425	3340	4456
28	•	1472	4487	4502	4518	4533	4548	4564	4579	4594	4609
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32		5051	5065	5079	5092	5105	5119	5132	5145	5159	5172
33	•	5185	5198	5211	5224	5237	5250	5263	5276	5289	5302
34	1	5315	5328	5340	5353	5366	5378	5391	5403	5416	5428
35		5441	5453	5465	54.79	5490	5502	5514	5527	5539	5551
34		5563	5575	5587	5599	5511	56 23	5635	5647	5658	5670
97	•	5682	5694	5705	5717	5729	5740	5752	5763	5775	5786
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14:	•	6232	6243	6253	6263	5274	6 284	6294	6304	6314	6325
4		6335	6345	6355	5365	6375	6385	6395	5405	6415	6425
14.	1	6435	6444	9454	6464	3474	5484	6493	6503	6513	6522
4		6532	6542	6551	5561	6571	6580	5590	6599	6609	66 18
1		6628	6637	6646	6656	6665	5675	5684	6693	5702	6712
	7	5721	6730	6739	5749	6758	5767	6776	5785	6794	6803
	8	5812	6821	5830	6839	6848	6857	5865	3375	1894	6893
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63	8062	8069	8075	8082	8089	8096	8102	810
68 65	8129	8136	8142	8149	8156	8162	8169	817
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68	8325	8331	8338	8344	8351	8357	8363	837
69	8388	8395	8401	8407	8414	8420	8426	843
70	8451	8457	9463	8470	8476	8482	8488	849
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72	8573	8579	8585	8591	2597	8603	96€€	86
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80	9031	9036	9042	9047	9053	9058	9063	90
81	9085	9090	9096	9101	9106	9112	9117	91
82	9138	9143	9149	9154	9159	9165	9170	91
83	9191	9196	9201	9206	9212	9217	9222	92
84	2513	9248	9253	9258	9263	9269	9274	92
85	9294	9299	9304	9309	9315	9320	9325	93
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67	9395	9400 9450	9405	9410	9415	9420	9425	; ;
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90	9542	9547	9552	9557	9562	9566	9571	95
91	9590	9595	9600	9605	9609	9614	9619	96
92	9636	9643	9647	9652	9657	9661	9666	96
93	9685	9689	9694	9699	9703	9708	9713	97
94	9731	9736	9741	9745	9750	9754	9759	97
98	9777	9782	9786	9791	9795	9800	9805	98
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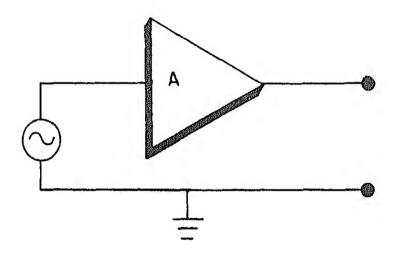
ous effects on circuits, we will use the block diagram diagrams of various schematics. Further simplificated by omitting all components that are bypassed, and g circuits.

and Osterheld, Essentials of Radio-Electronics, Secon

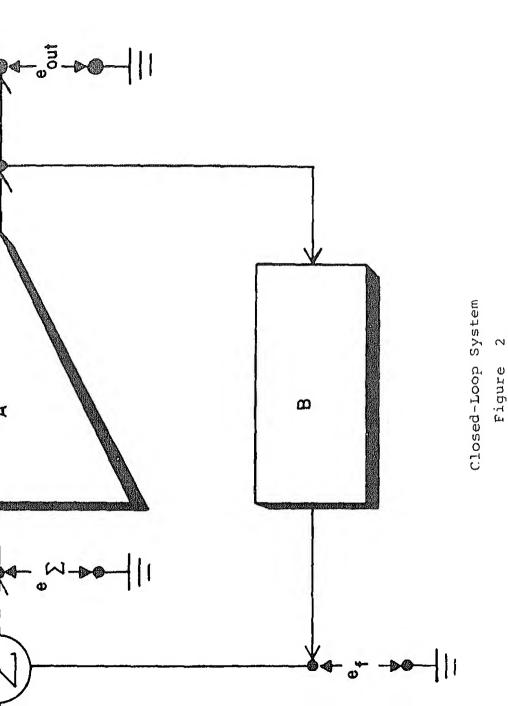
ral types of feedback circuits; each is determined by the signal that is fed back and the manner in which i the input circuit. The feedback signal can be prothe load current or to the load voltage. To investi-

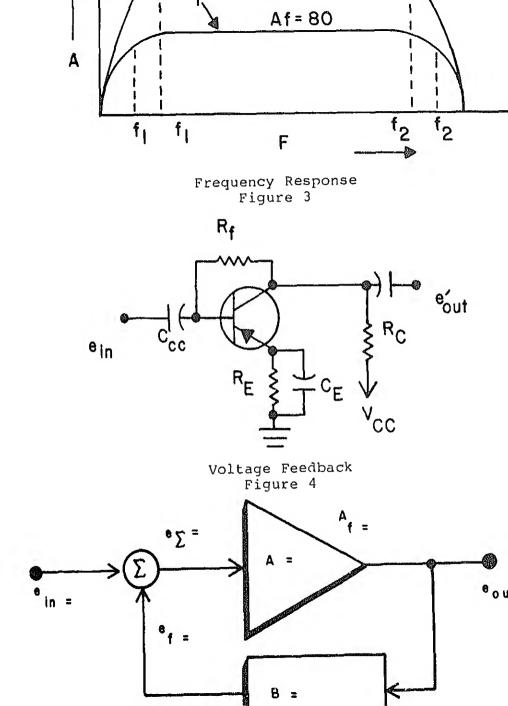
Circuits, NAVSHIPS 0967-000-0120, March 1980.

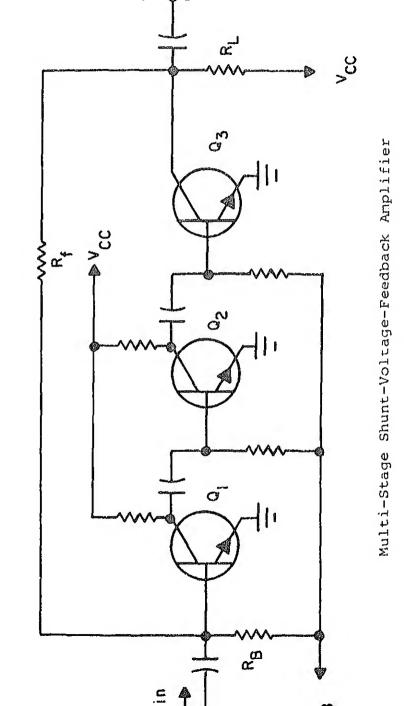
CGraw-Hill Book Company, Inc., 1961.

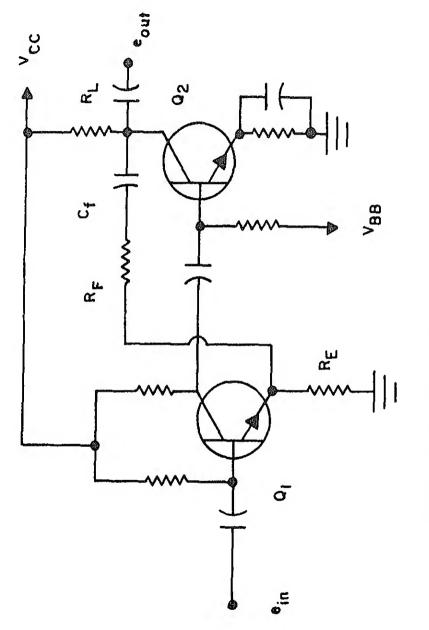


Open-Loop System
Figure 1

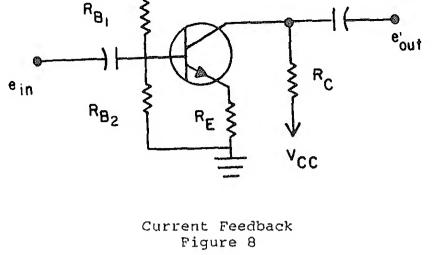








Multi-Stage Shunt-Voltage-Feedback Amplifier



Gain Formula

tween the input/output terminals. The drive to the gath ock (figure 1) is caused by ein alone and not by any rtion derived from eout.

Output Pagin Grant formula is Av = Cout. Therefore, cout =

e basic gain formula is  $A_V = \frac{e_{out}}{e_{in}}$ . Therefore,  $e_{out} = n^A v$ .

y change in  $A_V$ , causes a variation in  $e_{\rm out}$ . osed-loop system implies there is some form of feedbactom the output back to the input. It is used to overcome sensitivity of  $e_{\rm out}$  to variation in  $A_V$ . The principathe closed-loop system is based on error detection.

presents a gain (or loss) factor introduced into e'out fore it emerges as ef (the feedback voltage) where e'o the output signal with feedback applied. β is indicated decimal form and may be -or + to indicate whether it degenerative or regenerative. This will cause ef to

decimal form and may be -or + to indicate whether it degenerative or regenerative. This will cause  $e_f$  to or subtract from  $e_{in}$ .  $\sum$  is the symbol of the error tector. It will aid in developing  $e_{\sum}$  which is the gebraic sum of  $e_{in}$  and  $e_f$ .  $e_{\sum} = e_{in} + e_f$ , where  $e_f = e_{out}$ . The output will follow the input quite closely  $e_{\sum} = e_{in} + e_f$ . The drive to the gain block is

ried in such a manner as to hold of a relatively cons

therefore,  $e'_{out} = A_v(e_{in} + \beta e'_{out})$ . Multiplying th  $A_v$ ,

e'out = Avein + Avße'out to collect terms,

 $-A_{vein} = -e'_{out} + A_{v}\beta e'_{out}$  or, as is commonly writt

Avein = e'out - AyBe'out, and

 $A_{vein} = e'_{out}(1-A_{v}\beta)$ , dividing,

 $e'out = \frac{A_V e_{in}}{1 - A_V \beta}$ 

The closed loop gain (with feedback) is Af.

 $A_{f} = \frac{e'_{out}}{e_{in}}$  or as has been resolved previously,

 $A_{f} = \frac{A_{v}e_{in}}{1-A_{v}g} + e_{in}$  which could be rewritten as

$$A_f = \frac{A_V}{1 - A_V \beta} = closed-loop gain$$

# Negative Feedback Amplifiers

- 4. General
  - There are several types of feedback circuits; determined by the nature of the signal that is and the manner in which it is applied to the i circuit. Thus the feedback signal can be prop to the load current or to the load voltage.
    - 2. The signal fed back can be applied in series of shunt with the input circuit. It, therefore, that there are four basic types of feedback ci and they are:

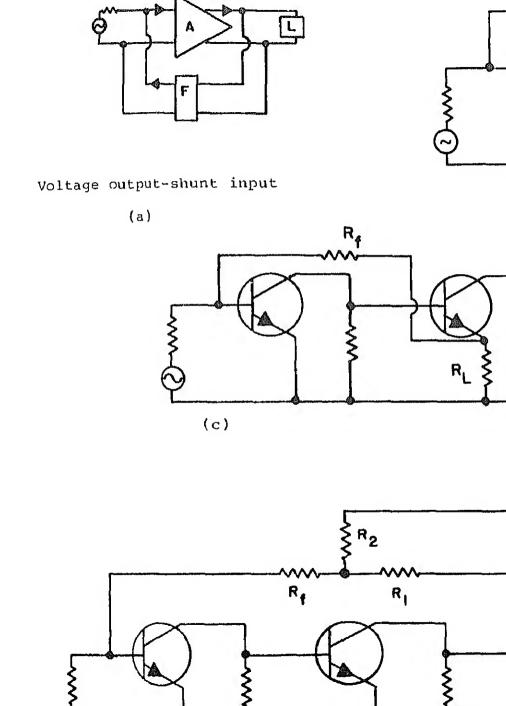
To investigate these effects, we will use the block liagram form and basic schematic diagrams. The blocks vill contain both the signal input and output leads. olus the common input and output leads for clarification he assumptions made are that the basic amplifier is inilateral; that is, there is no interaction between it nput and output terminal pairs and the input/output mpedance of the feedback network is sufficiently high ensure that it does not load the basic amplifier. further, simplification is obtained by omitting all con ponents that are bypassed, those capacitors with negligible reactance at mid-frequencies, and the d-c plasing circuits. The signal generator is always dislayed along with its internal resistance. ige output-shunt input rigure 9a shows the feedback block, "F", across the loa and the input. Any change in voltage across the load : sampled and a portion of this sample is applied across, or in shunt with the input terminals. Note, in the following sections of figure 9, the feedback resistor n series with the input resistance of the first stage. If the feedback block is in shunt with both the input/ output terminals of the gain-block, then the input/outp resistance must be lower with this type of feedback. Also, the polarity difference between the input signal and feedback signal is 180°. The gain-block resembles constant-voltage source and is rendered insensitive to device parameter changes, relative to the amount of fee back applied. In the schematics shown, blocking capacitors would solate the d-c voltages from upsetting the bias levels lowever, with careful design, the bias levels can be se

The input and output impedances of these four types of

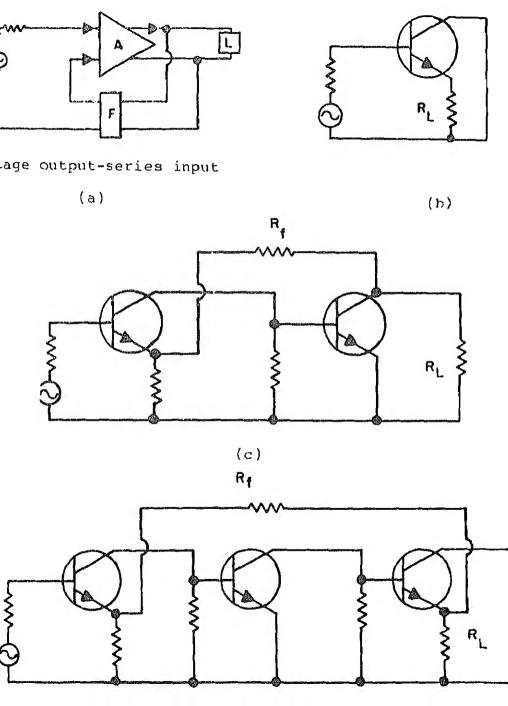
eedback circuits are affected differently by the applied feedback, but their individual gains will be

ffected similarly by the applied feedback.

1. The current output-series input.



e 9b represents a single stage with local feedback ed. Figure 9c is a CE to CC configuration, with the t resistance extremely low. Figure 9d shows three s of CE amplifiers. The load for the output stage .  $R_1$  and  $R_2$ , in series, are in parallel with  $R_1$ , ne portion of the output voltage at their junction d back through Rf, which is in series with the R; of irst stage. l the cited cases, the input driving signal has been tively reduced, reducing the output signal. Both aput and output resistances are lowered. Bandwidth creased, distortion reduced, stability increased, eriodic noise reduced. utput-series input e 10a is the block diagram of this feedback arrange-The voltage across the load is sampled and a on of it, called the feedback voltage, is applied in s with the input signal. The polarity of the feedsignal is such that it will oppose the input signal. ing the effective drive to the gain-block. e 10b shows the extreme case of 100% voltage feedin an emitter follower or CC amplifier. Reasoning ls that this could not be 100% degeneration, or else would be no output. The only way to cause 100% eration would be to throw the power "on/off" switch e "off" position. e 10c shows two CE amplifiers and figure 10d has an CC stage to effect a much lower output resistance. 1 cases shown so far, the output circuits are ed by the feedback circuits, lowering the output tances and keeping the output signals constant, with tions in the gain-block. However, in figure 10, the ack voltage is applied in series with the input l, thus greatly reducing the input driving signal nt. This has the effect of increasing the input tance. The polarity of the feedback signal is in with the input signal and opposes its action. fore, the input resistance is increased while the t recistance is lowered. With this application of



owered by this type of feedback. The feedback signa aken from R1, which samples the output load current. s then applied through Rf in series with the Ri of t irst stage. Since this type of feedback tends to ke he output current constant, the gain-block resembles onstant-current generator with its high output esistance. n figure 11c, Ro samples the load current and is als art of the load resistance of the last stage. Loadurrent variations develop the feedback signal voltag cross R1. The gain, stability, distortion, and nois his type of feedback application are similar to the thers discussed.

iqure 11b shows a CE to CE amplifier with the output esistance being increased and the input resistance b

nt output-series input

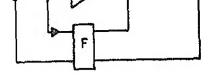
igure 12a shows a block diagram with the output load

reatly controls the input driving signal current. T nput and output resistances are increased by this ty eedback application. Figure 12b shows the CE amplif ith the resistor in the emitter leg. It is strongly imphasized here that this resistor will prevent therm unaway. Reasoning reveals that if the output curren ends to "run", the feedback voltage it develops acro educes the forward bias, resulting in slowing the "r

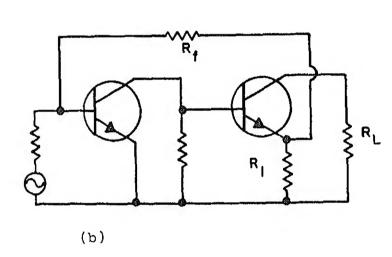
surrent flowing through the feedback sampling circuit nd the feedback voltage developed by the load curren hich is applied in series with the input signal.

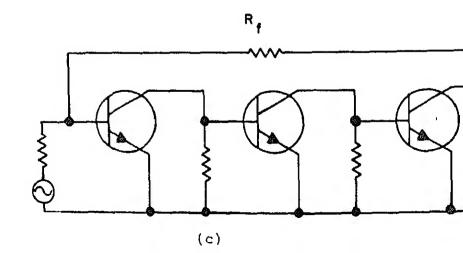
his application maintains a constant output current

o a "crawl" and a "stand still." This resistor, whe ypassed, allows maximum stage gain. However, when inbypassed, it introduces degenerative feed-back to t applied a-c signal and improves the stability, bandwi listortion, and noise figure as discussed previously.



Current output-shunt input (a)





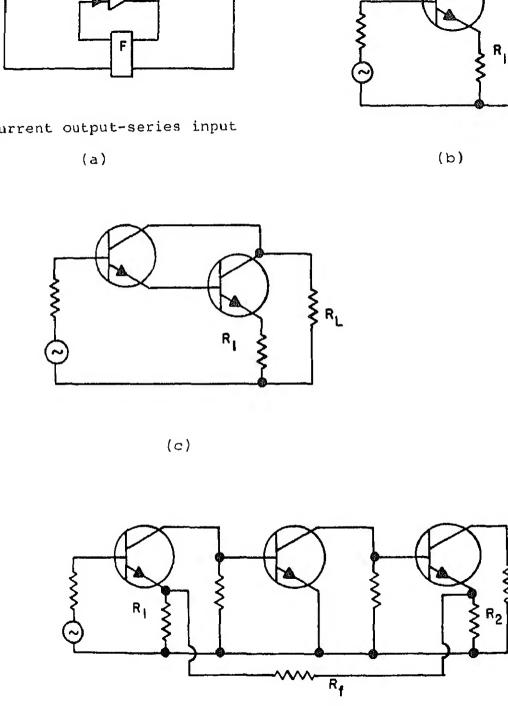
ng on the requirements, feedback can alter slightly cically, the input/output resistance of any type of er. The characteristics of one can be overshadowed ner, depending on the amount of each applied.

lOc is voltage output-series input, but the emitter

al feedback

First stage introduces a small amount of current series input, locally. This, of course, is able, because the emitter of the first stage must a ground for injection of the overall feedback. The same holds true for figure 10d.

plexities which reactive components add to feedback great to be analyzed in this allotted time. The ian will see various types and applications during ableshooting procedures. With experience and studies, you will become familiar with the forever feedback circuits.



s of Radio-Electronics, Slurzburg & Osterheld, McGraw-Second Edition, 1961.

c Circuits, NAVSHIPS 0967-000-0120, March 1980.

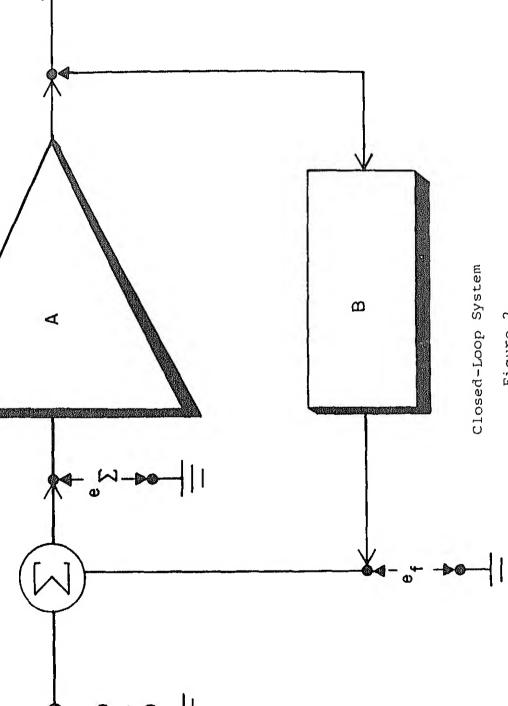
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TLINE:

pen-Loop System

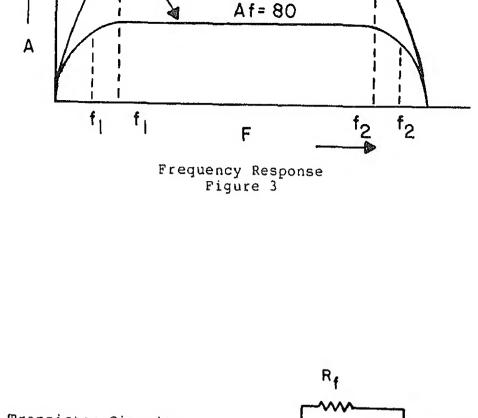
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III. Classes and Types of Feedback

## Characteristics



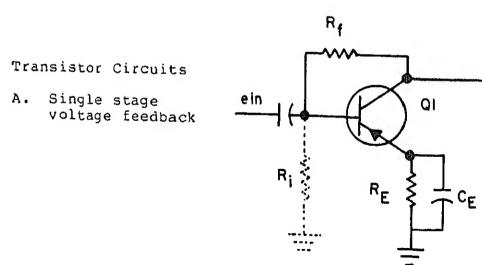


Figure 4 - Single-Stage-V Feedback.

C. Multistage voltage feedback (series)

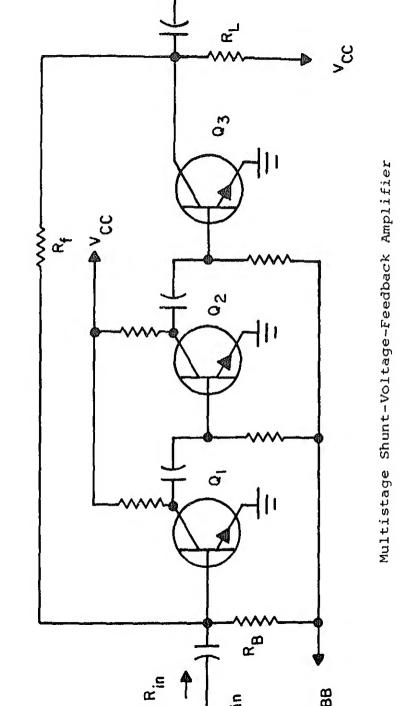
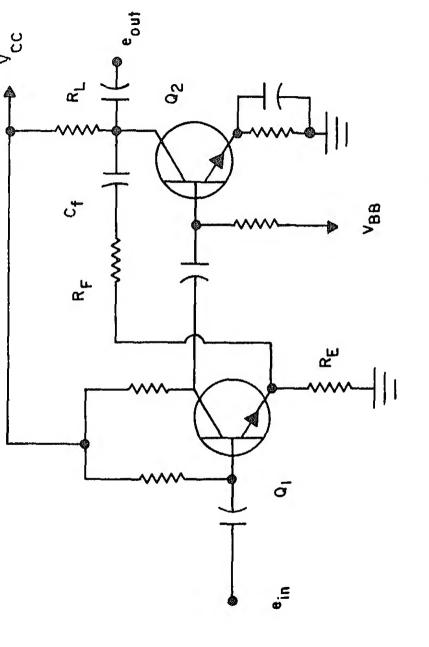


Figure 5

## D. Current feedback



Multistage Series-Voltage-Feedback Amplifier

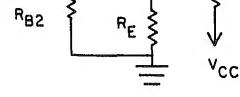


Figure 7 - Current Fee

E. Combination feedback

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-3 V d - c

n systems, require the amplification of d-c voltages stage of amplification is not sufficient to bring of such signals to the required values; therefore, types of coupling are necessary to ensure that maxice of energy is required. This lesson on direct

perational amplifiers is essential for the

Kiver, Transistor and Integrated Electronics.

Shrader, Electronic Communication, McGraw-Hill Book

1 Book Company, Fourth Edition, 1972.

ing figures are labeled by title and will assist you ng the instructor through the lesson.

R<sub>B2</sub>

Figure 7 - Current

onic systems, ranging from voltage regulators to compi tion systems, require the amplification of d-c voltage

one stage of amplification is not sufficient to bring de of such signals to the required values; therefore, nt types of coupling are necessary to ensure that maximence of energy is required. This lesson on direct doperational amplifiers is essential for the

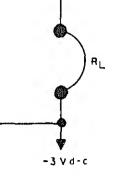
S. Kiver, <u>Transistor and Integrated Electronics</u>. Hill Book Company, Fourth Edition, 1972.

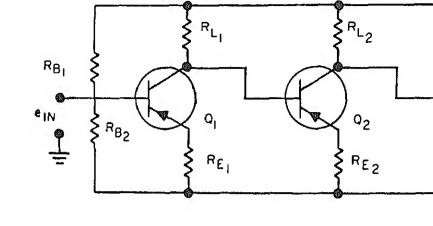
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L. Shrader, Electronic Communication, McGraw-Hill Book

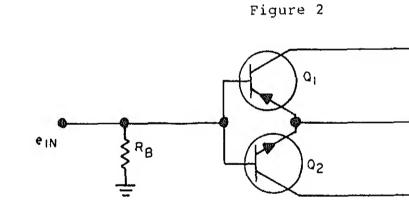
owing the instructor through the lesson.

, Fourth Edition, 1980.

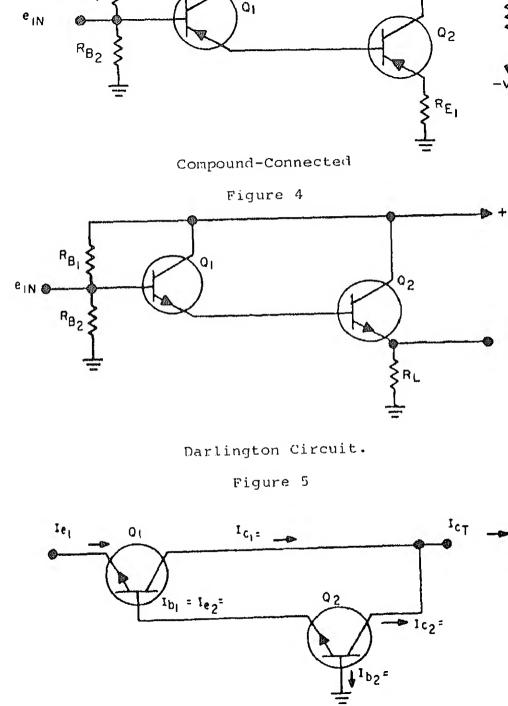


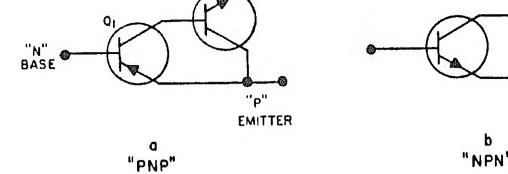


Cascaded CE d-c Amplifier.



Complementary Symmetry





Complementary Darlington's

Figure 7

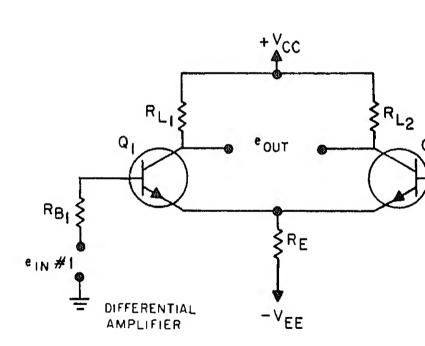


Figure 8--Modulated a-c Carrier

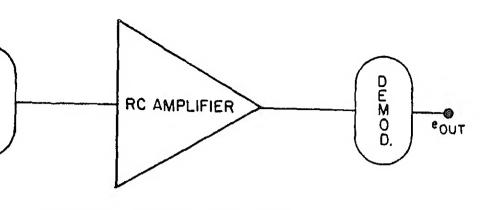


Figure 9--Chopper Amplifier

#### ED AUDIO AMPLIFIER

ion

ct-coupled audio amplifier is used where high gain udio frequencies or amplification of direct (zero frequency) is desired. The direct-coupled plifier is also used where it is desired to e loss of frequencies through a coupling network. cuit has numerous applications, particularly in s, measuring or test instruments, and industrial equipment.

### ristics

common-emitter circuit for high gain.

lly requires thermal stabilization to prevent way.

uency response extends to zero frequency (direct ent).

onds equally well to pulses or sine waveforms.

## Analysis

In most instances, however, the becomes a major problem if more than two amplification are cascaded. 2. Germanium transistors are more subject to instability than are silicon transistors case it is usually necessary to provide temperature compensation if the temperature centigrade. The complexity of the compet cuitry is dependent upon the amount of co Because of the rapid changes which are of semiconductor field, it is likely that to pensation will be eliminated or minimized degree in the future. Even so, however, limitaion of direct coupling still remain necessity for cumulatively increasing the operating values as each stage is cascade use of low bias and collector voltages pe more range than can be obtained with the the transistor, like the electron tube, maximum breakdown or reverse potential 1: 3. In addition, noise is a problem, since the amplifies any internal noise as well as transistors are prone to produce greater lower audio frequencies. Thus, the abil amplifier to extend its response to low normally available through other coupling somewhat nullified by the amplification noise in the transistor. Generally speak the low-frequency response of the d-c am limited only by the signal-to-noise ratio high-frequency response is limited by the response characteristics of the transiste In the direct-coupled amplifier, the col input stage is directly connected to the second amplifier stage; therefore, any co variation also appears at the base of the just as if it were a change in the input the transistor in the second stage has no

criminating between actual input signal

is also applied to another element. No por decrease is self-correcting in the fo

on of the forward-bias characteristics of a manium diode with temperature is shown in The forward-bias variation is usually s a change in bias voltage with temperature nt forward-bias current. It is usually becomes significant because of the large on it receives because of the direct-coupling Figure 10 mer in which the collector-base diode varies

erse saturation current with temperature is lown in figure 11 (for a typical germanium stor). In this instance, the figure shows be reverse-current characteristic is highly sture-dependent, and relatively large current

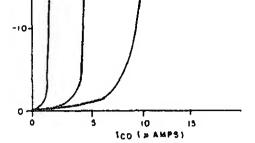
ons are produced as the temperature is

in any stage or on any element will be proportionally, and a change of output will h changes in bias levels normally occur as a emperature variations, aging, difference in

or changes in transistor leakage current, and

characteristic due to manufacturing

d to as drift.



VARIATION OF COLLECTOR-BASE DIODE REVERSE CURRENT

## Figure 11

In a similar manner, it can be shown that

8.

- current transfer characteristic of a germ sistor also varies with temperature; howe case the gain can either increase or decr temperature (silicon types generally incr temperature). The percentage variation i temperature varies greatly with the operation many units show a change in sign as well The gain variation of a silicon type may ten times that of a germanium type. Thus, that the major sources of drift in transi changes in the d-c properties of the coll emitter-base diodes, and changes in the transfer ratio. Generally speaking, in operation and performance of germanium as transistors, it can be said that at temperature that of the reference temperature, To, the comparable. At and above the reference silicon type tends to have lower drift. temperature for silicon is 100° centigrad germanium is 60° centigrade. With low so ance, low values of drift are obtained al with high source resistance, the best pe at temperatures where the reverse-satura
- 9. In d-c amplifiers, low drift is obtained with low values of collector current; th reverse-leakage current by keeping the v the collector and the base at a low value

is a forward bias for reverse current.

current may be neglected.

econd stage tend to help cancel the input-stage drift; in a differential d-c amplifier, however, the drift in he second stage may either aid or oppose that of stage, depending upon the design.

espite the apparent disadvantages of the d-c amplifier t does produce (for a two-or three-stage unit) high ain and good fidelity, particularly in the low-requency portion of the spectrum. It also provides mplification with as few parts as possible; thus, it i conomical to build. In actual practice, the d-c

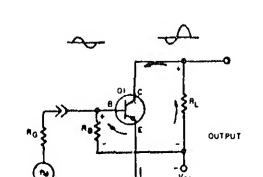
mplifier is usually limited to one or two stages of mplification because of drift, especially where d-c ust be amplified or where frequencies of 10 to 12 Hz

s somewhat limited. In single-ended amplifier stages, oth the current drift and the voltage drift in the

re of importance. To overcome the effects of drift in -c amplifiers, a special "chopper amplifier" has been eveloped; this amplifier converts the d-c into a-c so hat the stages can be isolated and thus prevent the umulative drift which normally occurs. This is a pecial type of amplifier, which will be discussed late n this section of the Information Sheet.

it Operation

asic Circuit. The schematic of a basic common-emitter -c amplifier is shown in figure 12. the input signal s represented by the AF generator with an internal esistance equal to R<sub>INT</sub>. The input signal is applied etween base and emitter. Transistor Q<sub>1</sub> is biased by



normally chosen for class A operation. Th electron current flow through the collecto resistor, R<sub>I</sub>, is indicated by the arrows. of the resulting d-c voltage across the lo is as shown. When the positive alternation signal is applied to the base, the base-to is reduced (since the signal and bias volt opposite polarity). Because the base-to-e tial is now less than the normal value, th from the emitter to the collector is lower electron flow through the output load resi reduced. The decrease in voltage drop acr duces a negative swing and, consequently, negative output signal across RI. As the input signal goes negative, the bias poten by the input signals, and as the base-to-e is increased, more hole current flows to t This produces more electron flow through t circuit, increasing the voltage drop acros produces a positive output-signal swing du that the input signal is negative. This e produces an opposite-polarity output signa referred to as a 180° phase reversal). Si load for both d-c and a-c, there is only of line, and any internal noise voltages flow the load resistor add to the developed out Since the output across RI is applied dire base of the next stage, it can be seen that components appear across the following inp In an a-c coupled circuit, these noise com sisting of d-c or very low frequencies, ar eliminated (blocked by the coupling capaci noise components are produced by thermal e also result from electron flow through the resistor. They include the so-called whit generated by diffusion-recombination effect transistor (similar to shot noise in the e and surface and leakage noise from the tra is sometimes referred to as semiconductor to distinguish it from white noise. Such mostly confined to the region of from 1 to white noise (in the audio range), with the noise predominating and increasing for fre than 1 kHz. The d-c noise results from su

Obboses circ pres becauses: sees.

frequencies. Stages. Because of the high gain possible per y applications require only a single stage of ed amplification. Where more than one stage is transistors offer circuit arrangements that ssible with electron tubes. For example, ie use of complementary symmetry, it is to connect the collector of the input stage o the input of the second stage without disas arrangements, and to use the same supply. alternate arrangements of NPN and PNP tranonly one supply is needed. Recall that in the be d-c amplifier, as each stage progresses, the age is increased, with the grid being tapped the preceding-stage plate voltage to obtain Only tandem arrangements of similar-type s can follow this principle. The term complemmetry is derived from the fact that the NPN is the complement of the PNP transistor, with its operating identically, but with opposite Figure 13 shows a simple direct-coupling ing complementary symmetry.

ier nand, with proper input and output matchnum gain is obtained in the stage; moreover, oupling network to create a loss between xinum output and efficiency are produced. frequencies are present, including d-c (zero and are applied equally to the next stage, it lerstood why the d-c amplifier presents maximum excellent frequency response, particularly at

4. By the use of a special compounding contransistors may be employed as a special amplifier to obtain linearity and almos (alpha). Figure 14 shows the compound connection, using the common-base confi

saving in components. To do this, of c

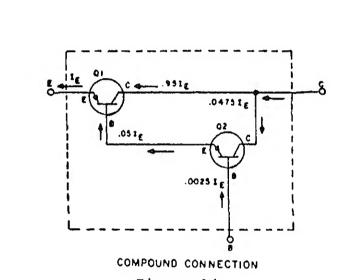


Figure 14

Note that the input to the second stage current of the first stage. Effective impedance is the series combination of sistors, while the outputs are in paralicircuit is roughly analogous to the pus

to afe, the total combination value (.9

tube circuit. Actually, this circuit is single-transistor compounded-type circuit base, and collector resistors used extendirection and relative values of currer in the figure, assuming the use of two an equal afb of .95. When these values

a gain of 399 as compared with afe of transistor, or more than the normal gain cascade (19 x 19 - 381). Compounded

an amplifier, or are used as the d-c amplifier in a

ypical three-stage, single-ended d-c amplifier is wn in figure 15. It represents the minimum of parts d-c supplies needed for a high-gain, three-stage plementary-symmetry type of d-c amplifier for small

Figure 15

۷٤٤,

TYPICAL THREE-STAG AMPLIFIER

tage-regulator circuit.

nal applications.

driving voltage, and zero base current exists. The lector current,  $^{\rm I}{\rm CEO}_1$ , flows through the base of ge 2, which is biased by supply  $^{\rm V}{\rm EE}_2$  in series with emitter of stage 2. Since stage 1 uses a NPN trantor, the positive emitter bias of stage 2 is of the

ough the input device, it is effectively open, it has

shown, the base of the input stage is completed

per polarity to act as collector voltage for Ql. And any in the collector current of stage 1 appears at collector of stage 2 in amplified form; that is, = B<sub>2</sub>I<sub>CEO1</sub>, where B<sub>2</sub> is the current gain of stage 2. ge 2 uses a PNP transistor; therefore, by comple-

tary symmetry, stage 3 must also be an NPN stage

act as emitter-swamping resistors to help amplifier with respect to temperature var:

Assuming that the input stage has a collection.

5 μA and assuming a gain of 38, the second have a collector current of 190 μA. With the third stage collector current will be clear that any slight change in the current caused by temperature or noise will be greated and appear at the output of stage 3. With tivity and amplification, therefore, it is mandatory that such an amplifier be tempe compensated, even if room temperatures do excessively. Naturally, the amplitude of signal must be limited if true fidelity is

obtained. Driving the transistor into cursaturation would clip the peaks of the signal electron-tube operation. It is also electron-tube operation. It is also electron-oise transitors must be used; otherw might mask the signal. Note that in this small emitter bias of stage 20perates as voltage of stage 1. Low collector voltage minimize noise generated in the input stage.

ional amplifier is an extremely efficient and device. Its applications span the broad electronic illing requirements for analog instrumentation, putation, and special system design.

to describe amplifiers that performed various al operations. It was found that the amplification a feedback around a high gain d-c ampifier would circuit with precise gain characteristics that ally on the type and amount of feedback used. By the action of feedback components, operational amplifier buld be used to add, subtract, multiply, divide, and differentiate.

al amplifier techniques became more widely known, it not that these feedback techniques could be used in all and instrumentation applications. Today, the e of operational amplifiers has been extended to the applications as d-c amplifiers, a-c amplifiers, so servoamplifier, deflection yoke drivers, and a mers.

perational amplifier can do is limited only by the and ingenuity of the user. With a good working of its characteristics, you will be able to exploit the useful properties of operational amplifiers.

Integrated Electronics, Kiver, McGraw-Hill, Fourth pages 271-305

An operational amplifier is a high gain, direct amplifier utilizing degenerative feedback for
 its amplification factor.

Gain itself is determined by the ratio of inp 2. output voltage.  $A = E_0$ . The voltage gain of an operational a ratio of Eo: Ein.

than one, then the operational amplifier is d For example, an amplifier with a gain of .5 w

they are called by several names; computing a isolation amplifier, feedback amplifier, and

However, the amplifiers do improve the perfor 3. various computing loops, by accomplishing the reversing the sign of a voltage with or witho scale factor; isolate or eliminate the loadin puting element from another; provide a voltag to the algebraic sum of two or more input vol the various functions performed by operationa

multiply its input by 1/2.

C. Functional analysis

amplifier.

1. Amplifier section

a.

- In order to better understand operational we will first go through the different po operational amplifier.
- The heart of the operational amplifier is ъ. It is represented by the triang It contains an odd number of direct-c
- amplifiers, usually three or five stages.
  - number of amplifiers are required to prov grees of phase shift from input to output
  - voltage will always be oppostie or invert respect to the input polarity to provide feedback. Open loop gain, that is the gain of the a without feedback, is from 1 x  $10^3$  to 2 x c.

usually around 50 x  $10^3$  or 50 k; 92 dB.

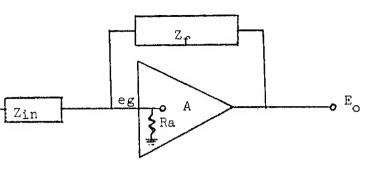


Figure 1

igure 2, is an expanded view of the amplifier ion in block diagram form.

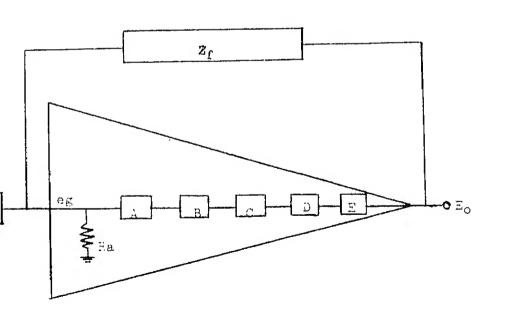


Figure 2

```
100 = 1,000,000. Because there is an odd
    stages, phase inversion always occurs.
    The final stage again will be either a ca-
q.
    or an emitter follower for further isolat
    R_{\text{a}} is the base or grid resistor for the f It develops \mathbf{e}_{\mathbf{g}} or the input potential for
h.
    section.
   The effective input impedance is very low
i.
    found by the formula Z_{in} (of amplifier se
```

Some typical values are:

f. Blocks B through D are the d-c amplifiers stage gain of only 100 then the over gain circuit would be 1,000,000 1 x 100 = 100

 $Z_f = 1 \text{ megohm}$ A = 50k

If they are put into the formula, then  $\frac{1}{1+}$ approximately. The effective input imped low.

j. The amplifier section's output impedance 
$$Z_O$$
 of the amplifier section may be found formula 
$$Z_O = \frac{r_D}{1+\Delta B}$$
 where

 $r_p$  = plate resistance of the final am B = ratio of input impedance to the s and feedback impedance

 $B = \frac{z_{in}}{z_{f+z_{in}}}$ 

with some typical values  $r_p = 50 k\Omega$ 

division by a constant, differentiation, integration nd other special function circuits. he input impedance,  $z_{in}$ , is usually in the 500 k to : egohm range. It couples the input voltage from the receding stage. It is also used as a current summing etwork to reduce Ein to eg the input voltage to the aplifier section.

unctions such as algebraic summation, multiplication

mpedances, and the type of impedance, specific

ne feedback impedance Zf is also in the 500 k to 10 egohm range. It develops the output voltage Eo and ouples the feedback current and voltage form output nput. operation

tion ne input voltage Ein causes a current Iin to flow arough Zin.

unction of the circuit in figure 3 is to reverse the

of the voltage, and give a gain of -1.

 $I_{in} = \frac{E_{in}}{Z_{in}}$ f E<sub>in</sub> is a positive voltage, then R<sub>a</sub> will develop a mall positive voltage  $(e_g)$  at the input to the ampli-ier section. The amplifier section will amplify  $e_g$ nd invert it (odd number of stages) causing a negati-

٥, he resulting difference of potential between the inp erminal and output terminal will cause a current (If

Ifb =  $\frac{-E_O}{Z_f}$ 

o flow through Zf.

---

The final stage again will be either a cat! g. or an emitter follower for further isolatic Ra is the base or grid resistor for the fir h. It develops eg or the input potential for section. The effective input impedance is very low. found by the formula Zin (of amplifier sec Some typical values are:  $Z_f = 1 \text{ megohm}$ 

A = 50k

Blocks B through D are the d-c amplifiers. stage gain of only 100 then the over gain circuit would be 1,000,000 1 x 100 = 100 x 100 = 1,000,000. Because there is an odd stages, phase inversion always occurs.

If they are put into the formula, then  $\frac{1M}{1+5}$ approximately. The effective input impedan low. j. The amplifier section's output impedance is

 $Z_{\rm O}$  of the amplifier section may be found by formula

$$Z_0 = \frac{r_p}{1+AB}$$
 where

 $r_{D}$  = plate resistance of the final amp

B = ratio of input impedance to the sur and feedback impedance

 $B = \frac{Z_{in}}{Z_{f} + Z_{in}}$ 

with some typical values  $r_p = 50k\Omega$ 

functions such as algebraic summation, multiplicati or division by a constant, differentiation, integra and other special function circuits. The input impedance,  $Z_{in}$ , is usually in the 500 k t megohm range. It couples the input voltage from the preceding stage. It is also used as a current summ network to reduce Ein to eg the input voltage to the

impedances, and the type of impedance, specific

couples the feedback current and voltage form output input. of operation e function of the circuit in figure 3 is to reverse t

gn of the voltage, and give a gain of -1.

The feedback impedance  $Z_f$  is also in the 500 k to 1 megohm range. It develops the output voltage Eo ar

The input voltage 
$$E_{in}$$
 causes a current  $I_{in}$  to flow through  $Z_{in}$ .

$$I_{in} = \frac{E_{in}}{E_{in}}$$

eration

amplifier section.

 $I_{in} = \frac{E_{in}}{Z_{in}}$ 

If Ein is a positive voltage, then Ra will develop small positive voltage (eg) at the input to the amplier section. The amplifier section will amplify

and invert it (odd number of stages) causing a nega Eo. The resulting difference of potential between the

terminal and output terminal will cause a current

$$\frac{-E_O}{Z_f}$$

to flow through Zf. Ifb =  $\frac{-E_O}{Z_f}$ 

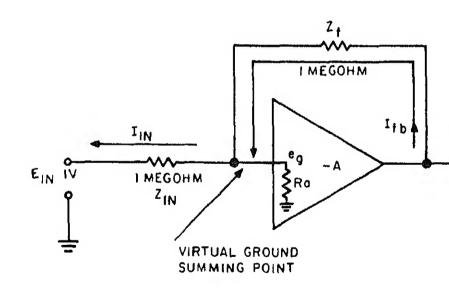
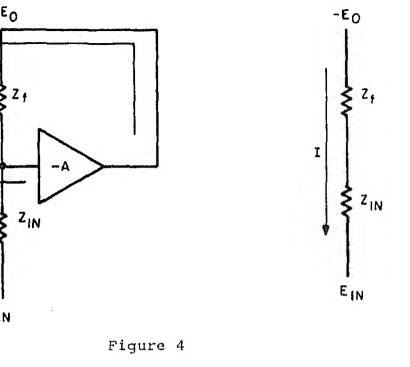


Figure 3

BASIC OPERATIONAL AMPLIFIER OPERATION

$$Gain = \frac{Zf}{Z_{in}}$$

$$E_O = \frac{Zf}{Z_{in}}$$



d I<sub>fb</sub> appear in series and in series circuits rrents are equal.

 $I_{in} = I_{fb}$ , then by algebraic substitution:  $n = \frac{E_{in}}{Z_{in}}; I_{fb} = \frac{-E_{o}}{Z_{f}}$ 

g for 
$$E_0$$
; multiply by  $(-Z_f)$ .  
 $\frac{E_{in}}{Z_{in}} = \frac{+E_0}{Z_f} (+Z_f)$ 

 $E_O = \frac{-Z_f}{Z_{in}} E_{in}$ 

amplifier is determined by the ratio of its circuit configuration and its funct circuit. In figure 3, then, with an input voltage  $z_{in} = 1M$ ;  $z_f = 1M$ .  $E_O = \frac{-1M}{1M} 1V = -1V = \frac{-1M}{1M$ Sign inversion and a gain of negative of The feedback current (Ifb) is determine k. Zin and Ein and Ifb will equal Iin at a l.

l. With LV in and Z and Z in both 1 megohin 
$$I_{in} = \frac{E_{in}}{Z_{in}}$$
 
$$I_{in} = 1V$$

 $I_{in} = \frac{1V}{1M}$ 

 $I_{in} = l\mu A$ 

transposing the formula. The gain of t

Ifb is equal to  $\frac{Z_0}{Z_0}$ 

Ifb =  $\frac{-1V}{1M}$ 

 $I_{fb} = 1\mu A$ 

Ifb = Iin

m.

If Z<sub>fb</sub> is increased to 2 megohms with remaining unchanged, then  $E_0 = -2V$ .

Ifb =  $\frac{E_0}{Z_f}$ 

 $=\frac{-2V}{2M}$ 

y be performed if the  $Z_f:Z_{in}$  ratio is less 1 = division

eg is very small and may be determined from in A

eg is equal to  $\frac{E_{O}}{A}$  where A is the open loop amplifier section.

as Ein and Zf of 2M and Zin of 1M, then

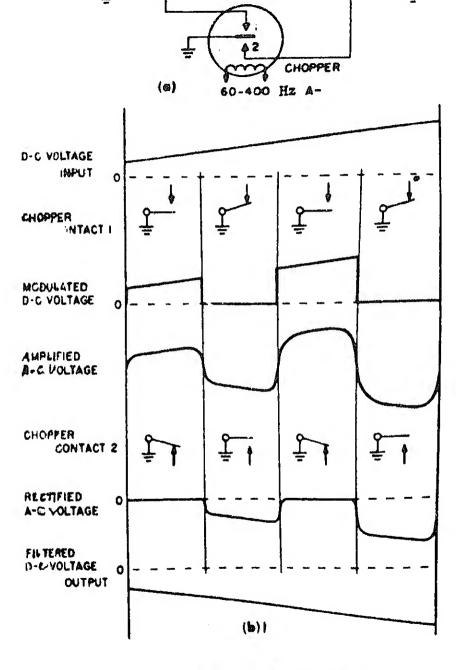
 $rac{V}{k}$  - open loop gain.

at this point is called virtual ground. ve impedance is very small. Current flows point and away from it acting as a ground.

onal amplifier constantly seeks to obtain a ground. So, when Ein increases or Eo must correspondingly change, by amplifier cause a current to flow through Zf that just a current flow through Zin.

amplifiers are self regulating. If Eo due to amplifier gain, component variation,

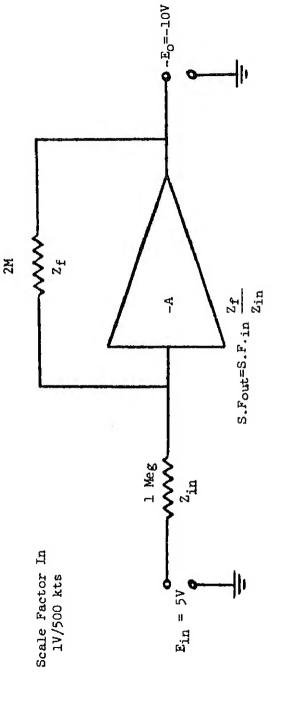
k increases.



The chopper amplifier.

put offset voltage to zero. A similar action occurs ative drift voltages except that the polarities of the olved signals would be reversed. illustrate the properties of high-quality computer am iers using chopper stabilization, some representative cifications are tabulated below: Gain of the d-c amplifier channel, 30,000 to 150,000 Gain of the automatic balancing channel, 2000 to 3000 Total d-c gain,  $25 \times 10^6$ . Grid current, less than 10-4 µA. Average drift over an 8-hour period, 20 to 200 µV. Linear output range, at least ± 100 volts into rated load; decreases above 100 Hz, depending on tube type actors input scale factor will be changed by the gain of an lifier. In an isolation amplifier with a gain of -1, Zin ratio of one, there will be no scale change. The no change in analog units; therefore, no change in sca tor. If the gain of the circuit is more or less than , the scale factor must be changed. identity process is used to change scale factors. If the output voltage is different from the input voltage, then the ratio of analog units to equation units must also change. Refer to figure 7. In figure 7, the Zf to Zin ratio is -2. With 5V in, Eout is -10V. The input voltage represents 2500 knots; there fore, by the law of identity the output voltage must also represent 2500 knots. This means the scale fac must be changed. The output voltge would represent 5000 knots, unless the scale factor is changed.

ocessing by the chopper amplifier, would end up as a pative balance signal at the B terminal, reducing the



BASIC SCALE CHANGING OPERATIONAL AMPLIFIERS

$$SF_{O} = \frac{2}{500}$$

$$SF_{O} = \frac{1V}{250} \text{ kt}$$
The new scale factor  $1V/250 \text{ kts}$ , the output voltage still represents 2500 knots.

Equation units = S.F. x analog units
$$= (1V/250 \text{ kts})(-10V)$$

$$2500 \text{ kts out} = 2500 \text{ kts in}$$

alog devices, input variables must be scaled to sent the same information (equation units) in rent modules of the device. This may be accomplished ecircuits shown in figure 8. Note that the input mation to amplifier #1, 250 knots of airspeed from the eed circuits is represented by 5V at a scale factor

$$\frac{2M}{FO=-10V}$$

$$\frac{2M}{FO=-10V/125 \text{kts}}$$

$$\frac{10}{FO=-20}$$

 $SF_0 = SF_{in} \frac{Z_f}{Z_{in}}$ 

 $SF_0 = (1V/500 \text{ kts})(\frac{2}{3})$ 

Figure 9 Basic Operational Amplifier Circuits Η. 1. The circuits covered below are some basic ope amplifier circuits covered in outline form. only basic circuits. There are many more. 2. Summing Amplifiers are used as an electronic circuit. Eo represents the algebraic sum of voltages.

250 kts

250 kts

250 kts

-10V

+ 2V

-20V

d I i

out

1V/25 kts 1V/125 kts

1V/12.5 kt

in

1V/50 kts

1V/25 kts

1V/125 kts

Amp #1 5V

Amp #2 -10V

Amp #3 +2V

Summing Amplifier Definition - An operational amplifier with mo input.

Figure 10

R2

- 3. Operational amplifier switch operates as a sw operating point determined by the bias potent
- With no voltage present on R1 and with E2 a. voltage, the output voltage will be posit
- diode CR1 to conduct. Resistance of CR1 when conducting is very b.

Output voltage would be near zero.

Operational Amplifier Switch

o high.

1 that resistance of conducting diode is about hms.

$$z_0 = \frac{-z_f}{z_{in}} E_{in}$$

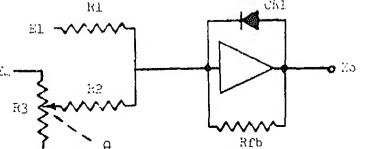
 $c_0 = \frac{-100}{1M}$  Ein

o is very small

input potential on Rl becomes sufficiently ive to drive input to a positive voltage Eo will e negative and diode CR1 becomes reversed biased. eedback impedance increases and gain switches from

specific gain is desired, a resistor is placed in

lel with the diode.



4. Logarithmic amplifier

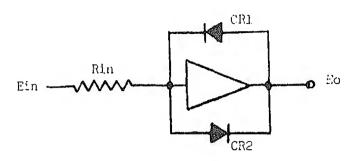


Figure 13

## Logarithmic Amplifier

- a. Diodes CR<sub>1</sub> and CR<sub>2</sub> are special function diod variable conduction level.
- b. Two diodes are used so that there may be bot and negative inputs.
- c. As input voltage increases in amplitude, one the other, depending on the polarity of the conducts.
  - (1) As diode conducts harder, current flow t
  - (2) It seems as if Zf had decreased.
- d. This results in a logarithmic gain for this
  - (1) High gain for small signals because of duction, therefore high resistance of di
  - (2) Low gain for larger signals.

Figure 14

## Integrating Amplifier

ates input voltage with respect to time by lating charge on capacitor.

ample, if an input voltage waveform represented ration, the output voltage would be the integral eleration, i.e. velocity.

ating Amplifier

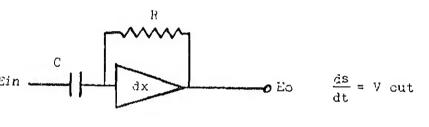


Figure 15

Differentiating Amplifier

entiates input voltage.

voltage represents derivative of input.

ample, if the input voltage represented displacethen the output would represent ds/dt or V. r and Integrated Electronics, Kiver, M. S., Il, Fourth Edition, 1972, pages 306 to 310.

d Circuits and Semiconductor Devices, Deboo and McGraw Hill, Second Edition, 1977, Chapter 4.

cs Communication, Schrader, R. L., McGraw Hill, ition, 1980, pages 216 and 317.

TLINE:

t-Coupled Amplifiers

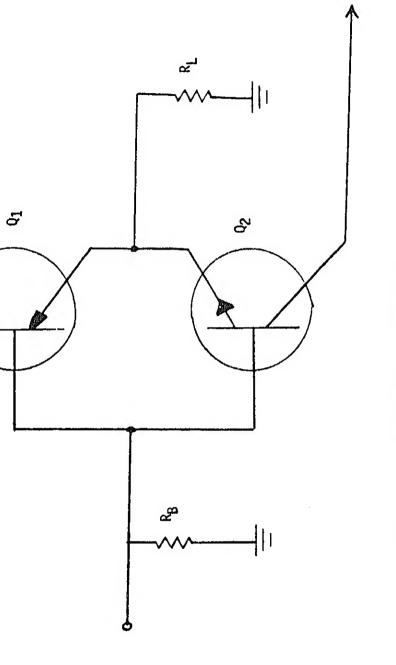
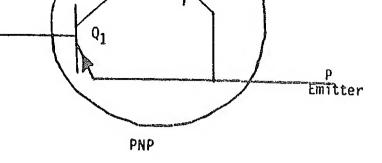


Figure 1 - Complementary Symmetry



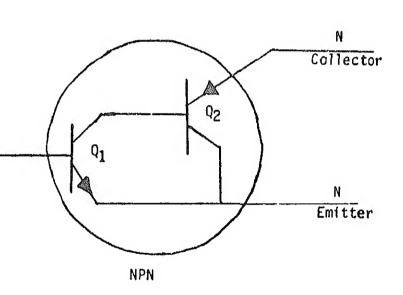
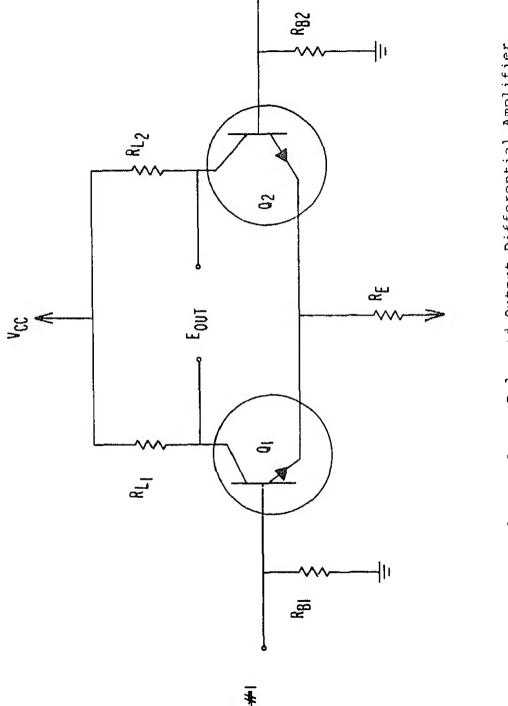
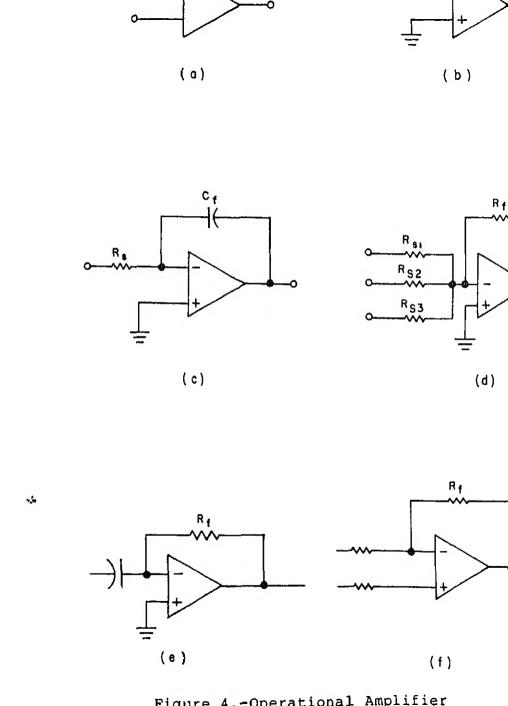


Figure 2.-Complementary Darlingtons.

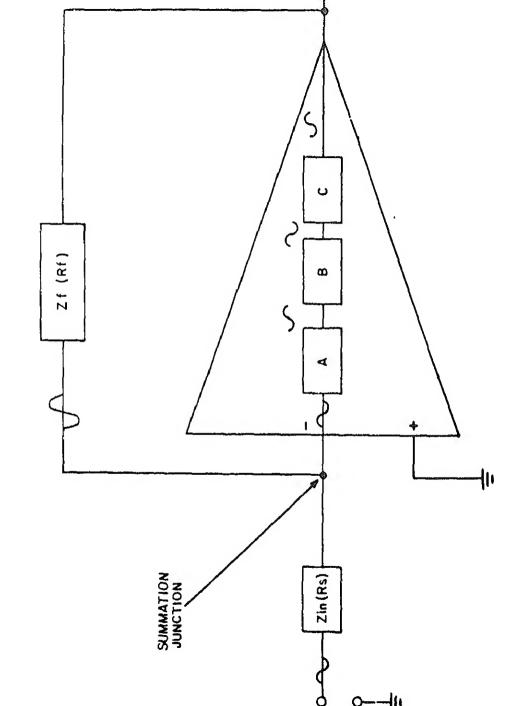






atic symbol

functional analysis



al amplifier

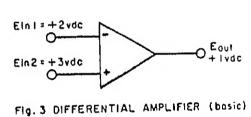
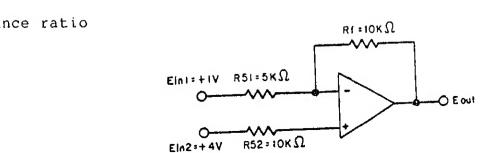


Figure 6



N

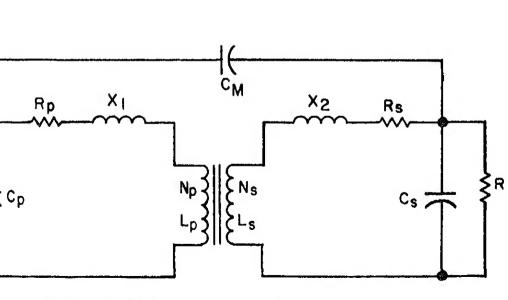
tion systems, require the amplification of d-c and a-Many times one stage of amplification is not sufficient amplitude of such signals to the required values; the different types of coupling are necessary to ensument transference of energy is required. This lesson or coupling is essential for the technician.

Hill Book Company, Fourth Edition, 1972.

L. Shrader, Electronic Communication, McGraw-Hill Book

S. Kiver, Transistor and Integrated Electronics.

L. Shrader, Electronic Communication, McGraw-Hill Boo, Fourth Edition, 1980.



TRANSFORMER EQUIVALENT CIRCUIT

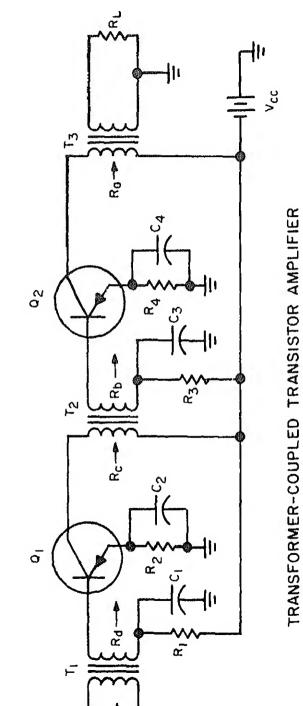


Figure 2

coupler is limited mainly by the collector output capacitance, and the low-frequency response is li by the shunt reactance of the inductor, L1. efficiency of the impedance coupler is approximat the same as that of the transformer-coupled circu (50% for the ideal case). See figure 3. Ccc ٥υτ L-C-L COUPLING ccc CUT IN

of an inductor broxide more offbar fugurine foad resistor. While the overall frequency response o impedance coupling is not as good as that of resi tance coupling, it is much better than that of transformer coupling, because there are no leakag reactance effects to deteriorate the high-frequen response. The high-frequency response of the imp

The

Impedance-Coupling Circuits

Figure 3

L-C-R COUPLING

2. Transformer coupling -- Transformer coupling is use extensively in cascaded transistor stages and pow output stages. It provides good frequency respor and proper matching of input and output impedance

yet coupled for a-c signal transfer. The winding presents a low d-c resistance, m colector current losses and allowing a lo collector voltage for the same gain as of methods, and it presents an a-c load impe following stage. The secondary winding the base d-c return path and provides be stability because of the low d-c (winding Since the transistor input and output im matched by using the proper turns ratio, able gain can be obtained from the trans 4. As in the impedance coupler, the shunt re transformer windings causes the low-frequency to drop off, while high-frequency respons by the leakage reactance between the prin secondary windings, in addition to the e lector capacitance. Because of the low in the primary winding, no excess power and the power efficiency approaches the theoretical value of 50%. в. Transistor impedance-coupled audio amplifier 1. Application -- The impedance-coupled trans.

Coupling between stages is achieved throunductive coupling of primary and secondary since these windings are separated physical input and output circuits are isolated for

3.

stage is desired with better response the vided by transformer coupling.

2. Characteristics

a. Uses common-emitter circuit for high

amplifier is used where higher gain than

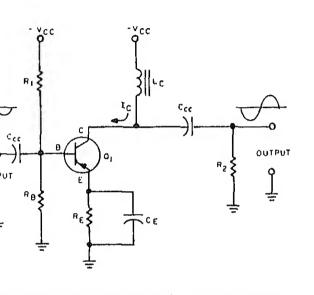
d. Is fixed-hiased from the collector s

- b. Operates class A for linear operation distortion.
- distortion.

  c. Usually amplifies small signals, but signed to handle large signals in ca

ar in a general sense to the impedance-coupled cron-tube amplifier.

ee 4 shows a conventional PNP, triode, commoner impedance-coupled transistor audio amplicircuit.



edance-Coupled Audio Amplifier

Figure 4

divider  $R_1$ ,  $R_B$  provides fixed bias form the ector supply. Emitter swamping is provided by or temperature stabilization;  $R_E$  is bypassed by Collector impedance  $L_C$  is the load across a the output voltage is developed; this voltage oplied through coupling capacitor  $C_{CC}$  to the at circuit. Resistor  $R_2$  is the base-to-ground stor in the next stage when cascaded amplifiers used, or is the output load resistor (such as a set) in a single-ended stage. (In some appliance,  $R_2$  may be replaced by an iron-cored etor similar to  $L_C$ .

input is shown capacitively coupled, and volt-

When the input signal goes positive, d. sinewave iput, the forward base bias instantaneously by the amplitude of signal, and collector current Ic is reduction in collector current cause across collector impedance Lc to dec toward the supply voltage, which is a negative-swinging output signal is When the input signal becomes negation the forward base bias and causes Ic The increase in collector current th duces a large voltage drop across th reduces the negative collector volta duces a positive swing. Therefore, output follows the input signal exce reversed in polarity; when the input positive, the output signal is negat versa. The collector output is deve the impedance of LC between the coll ground, and is applied through coup! Ccc to the base of the next stage, of load. In cascaded impedance-coupled stages e. resistor and base-to-emitter interna the next stage transistor offer a sh between coupling capacitor Ccc and c fore, the reactance of Ccc and the

cause the quiescent value of  $I_C$  to though the collector is reverse-bias

the next stage transistor offer a shape tween coupling capacitor  $C_{\rm CC}$  and offere, the reactance of  $C_{\rm CC}$  and the resistance (or impedance) from resisting first stage. If the reactance of the capacitor is large, the output voltatenuated, and ony a small output stage.

base and ground of the second stage reactance of C<sub>CC</sub> varies inversely withe lower audio frequencies are attentian the higher frequencies. For go frequency response, the coupling cap sufficiently large in value that its very small as compared with the base

resistance or impedance. This is si

capacitor should always be less than one-tenth the effective base input impedance.

In those circuits where an impedance replaces R2.

response.

boost. At the higher audio frequencies (about 15,000 Hz), the collector-to-emitter shunting capacitance of the second stage, together with the large distributed capacitance from turn to turn of the collector-inductance, tend to bypass the high frequencies to ground, causing a drop in the

the coupling capacitor and inductor can be made to series-resonate at a low frequency to provide base

transistor PN junctions is voltage-sensitive. With higher voltage, the transition region is narrow, corresponding to the closely spaced plates of a capacitor with the associated high capacitance. The reverse bias on the collector also reduces the width of this transition region, so that transis-

tors are generally characterized by a high interelectrode capacitance. For example, an audio

transistor may have a collector-to-base capacitance

The frequency-attenuating action produced by the transistor occurs because the width of the interna-

on the order of 50pF, as compared with a vacuum-tube plate-to-grid capacitance of one or more pF. The collector-to-emitter capacitance is usually 5 to 10 times the value of the collector-to-base capacitance (in the common-emitter circuit), as compared with 8pF or less for vacuum-tube plate-to cathode capacitance. Thus, it can be seen how the high-frequency response is affected considerably by internal transistor parameters. Of course, any

shunt wiring capacitance and that of the collector inductance will also add to the shunting effects o the transistor. Both low-and high-frequency compensating circuits may be used to increase the frequency response of the circuit.

Over the region of 100 to 15,000 Hz, the impedance

coupled amplifier has a relatively flat response, and with proper matching will afford high power an voltage gains. Hence, this form of coupling is

of emitter current and low collector together with low values of input re to minimize the noise. By using an place of the base-to-ground resistor the schematic), a very low input res lower noise figure over that of the amplifier, is obtained. In the comm degenerative effects produced by an emitter resistor tend to increase th sistance. Thus, it is conventional large emitter bypass capacitors to a possibility of degeneration. As wit tubes, external feedback circuits pr response, although emitter degenerat times be used. Since fixed bias fro supply may be easily obtained by a s divider, it is used in both large-an applications. Self-bias is generall use to very small-signal amplifiers; distortion and improper operation wi in gain, or blocking, may occur on 1 The emitter resistor functions main! resistor for temperature stabilizati vents large changes in amplification temperature variations. i. In considering the operation of the impedance-coupled amplifier as compa electron-tube impedance-coupled ampl should be clear from the above discu circuit is an almost exact counterpa the other. The difference is that t stages operate with low input and ou ances, at low voltages, and at very amplification, whereas electron-tube with relatively high input and outpu at high voltages, and at high levels Thus, the transistor is basic amplifier, while the electron tube i amplifier. Consequently, the transi closer matching (rather than mismatch impedances to maximize performance

Transistor audio amplifiers are also by a high inherent noise which is gr lower audio frequencies. Operating

i.

## Operates class A for linear operation and minimized distortion. Usually amplifies small signals, but can be

haracteristics

stabilization.

INPUT

.

.

designed to handle large signals in cascaded stages.Is fixed-biased from the collector supply, but ma use self-bias in some applications.

Emitter swamping is normally used for thermal

Gain is fairly uniform over a range of approxi-

OUTPUT

Vcc

Uses common-emitter circuit for higher gain.

The transformer-coupled transistor amplifier is similar in general to the transformer-coupled electron-tube amplifier. See figure 5.

mately 100 to 10,000 Hz or more.

Both voltage and power gains are high.

The use of Tl to apply the input signal c. circuit provides an almost ideal temper sponse characteristic. The low transfe resistance produces a low base input re when used with emitter swamping resiste variation in gain with temperature is very small value over a large range of (greater than for any other type of co-Normally, transistor Q1 rests quiescent condition, with class A bias voltage divider R1, RR. The quiescent current, Ic, is steady, producing only constant voltage drop across the prima: of T2. Thus, practically the full val tor supply, VCC, is available. With a collector current, no voltage is induce secondary of T2, and there is no output input signal or noise). When a positive signal is introduced into the input ciflow through the primary of Tl induces the secondary, which is applied to the Assuming that the transformer secondar in-phase with the primary, a positive voltage appears at the base. This pos swing cancels the forward negative bia duced flow of collector current occurs instantaneous collector current decrea primary voltage drop also decreases, a collector voltage to rise toward the n voltage. Meanwhile, the reducing coll induces a voltage in the secondary winsecondary winding is connected in-phas reducing collector current produces a voltage swing in the secondary, and an current produces a positive swing. Th current flowing through RE is the stead value, and any change in base bias wit is bypassed around the emitter resisto capacitor CE. Although the capacitor the quiescent d-c current, it will pas nating audio voltage produced by the c signal. Thus, only d-c current change

TIZECTOR; KE IS DYPESSED BY CH. THE O

transformer-coupled through T2.

were not used, the input signal voltage would produce a degenerative effect, since all collector and emitter current would be forced to flow through the emitter resistor. Consider next the next negative swing of the input signal. In this instance, the forward bias on the base element is increased (the two negative voltage add), and a heavy collector current flow occurs. The increasing IC through the primary of T2 induces a voltage into the secondary. Assuming the same in phase connection of the primary and secondary, the output voltage is positive. By changing the connections of the secondary winding of either Tl or T2, the signal can be changed so that it is of the same phase at both the input and the output; this i an advantage of transformer coupling. Since the secondaries of Tl and T2 are not connecte to their primaries, the transformers offer a convenient method of separating input or output signal from bias or collector voltages. By using the proper turns ratio, the primary and secondary impedances may be matched. In the base circuit, th input resistance is matched, giving maximum gain; likewise, in the output circuit, the proper turns ratio reflects the secondary load impedance into th primary, which, when added to that of the transformer primary itself, provides a matched load for maximum output. Normally, the transformer-coupled stage is operated in the middle of its transfer characteristic to produce linear amplification. It is also a smallsignal amplifier when used in preamplifier stages. In following cascaded stages, it becomes a largesignal amplifier, operating with a larger bias over

the linear range of its transfer characteristic. When necessary, bias resistor R<sub>B</sub> is bypassed to ground with a large capacitor to prevent audio signal voltages from causing the bias to change with the signal, particularly in high-gain and large-

current back to the original value so that it

appears unchanged. If the emitter bypass capacitor

important when it is a large percentage operating collector current. Thus, the chooses a transistor with as large a be possible, and as small a leakage curren obtained, in order to get the most gain least leakage current. (The flow of re does not occur in electron tubes.) The frequency response of the transform h. amplifier is lower than that of the res or impedance-coupled transistor audio a There is more shunting capacitance than tance coupling because of the transform tributed turn capacitance, and there is inductance between the primary and seco does not exist in the impedance-coupled primary inductance is usually made from load resistance, RI, for good low-freque ponse. However, the lower the frequency the inductive reactance, so that the re to drop at low frequencies. The high-f response is primarily determined by the of shunting capacitance with load resis linkage inductance, while the low-frequ is detrmined by the combination of load and magnetizing inductance. In addition shunting capacitance and inductance for circuits which produce humps in the res Practically speaking, the response is v to that of the electron-tube transforme audio stage, with somewhat less high-fr response. Loss of low-frequency respon pared with the electron-tube circuit be apparent when miniaturized transformers because of the difficulty of building t with a sufficiently large iron core to high inductance with the limited number

available in the space allocated.

stages, the flow of reverse (leakage) of through the collector-to-base junction

iver, Transistor and Integrated Electronics.
Book Company, Fourth Edition, 1972.

hrader, Electronic Communication, McGraw Hill y, Fourth Edition, 1980.

Instruction, Transformers, M135.

INE

ges/Disadvantages

rmer Theory

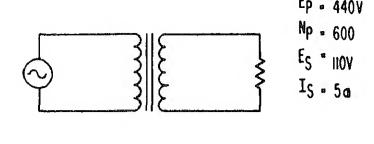
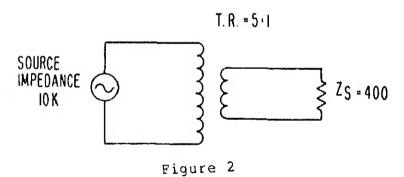
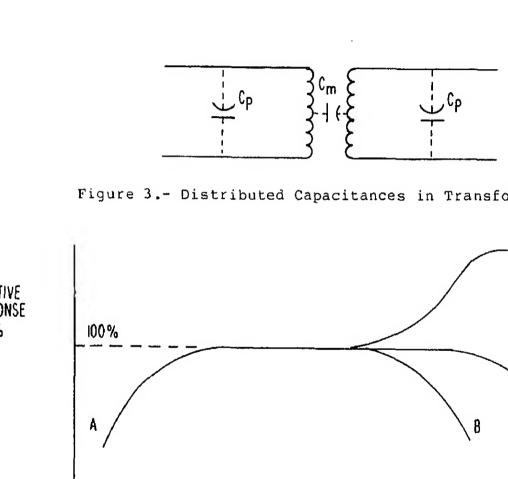


Figure 1





100

10

1,000 FREQUENCY IN HERTZ

10,000

e the development of solid state devices, the ability to amplify or control has been under constant invest Manufacturers have been forming layers of semiconduct, inserting PN junctions, shaping new geometries, and oping levels in the search for new control or amplify Some of the newly made special devices parallel tranaracteristics; while other devices completely take or

that a transistor cannot perform. At the present -the-art", several devices will be explained in this on.

ronic Circuits, NAVSHIPS 0967-000-0120.

n S. Kiver, Transistor and Integrated Electronics.
w-Hill Book Company, 1972, Fourth Edition.

ny S. Manera, Solid State Electronic Circuits: for eering Technology, McGraw-Hill Book Company, Inc., 19

t P. Malvino, Ph.D., <u>Electronic Principles</u>, McGraw-Hi Company, Inc., 1979, Second Edition. ON

ION

CONSTRUCTION AND OPERATION OF JEET
FET Construction

The Junction Field-Effect Transistor (JFET) is a state device with a very high input impedance and high output impedance—two favorable attributes alfound in vacuum tubes. Like a vacuum tube, the JF a voltage-controlled device. (The conventional transistory of the conventional transistor (JFET) is a state device with a very high input impedance and high output impedance and high output impedance.

sistor is a current-controlled device.) In its option and construction, the JFET is completely difffrom a vacuum tube, yet many circuits of both are similar. The JFET is a semiconductor device with filament, so no excess heat must be dissipated.

be operated at high voltages comparable to those of small vacuum tubes, or with the low voltages normal

capacitance problems are reduced when app external circuit designs are used. JFETs destroyed quickly if maximum ratings are in the production of many solid-state dev are wide variations in units of the same formance specifications are not too stric limitation also can be compensated for by ternal circuit design.

5. The simplified JFET structure shown in fi helpful in obtaining a fundamental unders JFET operation. First imagine simple ba material with direct (ohmic) contacts at

marketed.

lators. They also are used in small-sign video amplifiers. A few high-power junct effect transistors are available with hig capabilities. As the demand rises and pr techniques improve, higher power JFETs wi

Like most solid-state devices, field effe are temperature sensitive, but not as muc tional (bipolar) transistors. Input and tances of the FET are moderate. Both tem

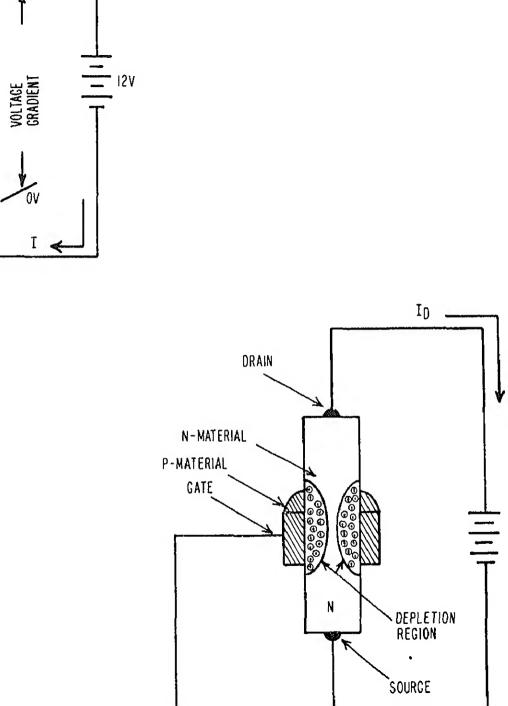
excess electrons are available in the mat voltage source connected across the leads movement of electrons. The magnitude of flow depends on the applied voltage, the doping, and the dimensions of the semicon Of course, the larger the cross-sectional bar, the lower the resistivity. Likewise the doping of the N-type material, the lo

6. It is not feasible to vary the physical of the bar or its doping level; however, it influence the movement of charges by chan resistivity of the bar. This can be done by varying the depletion region.

resistivity.

7. The connection of a voltage source betwee (figure 1A) sets up a voltage gradient al semiconductor material. The voltage at a becomes more positive as one proceeds alo

Small the model to the



reverse bias on the junction is obtained positive gradient that extends from the the bar to the positive end. In previous lessons, the influences of a 9. on the depletion regions associated with were detailed. It is this activity that

control the movement of charges through JFET terminology the bar is called a cha fore, figure 1(B) is an N-channel JFET).

that controls the motion of charges along is called the gate. The common end of t its associated lead is known as the sour opposite end of the channel and its asso called the drain. The gate can be compa control grid of a vacuum-tube--the sourc be compared to the cathode and plate res A reverse-biased junction causes the dev 1. depletion region in the channel, as show Adequate doping keeps the resistivity of material lower than that of the channel DEPLETION REGION

Influence of the Reverse-Biased Junction В.

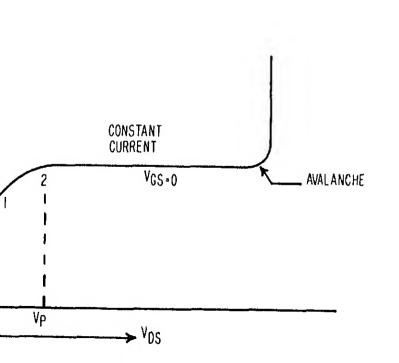
> DEPLETION REGION

increase in the resistivity of the bar. If source voltage (VDS) is increased, the region extends farther into the channel, its resistance. In figure 2(B) the region would seem to extend through the such a manner that channel current would be "pinched off."

however, counteracting influences that pre-

ce of the depletion region in the channel

omplete pinch-off of the current. Increasing to increase the current, while a larger degion tends to reduce it; thus, current is not The combined influence of the depletion the voltage drop establishes a condition in current rises to a maximum and then holds further increase in channel current with an n VDS). This is indicated by the curve in



current region where the drain current re same level despite the increase in Vps. 5. If the drain-source voltage is made too ! channel junction will undergo avalanche causing the current to rise sharply. It that the device will be damaged if power is not held to a safe level. c. Influence of the Gate Potential 1. The resistivity of the channel depends or drain voltage and gate voltage. The infi gate on the channel current can be enhance necting a negative voltage between the ga source (common), as shown in figure 4. establishes a larger depletion region and

channel resistivity for a given VDG.

will cause pinch-off at a lower VDS.

the limiting drain current will also be

Point 2 corresponds to full penetration (where the two depletion regions meet). pinch-off condition. Operation now is in

gate bias voltage is made high enough, to current can be reduced practically to zero activity can be compared with the cut-of tube's plate current when a high control applied.

In

Th.

current characteristic means that the output resistar is high, providing favorable operating conditions whe nigh voltage and/or power gain are desired. The thir region is the breakdown (avalanche) region. OHMIC PINCH-OFF **AVALANCHE** REGION REGION REGION ĺρ VGS-OV VGS - IV VGS -- 2V VGS=3V 0 Vos

Family of Curves for a Typical

As long as the gate-channel junction is reverse biase

N-Channel JFET

Figure 5

There are three main regions. In the ohmic region the drain current rises significantly with the increase is the drain-source voltage because neither gate potention the channel IR drop have enough influence to cause inch-off. The drain-source voltage has a significant influence on the drain current, and the output resistence is relatively low. The second region (pinch-off is one of saturation. The current remains essentially constant for a large change in VDS. This constant

the electrons (plate current) between the the plate of a vacuum tube. To the extent signal voltage across a high impedance con output current, a field-effect transistor a vacuum tube than a bipolar transistor. RL

There will be corresponding changes in the of the channel and the movement of charges channel. Consequently, the drain current the changes in the gate-source voltage (VG control of the channel current (ID) by VGS the influence that a grid voltage has on t

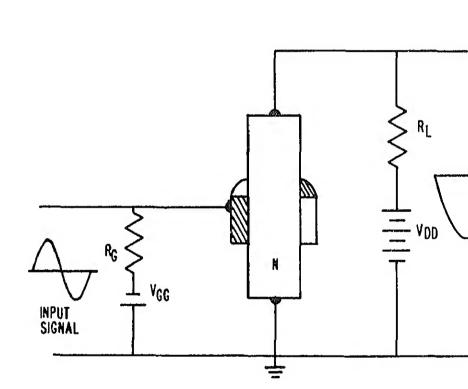


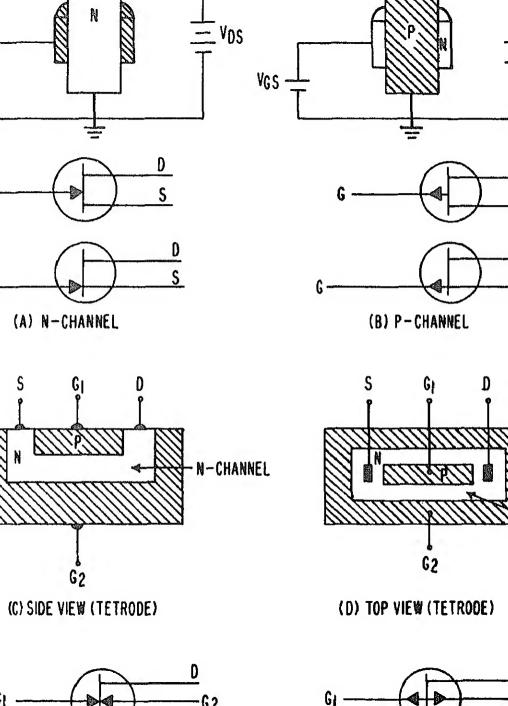
Figure 6 Signal Input to and Output from a

TERMIC as soon in figure 7 To a D about

## JFET Types

D.

Field-effect transistors come in various t l. structures. Just as there are PNP and NPM transistors, there are both N-channel and



holes at the emitter junction which result fusion current in the base that propels ch high electric field across the reverse-bia base junction. 2. It is possible to include two gate element from each other as shown in figures 7(c) a their symbols in figures 7(e) and (f). The are available for mixing and other circuit such as AGC and d-c feedback, in which a d a-c amplification is to be established. called dual-gate field-effect transistors. second input is not used, it is normally of the circuit so that its gate-channel junct reverse-biased. E. Basic Circuit Configurations

carriers. For this reason the conventions is called a bipolar type. The bipolar tratwo junctions, one forward-biased and the biased. It is the interaction between electric carriers.

field-effect transistor can be connected in arrangements (figure 8). Each has its indicharacteristics. The common-source connect most widely used. It has a good voltage of input impedance, and a medium-to-high output signal is applied between the gate and the output signal is developed between the source.

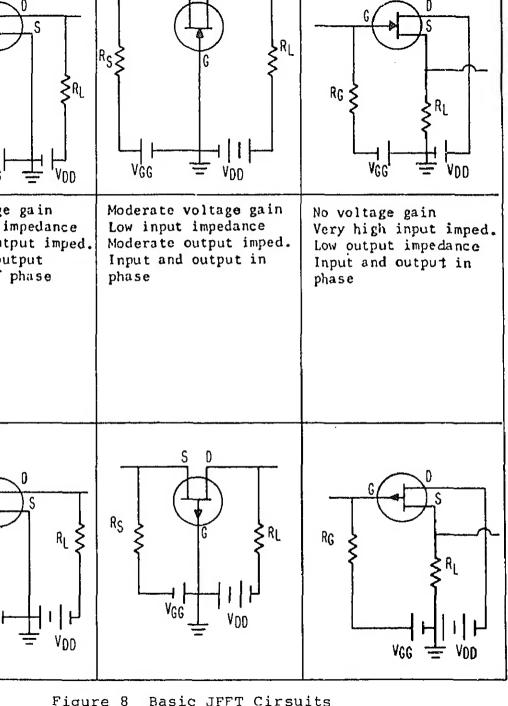
l.

Like the vacuum tube and the bipolar trans

- and the output signal is developed between the source.

  2. Input and output voltages are out-of-phase example, a positive swing of the input to junction FET increases the drain current to
  - channel. The resulting increase of drain through the load resistance causes a decre positive drain voltage. Conversely, a neg the gate voltage decreases the drain currected creases the drain voltage.
  - creases the drain voltage.

    3. The common-gate configuration's voltage gathan that of a common-source. Input impedance is high: therefore.



in the positive direction (same as a negat the gate voltage) decreases the drain curr creases the drain voltage. Conversely, a of the source voltage increases the drain decreases the drain voltage.

Input and output voltages are in phase. U

channel FET as an example, a swing of the

The common-drain's (source follower) input very high, and the output impedance is low impedance of the common drain can be compainput impedance of the common-gate. A cur possible but there is no voltage gain.

nput and output voltages are in-phase. F

using the N-channel JFET, a positive swing age increases the source-to-drain current.

electronics continues to be a problem for industries, and engineering societies. The

ment uses the common (ground) as a reference conventions of figure 9 are widely observed

- crease causes the source (output) voltage the positive direction. Conversely, a neg the gate voltage decreases the drain curre source voltage.
- F. Symbols1. Standardization of alphabetical and graphi

4.

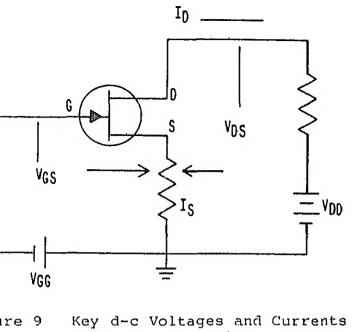
5.

6.

- solid-state devices has resulted in some sization, and certain procedures have become accepted. It should be stressed that, alt now common to use the letter V for voltage state symbology, the letter E continues to
  - relation to vacuum tubes.

    2. When a current is specified, the first subcates the element at which the current is when a voltage is specified the first subcates.
    - cates the element at which the current is When a voltage is specified, the first subto the element at which the voltage is meathe second subscript indicates the reference when no second subscript is used, the voltage is used.

present time.



of a JFET Circuit
and Specifications

el FET (2N2608) is given in figure 10. Note that rain voltage used is negative. The less positive the greater the magnitude of drain current ( $I_D$ ). Tample, a drain voltage of -10 volts and  $V_{GS}$  of volts,  $I_D$  is 0.6 milliamperes. If the gate bias suced to +0.2 volts,  $I_D$  rises to about 1.4 millies. The breakdown voltage is also indicated on the characteristic curves. This is the point at avalanche occurs on the  $V_{GS}=0$  curve.

mily of drain characteristics for a typical P-

on FET specifications compare the drain current ( $\Delta I_D$ ), to the gate voltage signal ( $\Delta_{GS}$ ) at a int VDS. This ratio,  $\frac{g}{\Delta I_D} = \frac{\Delta I_D}{\Delta V_{GS}} = 0$  is

I the small signal common-source forward transtance. This is similar to gm in vacuum tubes. ates the control that gate-source voltage has on current and has a value that ranges from 35 to

lumbos. If the dynin-to-course vesistance (r. )

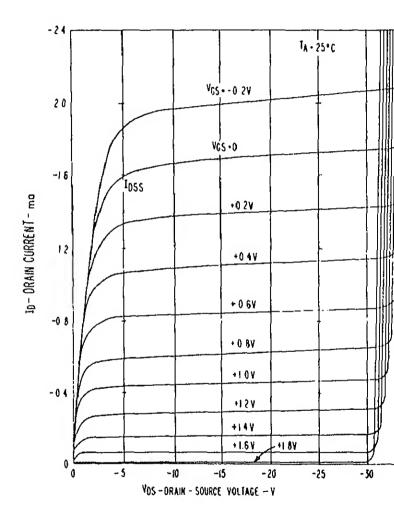
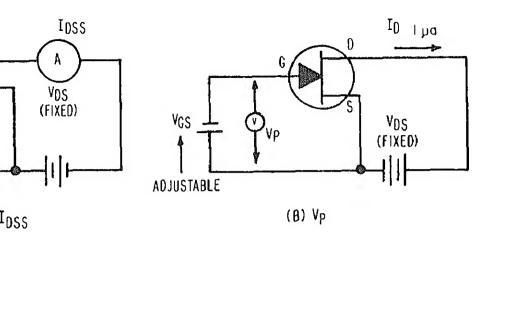
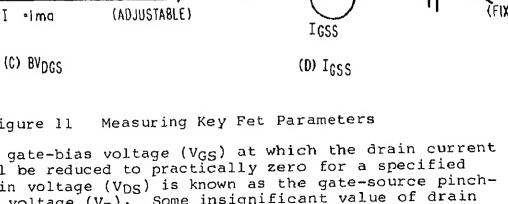


Figure 10 Typical JFET Output Characterist for the 2N2608

2 An important parameter of a PPM is the gove





VGS

 $\mathsf{BVDGS}$ 

VGD

	Parameter	Units	Min
SS	Gate-Source Cutoff Current at: V <sub>GS</sub> = 30V V <sub>DS</sub> = 0	mA	
SS	Gate-Source Cutoff Current at:  V <sub>GS</sub> = 5V  V <sub>DS</sub> = 0  T <sub>A</sub> = 150°C	μA	
GDS	Gate-Drain Breakdown Voltage at: $I_G = 1 \mu A$ $V_{DS} = 0$	Volts	30
ss	Drain Current at Zero Gate Voltage: $V_{\rm DS} = -5V$ $V_{\rm GS} = 0$	mA	0.90
	Gate-Source Pinch-off Voltage at: $V_{DS} = -5V$ $I_{D} = 1 \mu A$	volts	1
9	Small-Signal Common Source Forward Transconductance at:  VDS = -5V  VGS = 0  f = 1kHz	μπho	1000
SS	Gate-Source Capacitance at:  VDS = -5V  VGS = 1V  f = 140 kHz	pF	12
	Noise Figure at $V_{DS} = -5V$ $V_{GS} = 0$ $f_O = 1M$		- LUCATION CONTRACTOR

result in the destruction of the transistor. y of the key parameters and specifications for as furnished by the manufacturer are shown in 1. q a Load Line line can be drawn (figure 12) on the FET's teristic curves. TA - 25 ° C VCS - - 0 2V Vcs • 0 IQSS +0 2V +0 4V ( 0.P + 0.69 VB D4 +1.07 +127 +1.44 +1.6V +1.64 - 5 -30 -20 -25 -10 -15

are certain maximum ratings which, if exceeded,

error in reading the curves; however, the mation is as accurate as most electronic of a Noise Considerations

The noise content of a FET is low in comparison tube or a bipolar transistor. The three source in a field-effect transistor are: The gate-less that noise, thermal or resistance noise that it

At the operating point, the transconductar

 $A_v \approx g_{fg} R_{L}$ :  $A_v \approx (1375 \times 10^{-6})(12.5 \times 10^{-6})$ 

The slight discrepancy in this case is bed

about 1375 µmhos. Using the formula

- the agitation of the charge carriers in the charge frequency noise (1/f noise).
  J. Frequency Response
  1. Low power junction FETs have a gate-to-dratance (Cgd) ranging from 1 to 100 pF. The
- increases as the drain-to-source voltage approaches the pinch-off voltage. As a recapacitance (Cgd) the "Miller effect" occution FET's.

  2. A regular (bipolar) transistor's low impedingut tends to shunt a large portion of the sistor's high impedance internal feedback
  - emitter. The Miller effect in regular tratherefore, not as great as in FETs where signal at the gate, like the internal feet is usually also of high impedance.

    The Miller of Foot in FETTs can be reduced by
  - 3. The Miller effect in FETs can be reduced the drain to source voltage, reducing the input impedance or with a feedback circuit semiconductor's internal feedback.
- 4. Theoretically, junction FETs should be abs

iers at frequencies of several hundred megahertz. e Effects on FETs, like regular transistors, are normally ed by changes in temperature (TA). Measurements te that their pinch-off voltage (Vp) usually inat about 0.2% per 8°C. gh FET PN junctons are affected by temperatures, te current stability of silicon FETs approaches se current stability of bipolar silicon trans. Provided the circuit's gate-to-source rece (Rg) lies between 1 and 10 megohms. posing effects of temperature change in JFETs in a linear decrease in IDSS with increasing ature, causing the current to decrease about 0.6% . This drift can be reduced by operating the FET level of In. e of JFETs with lower pinch-off voltages also s I<sub>D</sub> drift. Measurements show that FET's having V pinch-off experience no temperature drift when ing at their normal IDSS and gfs. ardization--In a previous lesson, it was shown ransistors of the same type have exactly the same stics. The same problem exists with JFETs. of the same type have IDSS and gfs ratings that much as 2 to 1. and Disadvantages: uld be apparent that the primary advantages of are: ry high input impedance. w noise characteristics. gh their voltage gains are relatively low, once a pedance point occurs in a circuit, the bipolar

an be made to operate well as common-source

A. Avalanche is defined as a cumulative process a charged particles collide with and ionize the through which they are traveling.
B. As long as the current-handling capacity of the not exceeded during the avalanche process, some characteristics can be utilized.
1. Zener Diode
A zener diode is a PN-junction diode that

heavily doped than the average diode.

to operate in the reverse bias breakdown,

Ιt

transistor.

The reader must be aware that, although the characteristics are temperature sensitive near as sensitive to  $T_A$  variations as the

region without damaging the junction. Sir diode operates in the reverse-bias directi it operates on minority carriers. AVALANCHE (4) VR **AVALANCHE** CURRENT 12

semiconductor material used, the type of doping material used, and the actual doping level of the zener diode. Once the diode goes into the avalanche region, the voltage across the diode will remain almost constant The reverse-bias potential accelerates the minority

breakdown (VZ) occurs is determined by the type of

carriers to such a velocity that they physically dis lodge other carriers from the crystal lattice. result is a very large current flowing in the zener diode. If the voltage applied to the junction decreases, the acceleration of the carriers will decrease, which results in less current through the

diode. With less current flow, the zener impedance increases and the voltage across the diode remains constant. The constant voltage characteristics of the zener di

(in the avalanche region) are particularly useful in voltage regulator circuits. Figure 14 is a basic voltage regulator circuit emplo ing a zener diode as the regulating component.

R I IMITING  $100\Omega$ Dı EOUT REGULA INREGULATED +12 V **I** 1 TLOAD

Figure 14

b. If the unregulated voltage increases, suppied to the zener diode will increased voltage (VZ) will cause an IZ. When IZ increases, the voltage of Rlimiting will increase, thus returning regulated output to +12 volts.
2. Four-layer didoes (PNPN)
a. A PNPN diode is a 4-layer, 3-junction operates in the avalanche mode.
b. As shown in figure 15, the layers are doped P- and N-type semiconductor mat

output returns to +12 volts.

rent flow through R<sub>limiting</sub> decreases

Ohmic contacts to the P-type and N-ty The Ohmic contact to the P-type regio

12

13

the anode, and the contact to the N-t called the cathode. Notice that the and N-regions are floating.

+ - + - + - + - ANODE

P

N

P

N

J

LOAD

With J2 reverse-biased, only minority carriers flow through the internal P- and N-areas. The negative voltage on the N-type cathode injects electrons into the internal P-type area where they flow as minority carriers, and the positive voltage on the P-type anode injects carriers into the internal N- type area where they also flow as minority carriers. As can be seen in figure 15, as the applied voltage (VF) is increased, more injected holes from the P-type anode will diffuse through the internal Ntype material and be controlled by the internal P-type material. The internal P-type material becomes more positively charged (contains more holes), thus increasing the forward-bias on J3. At the same time J3 is increasing its forward-bias,

said to be "OFF" or blocking, which represents a

high resistance between anode and cathode.

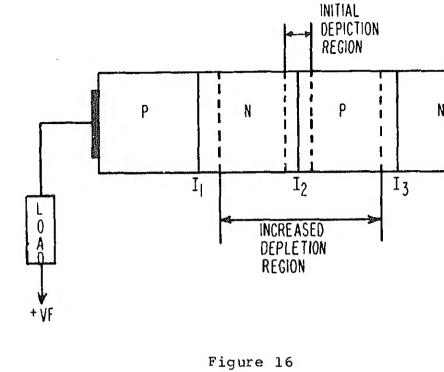
At the same time J3 is increasing its forward-bias, the N-type cathode is injecting more carriers into the internal P-type material which diffuse into the internal N-type region which becomes more negatively charged (more electrons) increasing forward-bias at J1.

As Jl and J3 increases their forward bias, their junction resistance decreases and more of the applied voltage (Vr) is felt at the reverse-bias junction J2, increasing the depletion region at J2

As the depletion region at J2 increases, the effective N and P areas are reduced.

Figure 16 depicts the condition now existing; i.e. the increased depletion region at J2 and the reduced efective areas of the internal N and P-type materials. As the external voltage  $(V_F)$  continues to increase, the carriers crossing the depletion region gain velocity as they are swept across the

region gain velocity as they are swept across the junction. When the velocity the carriers gain while crossing the junction is great enough, free carriers are produced in the internal N- and P-type



This process is accumulative and anode

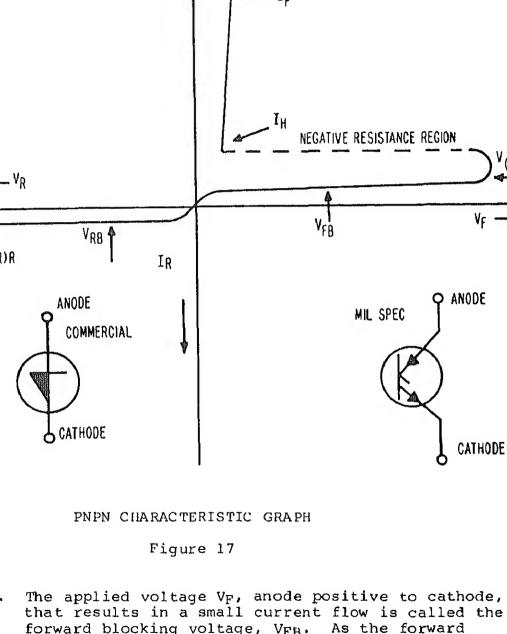
j.

carriers generated. Avalanche soon of current must be limited by external se ance or else the device will destroy i device is said to be switched "ON" and low resistance between anode and catho k. The PNPN device thus acts as a switch. high resistance, very low current flow low resistance, heavy current flow.

starts increasing rapidly because of t

device is turned on, a specific amount (I<sub>F</sub>) must be maintained to keep it on. rent is specified as holding current, current rating that must be considered current I<sub>L</sub>. The latching current ratia value of anode current, slightly high

holding current, which is the minimum quired to sustain conduction immediate device is switched ON. In other words



forward blocking voltage, VFB. As the forward voltage is increased, a sudden increase in current is apparent as the device switches "ON."

minimum voltage necessary to turn the device on is

o. PNPN switches are used for trigger device low-cost sweep generators and timers.

will occur at the reverse breakdown point

reverse-bias avalanche region and should operated with reverse-bias between anode

The PNPN switch can be destroyed

p. Figure 18 is another sweep-generator circ a PNPN switch.

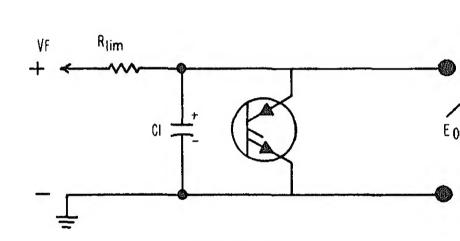


Figure 18

When Vp is applied to the anode of the PN the capacitor starts charging toward Vp. voltage across the capacitor reaches V(BP diode turns ON and discharges the capacit sawtooth waveform is thus produced across diode. Rlim limits the current to a safe with Cl determines the rate of firing.

## 3. Silicon Controlled Rectifiers (SCR)

a. Basically, the SCR is a PNPN structure wi ohmic contact made to the internal P-type

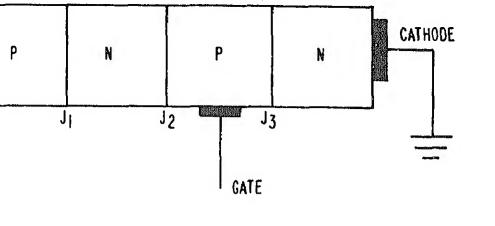


Figure 19

e "turn-on process."

ne SCR is normally operated with  $V_F << V_{(BR)F}$ , here  $V_{(BR)F}$  represents the forward breakover oltage, as was the case with the basic PNPN evice. With the gate open, the SCR will be "OFF" in the blocked condition. When a positive oltage is applied to the gate, current will flow ato the gate (IGT).

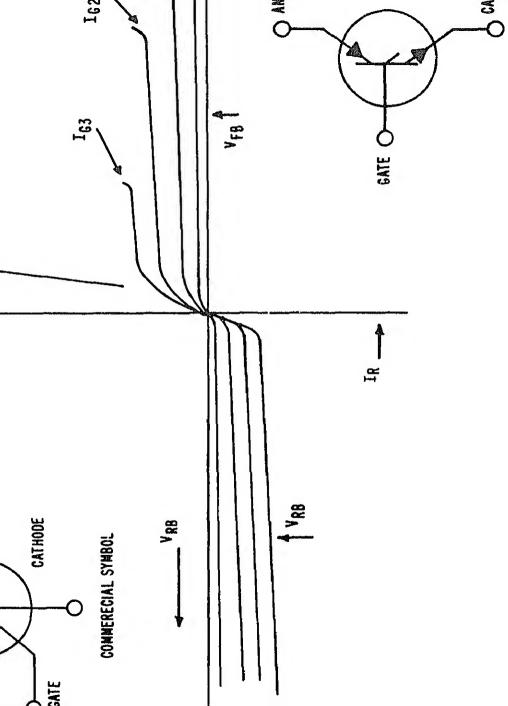
ne current flow (electrons) in the gate is inected from the N-type cathode; however, many

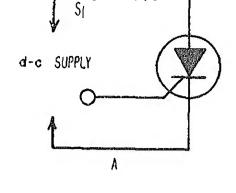
e additional lead is called the gate and aids in

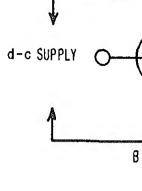
rijected carriers will diffuse through the inernal P-type material to the internal N-type aterial. The internal N-type material now takes a a negative charge (excess electrons) increasing he forward bias on Jl. The increased forward-bias a Jl increases injected holes through J2 from the mode.

commercial and Mil-Spec symbols for th Notice that as Igate is increased, tur g. (breakover) occurs at lower values of quite an advantage over the basic PNPN there was no control over the breakove Also apparent in figure 20 is the fact h. acts as a bistable switch; i.e., "ON" V<sub>F</sub> is a positive voltage and V<sub>gate</sub> is positive. The SCR is the solid state equivalent i. eous thyratron tube which is switched voltage pulse on its control grid which tube. The SCR on the other hand recei pulse on its gate which aids in the "a process in much the same manner as a t Like the thyratron's grid, the SCR's of control once the device turns on. The turned off in the same manner that the was. (1) Reducing the anode-cathode to zero (2) Driving IF < IH. (3) Forcing commutation. j. The main advantage of the SCR is its a control heavy load currents with light (gate) currents. Currently SCR's have cations among them, being; motor speed heating controls, and ignition systems As stated earlier, the SCR may be turn k. several methods: (1) Reducing anode current to zero. (2) Driving IF to < IH. (3) Commutation

process just described and also include





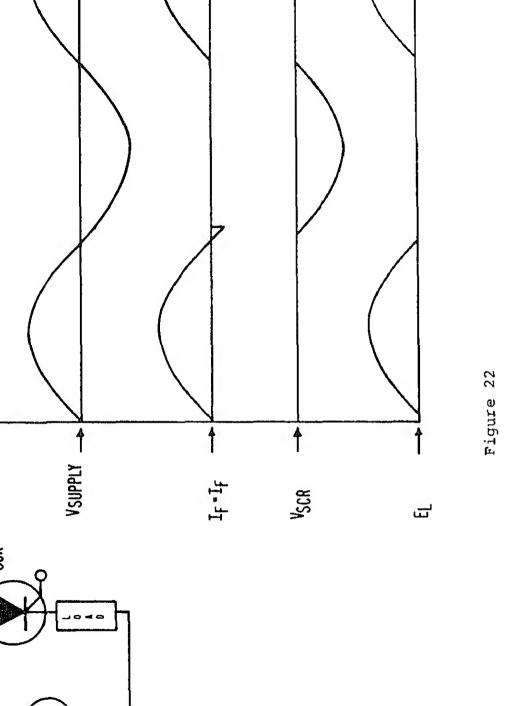


Figures 21a and 21b will definitely "fit for conditions (1) and (2) above; however be difficult to operate the switch at a v frequency or with any appreciable current tation is the most often used "turn off" employed. This method switches current fenergy source to force current through the reverse direction. There are six disclasses of commutation.

(1) Class A - Self-commutated by resonati

(2) Class B - Self-commutated by an LC ci

- (3) Class C C or LC switched by another carrying SCR.
- (4) Class D C or LC switched by an auxi
- (5) Class E An external pulse sound for commutation.
- (6) Class F A-c line commutation.
- As class F, a-c line commutation is the m turn-off technique used; it will be the m analyzed. Figure 22 will be used in the



- A. The unijunction transistor (UJT) is basically with two contacts and a PN junction.B. Figure 23 shows the construction of an UJT and symbol.
- 1. The two ohmic contacts made to the base (s are called  $B_1$  and  $B_2$  (N-type material). Be potential or common side and  $B_2$  is the high
  - or voltage supply side. B<sub>2</sub> will be biased respect to B<sub>1</sub> (V<sub>B2B1</sub>).

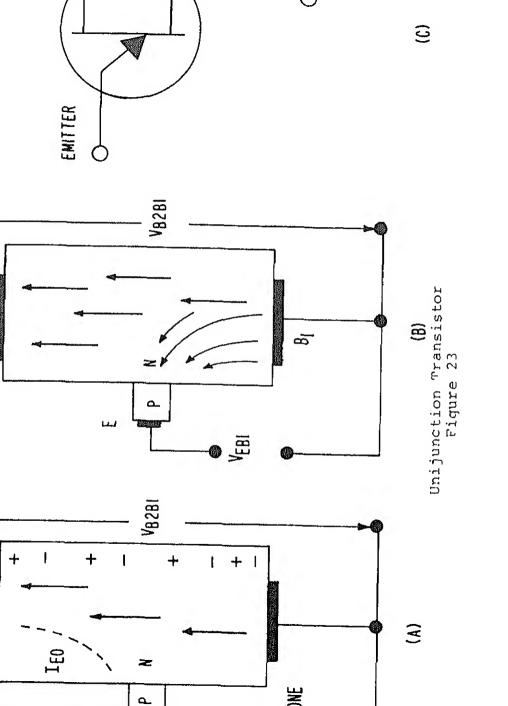
    2. The PN junction formed is the emitter which positive in respect to B<sub>1</sub>.
    - a. R<sub>BB</sub> is the interbase resistance between with typical values ranging from 4 kΩ
       b. Figure 23A depicts the condition exist emitter base junction with a voltage and the condition of the condition of
    - emitter base junction with a voltage a B<sub>2</sub>B<sub>1</sub> leads (V<sub>B</sub>2B<sub>1</sub>) and the emitter vol equal to zero.

      c. With V<sub>B</sub>2B<sub>1</sub> applied, R<sub>BB</sub> develops volta

throughout the N-type silicon bar. Th

- opposite the PN junction, between B<sub>2</sub> a some positive value.

  d. Under these conditions, the PN junction biased and only a small amount of leak
- flased and only a small amount of leak (I<sub>EO</sub>) will flow in the emitter lead. flow in the device will be essentially and B<sub>1</sub>.
- e. As shown in figure 23B, as the emitter is increased, positive in respect to E V<sub>EB1</sub>, the PN junction will become forw
- (1) The emitter injects holes into the where they are swept toward B<sub>1</sub>.
   (2) Electrons from B<sub>1</sub> combine with the holes increasing I<sub>P</sub> (emitter curre



R<sub>B</sub>2

acteristics of a gas thyratron. Until the contage  $(V_{EB1})$  reaches a certain value  $(V_p)$ , is reverse-biased and essentially cut off. the critical value is exceeded, the emitter becomes forward-biased and emitter current in

A simplified equivalent circuit for the unij transistor may be developed as shown in figu

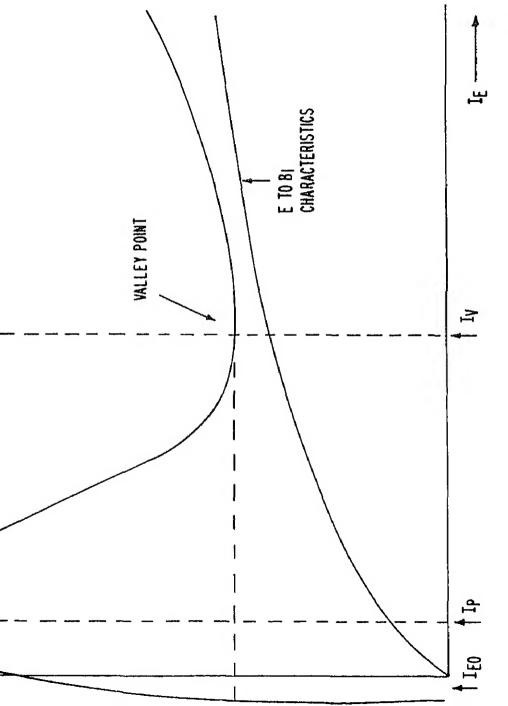
considerably.

5.

Figure 24

VB2BI

Diode CR1 represents the emitter-bar PN jun RB1 representing the resistance of base 1 a representing the resistance of base 2. RB1 as variable since it does vary as a function



eter in his specification sheet (typical v from 0.51 to 0.82).

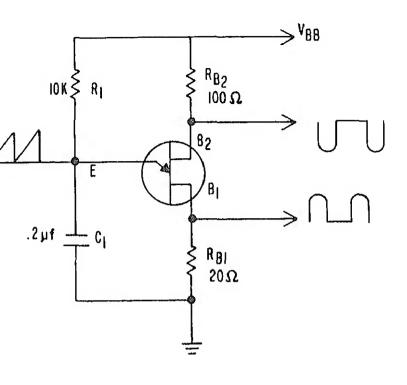
7. Also shown in figure 24 is a voltage drop diode CR<sub>1</sub> V<sub>D</sub>. This voltage will be present static condition because of I<sub>EO</sub>.

8. In order to turn the UJT on, the emitter v be positive with respect to nV<sub>B2B1</sub>. Thus, + V<sub>D</sub>. For example:

Given: V<sub>B2B1</sub> = 10 volts

is called the intrinsic standoff ratio and the percentage of the voltage  $V_{\rm B2B1}$  develoge. The manufacturer of the UJT supplies

- $2\tilde{N}\tilde{2}\tilde{6}\tilde{4}\tilde{6}$   $\eta$  = .51 Characteristics  $V_D$  = .5 volts Find: The minimum voltage required to tu UJT  $(V_p)$ . Solution:  $V_p$  =  $\eta V_{B2Bl}$  +  $V_D$
- Solution:  $V_p = nV_{B2B1} + V_D$   $V_p = (.51)(10V) + .5 V$   $V_p = 5.6 \text{ volts}$ C. A typical characteristic curve of a unijunction is shown in figure 25. This curve has three directions. Region 1 is the cutoff region, where
- is reverse-biased. As the voltage applied bet emitter and  $B_1$  rises, the current  $(I_E)$  rises the total current seldom exceeds 10  $\mu$ A  $(I_{EO})$  R when the applied voltage reaches the point marthis point, the UJT "fires" with a large increrent and a decrease in the voltage drop between  $B_1$ . This is the negative resistance region, a feature which gives the UJT its unique propert shall see presently. Eventually there is a possible of the minimum, or valley point, beyond where
- shall see presently. Eventually there is a pocalled the minimum, or valley point, beyond wh device behaves as a positive resistor. That i current increases slowly with voltage. This r called the saturation region. The UJT switche cutoff to the saturation region quite rapidly the highly unstable negative resistance region



he power supply ( $V_{\rm BB}$ ) through  $R_{1}$ , it will slowly be until enough voltage develops across  $C_{1}$  to

ard-bias the emitter junction  $(V_p)$ . At this point, unijunction transistor "fires."  $C_1$  now discharges ally through  $^{RB}_1$  and the low resistance of the zer -  $B_1$  junction. With  $C_1$  discharged, the transreturns to its nonconducting state, and the repeats itself.

vaveform developed in this circuit are also shown gure 26. The voltage across  $C_1$  is a sawtooth possessing a slow rise and a rapid descent. At time of firing, the current through the entire con bar rises developing a positive pulse at the of  $^{RB}_2$  and a negative pulse at the bottom of  $^{RB}_1$ . the extreme simplicity of this circuit, requiring

an SCR. RB1 develops the positive trigger pulses necessar

Figure 27 is another typical UJT trigger as used to o

l. the SCR.

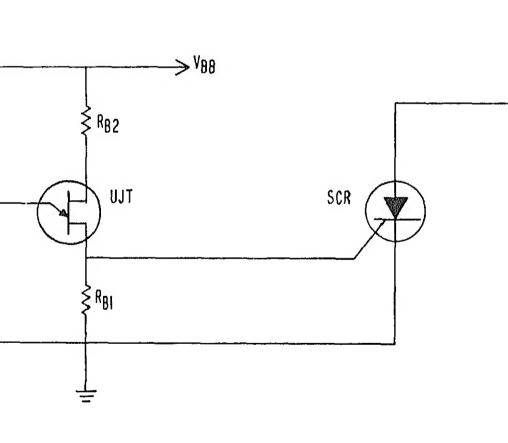


Figure 27

UJT CONTROL OF AN SCR

## Circuits, NAVSHIPS 0967-000-0120

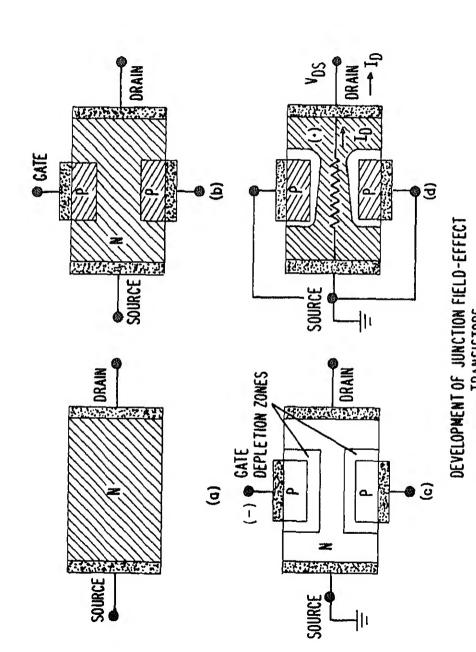
Kiver, Transistor and Integrated Electronics. Ll Book Company, Inc., 1972, Fourth Edition.

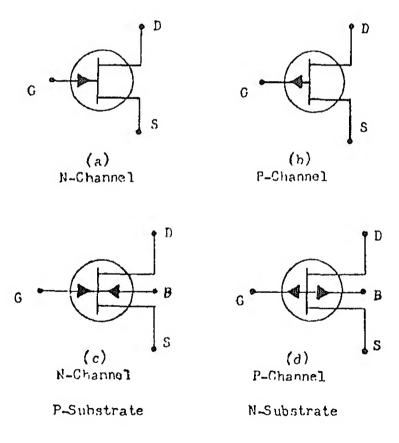
Manera, Solid State Electronic Circuits for ng Technology, McGraw-Hill Book Company, Inc., 1973.

Malvino, Ph.D., Electronic Principles, McGraw Hill any, Inc., 1979, Second Edition.

LINE

on Field-Effect Transistors

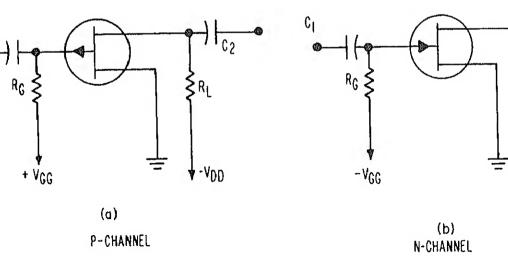




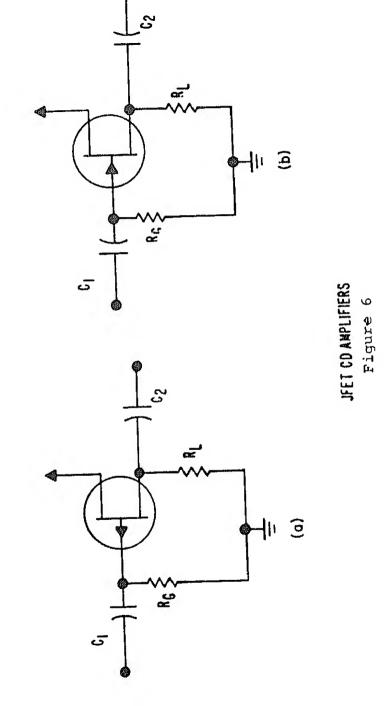
SYMBOLOGY

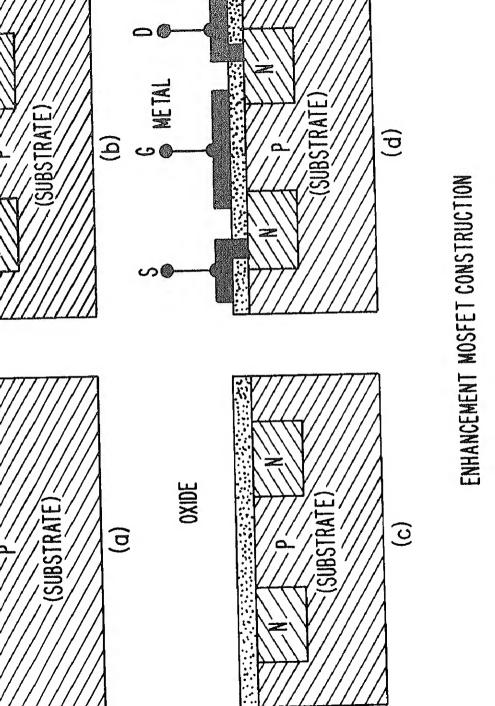
JFET

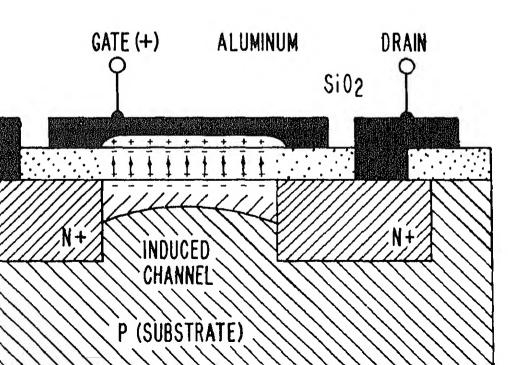


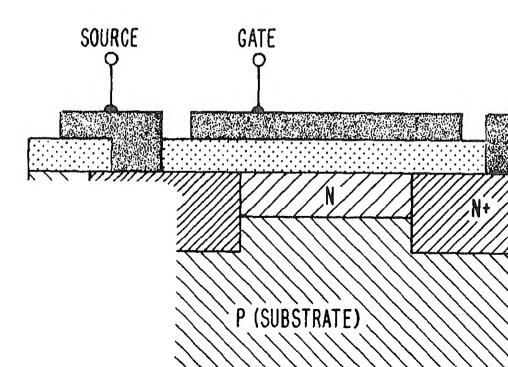


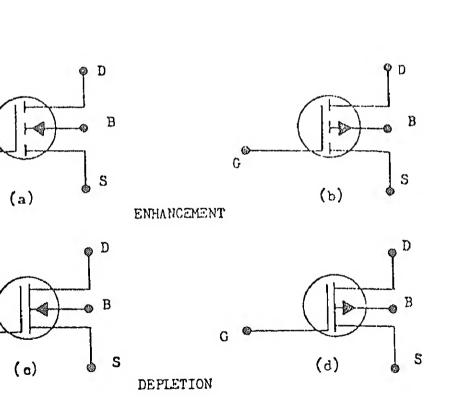
JFET COMMON SOURCE AMPLIFIER







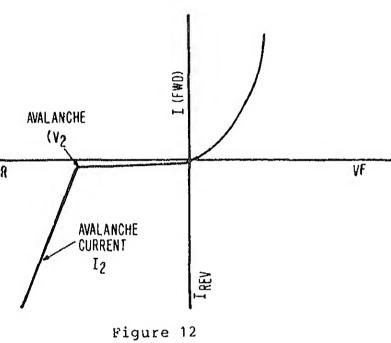




MOSFET Symbols

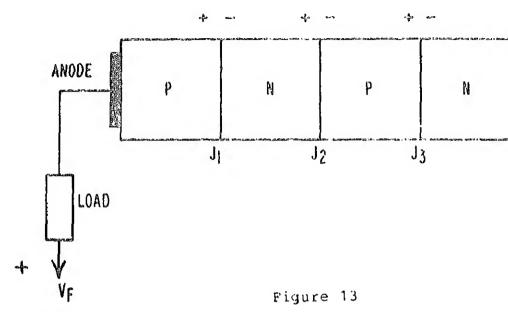
VI. Avalanche devices

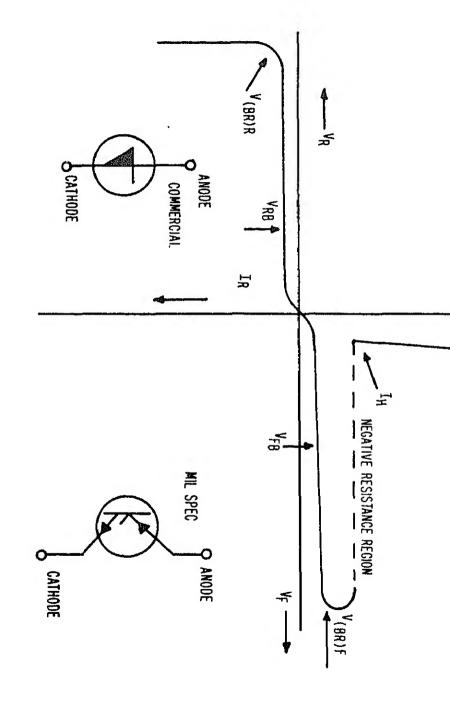
A. Zener Diodes



riguic 1.

Diodes





PNPN CHARACTERISTIC GRAPH

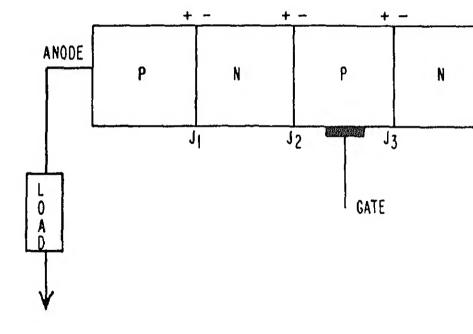
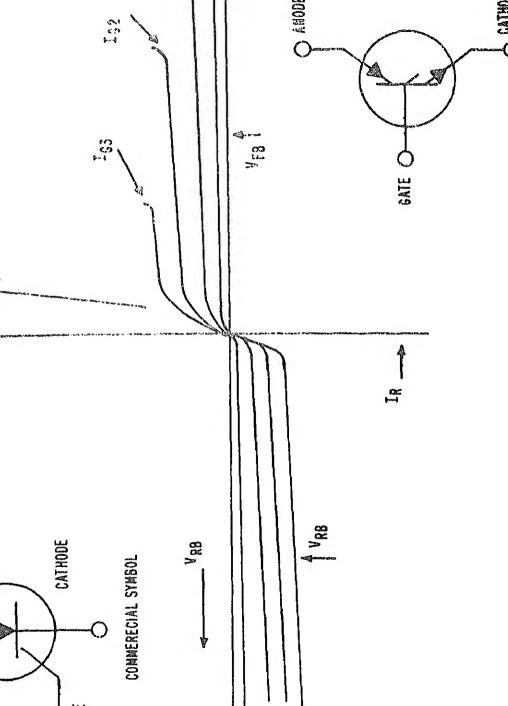
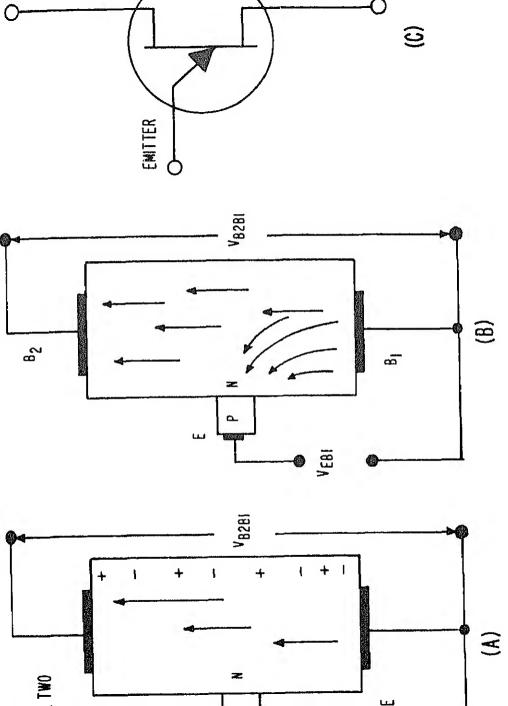
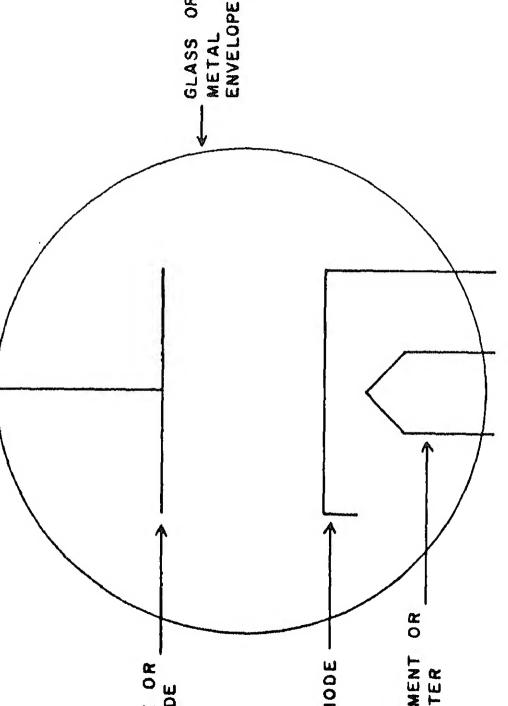


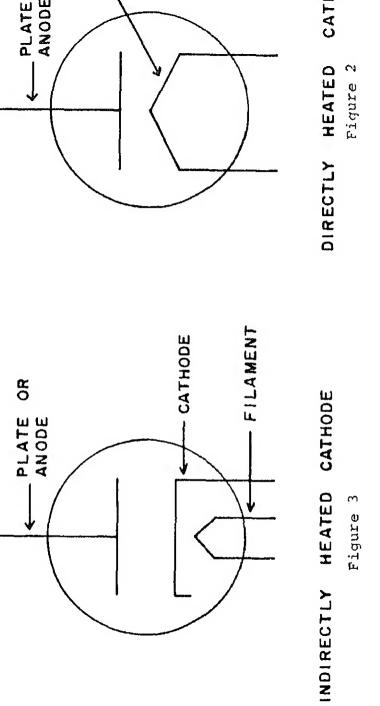
Figure 15--Silicon-Controlled Rectifier





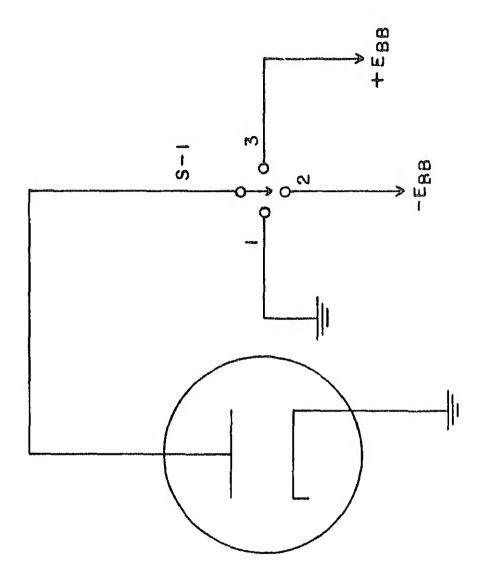
c Circuit Analysis, Vol. I, NA 00-80-T-79, Chapter 4, to 4-42. CLINE Construction of a Vacuum Tube.

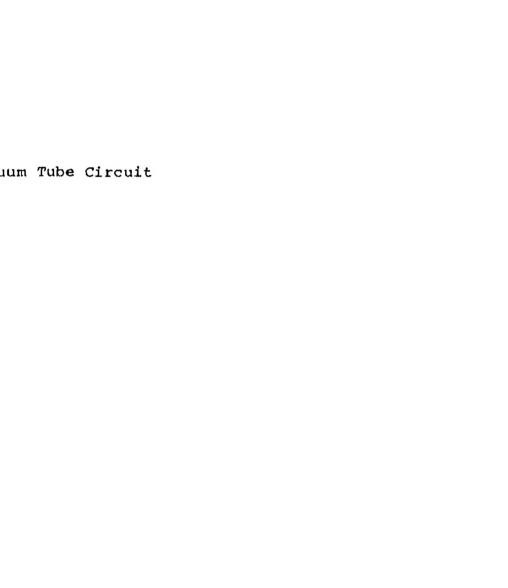




B. Photoelectric emission

C. Cold cathode emission

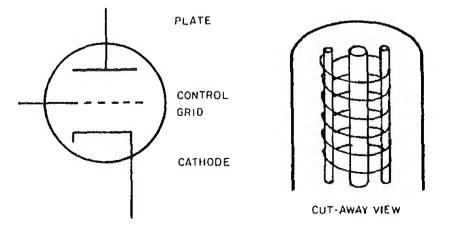




## ectronics, Vol. I, NAVPERS 10087-C, Chapter 7, pages Shrader, Electronic Communication, Chapter 9, Fourt 1980, McGraw-Hill Book Company Inc.

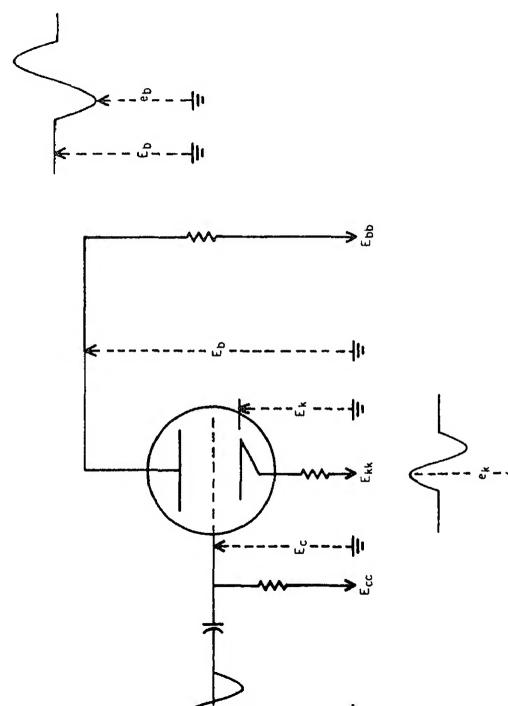
truction of a Triode Vacuum Tube

JTLINE



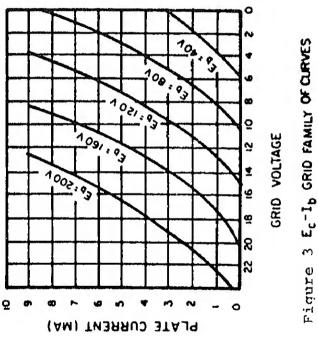
Piguro 1 - Mriodo Vacuum Tubo

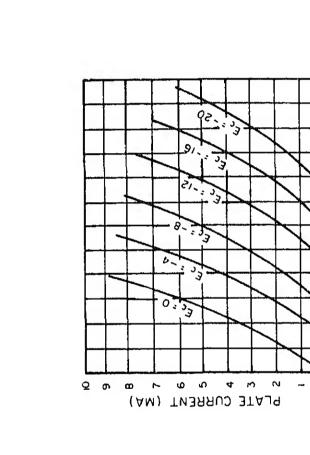
## II. Bias



## Tube Notations

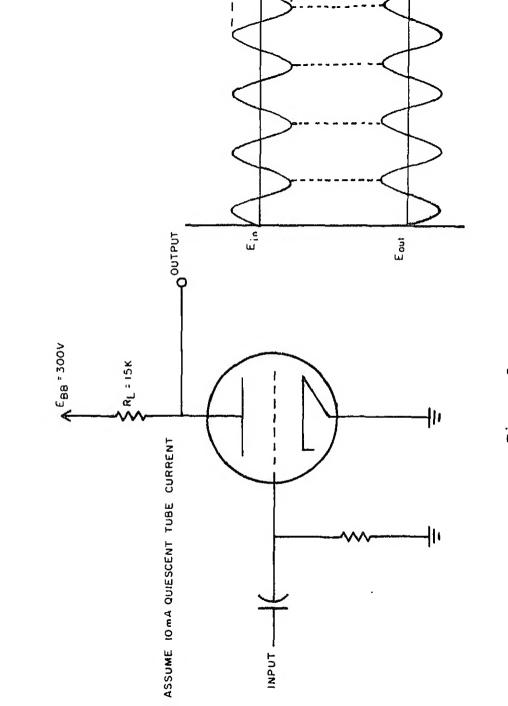
IV.	Vacuum	Tube	Static	Characteristic	Curves

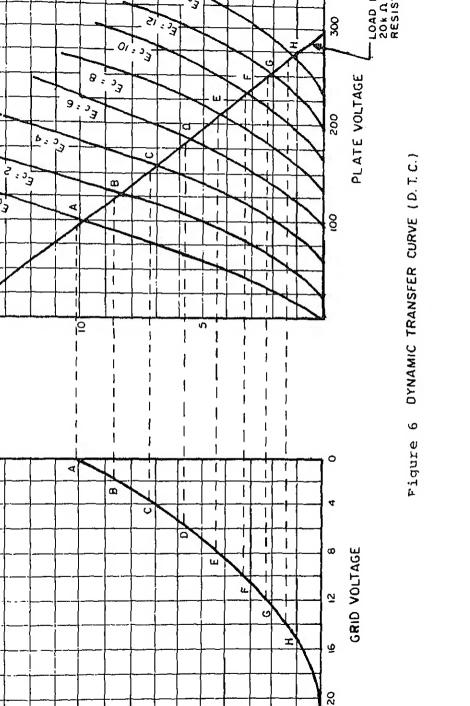




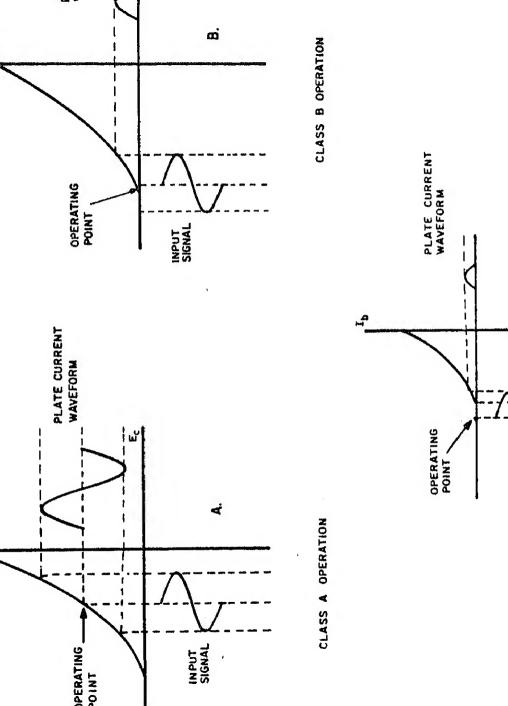


haracteristics of a Triode





namic Transfer Curve (DTC)



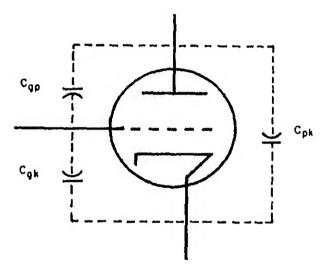


Figure 8 - Interelectrode Capacitance

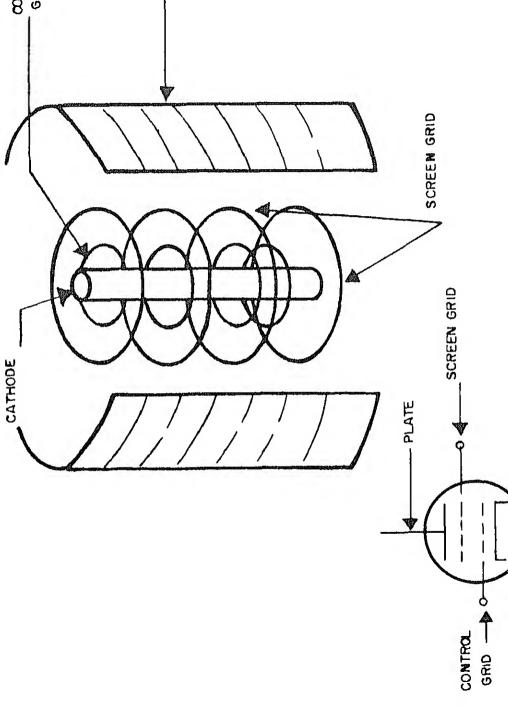
Limitations of the Triode

ectronics, Vol. I, NAVPERS 10087-C, Chapter 7, pages

Shrader, Electronic Communication, Chapter 9, Four
1980, McGraw-Hill Book Company Inc.

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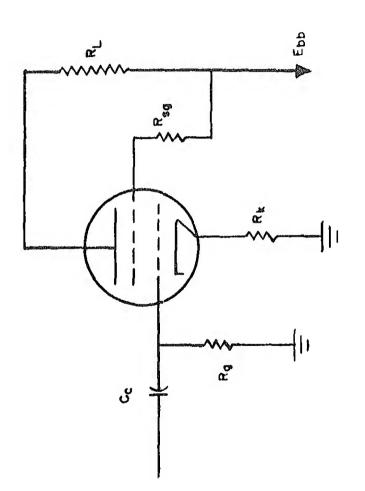
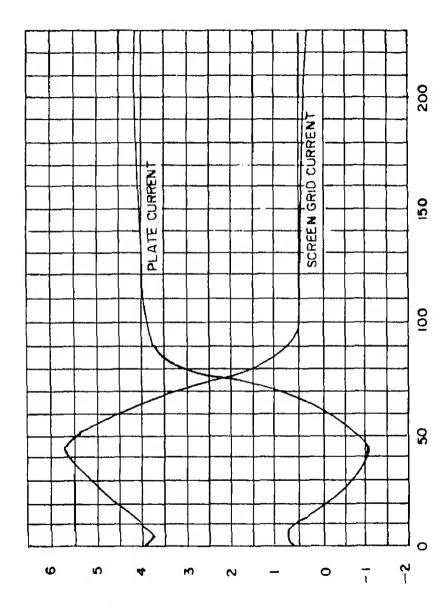


Figure 2 - TETRODE CIRCUIT

PLATE CURRENT AND SCREEN GRID CURRENT IN ma



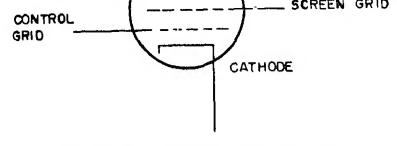
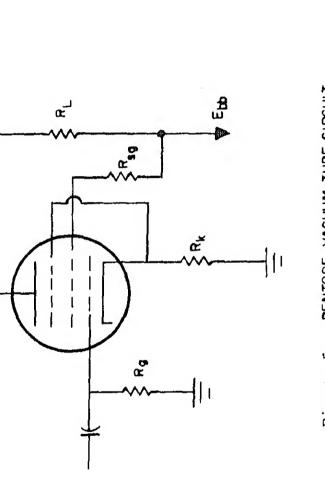
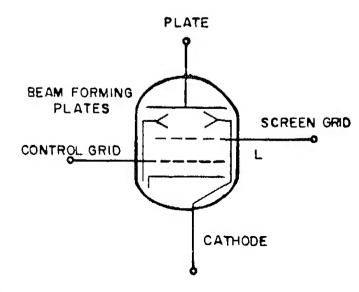


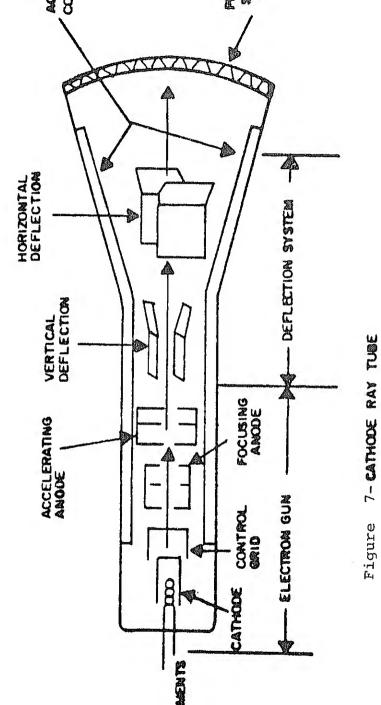
Figure 4 - PENTODE VACUUM TUBE



- PENTODE VACUUM TUBE CIRCUIT Figure 5



de-Ray Tubes



7- CATHODE RAY TUBE

$$\frac{1}{2\pi f C}$$

$$4 \cdot BW = \frac{R}{2\pi L}$$

$$1y$$

$$5 \cdot X_L = X_C = L/C$$

$$6 \cdot F_O = \frac{X_L}{2\pi L}$$

$$Conly$$

$$Common Emitter Amplifier$$

$$1 \cdot \beta = \frac{I_C}{I_B}$$

$$\frac{E_A}{I_{line}}$$

$$Q^2R$$

$$\frac{X_L}{R}$$

$$dB = 20\log(101) \frac{E_2}{E_1} \sqrt{\frac{z_1}{z_2}}$$

dB = 
$$20\log(101)$$
  $\frac{I_2}{I_1} \sqrt{\frac{z_2}{z_1}}$ 

Black Amplifiers

$$A_{f} = \frac{A_{V}}{1 - \beta A_{V}}$$

$$e_{\varepsilon} = e_{in} + \beta e'_{out} = e_{in} + e_{f}$$

$$e_{\varepsilon} = e_{in} + \beta e'_{out} = e_{in} + e_{f}$$

$$e'_{out} = \frac{A_{v}e_{in}}{1 - \beta A_{v}} = e_{in}A_{f} = e_{\varepsilon}A_{v}$$

$$\frac{A_{V}e_{in}}{1-\beta A_{V}} = e_{in}A$$

$$\frac{ed}{-\beta A_{V}}$$

$$ed' = \frac{ed}{1 - \beta A_{V}}$$

$$\beta = \frac{R_{i}}{R_{f} + R_{i}} \frac{R_{E}}{R_{C}}$$

 $E_{\text{out}} = \left(E_{\text{in}_2} \frac{R_f}{R_{\text{s}_2}}\right) + \left(-E_{\text{in}_1} \frac{R_f}{R_{\text{s}_1}}\right)$ 

mps

 $E_{\text{out}} = e_{\text{in}} \frac{R_{\text{f}}}{R_{\text{s}}}$